# UNDERGRADUATE/ INTEGRATED POST GRADUATE DEGREE PROGRAMMES

(With exit option of Diploma)

(Choice Based Flexible Credit System)

Regulations 2021

Volume - 19 (Syllabi for Nanotechnology Programme Courses)

Revised on July 2024



## SRM INSTITUTE OF SCIENCE AND TECHNOLOGY

(Deemed to be University u/s 3 of UGC Act, 1956)

# UNDERGRADUATE/ INTEGRATED POST GRADUATE DEGREE PROGRAMMES

(With exit option of Diploma)

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Regulations 2021

Volume - 19A (Syllabi for Materials Science (Integrated) Programme Courses)



## SRM INSTITUTE OF SCIENCE AND TECHNOLOGY

(Deemed to be University u/s 3 of UGC Act, 1956)

**Engineering Course** 

Regulations 2021



# SRM INSTITUTE OF SCIENCE AND TECHNOLOGY

(Deemed to be University u/s 3 of UGC Act, 1956)

Course Code	21NTS211T	Course Name	COMPUTATION	IAL METHODS I	FOR MATERIALS SCIENC		ourse		S			ENG	INEER	ING S	CIENC	Έ		L 3	. T	P 0	C 3
Pre-requis		Nil	Co- req Cours		Nil	****		gress							Nil						
Course C	Offering Departme	ent	Physics and Nanote	echnology	Data Book / Codes /	Standards								Nil							
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	arning Rationale	` '	e purpose of l <mark>earni</mark> i		s to:	<u> </u>	1	4	-				itcome	•		ı				ograr pecific	
CLR-1:	develop skills to	solve problem	is in physics <mark>nume</mark> ric	ally	1.0		1 -	2	3	4	5	6	7	8	9	10	11	12	Ou	tcom	:S
CLR-2:	learn advance to	ols for compu	tational p <mark>hysics</mark>				dge		<b>Jo</b>	SI S					ork		8				
CLR-3:	learn methods to	solve various	ร real-l <mark>ife problem</mark> s กเ	ımerically		Acc.	<u>≪</u>	S	nent	atio	age	ъ			×		nan	Вu			
CLR-4:	learn and apply n	nethods used	acro <mark>ss the ac</mark> ademic	s and industry	43.5	1.72	Engineering Knowledge	Analysis	Design/development of solutions	Conduct investigations of complex problems	Modern Tool Usage	The engineer and society	∞ >	L.	ndividual & Team Work	ion	& Finance	ife Long Learning			
CLR-5:	learn to solve qua	antum mecha	nic <mark>al proble</mark> ms		R 10 37	379.7	ring	Yu	deve	ex in X	2	inee	Environment Sustainability		<u>~</u>	Communication	Project Mgt.	g Le			
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Course Ou	tcomes (CO):	At	<mark>the en</mark> d of this cou	rse, learners w	ill be able to:	4	Eng	Problem ,	Designation	o Sol	Mod	The en	Envi S <mark>us</mark>	Ethics	Indi	Con	Proj	Life	PSO-1	PSO-2	PSO-3
CO-1:	understand the id	dea of model <mark>li</mark>	<mark>ng</mark> i <mark>n s</mark> mall systems		1 2/ A XX	69 413	3	- 3	-		3	-7	-		-	-	-	-	3	-	3
CO-2:	solve classical m	olecular dyn <mark>a</mark>	mics			1880	3	3	9.73	11-14	3	1	-	-	-	-	1	-	3	2	-
CO-3:	solve ODE by diff	ferent meth <mark>od</mark>	ds	A sale	75 APR 100 TEL		3	3	1	-3	3	_	-		-	-	-	-	3	-	3
CO-4:	solve quantum m	echanical <mark>pro</mark>	<mark>oblem</mark> s	En 12			3	3	De t	<b>I</b> -	3	-	-	1	-	-	1	1	3	3	3
CO-5:	solve problems u	sing rando <mark>m i</mark>	<mark>numb</mark> ers	N/A		7 E 1 E	3	3		7 -	3	-	-		-	-	-	-	3	3	-
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Learning Resources	2. Qing	gkai Kong, Tin	nerical Recepies, <mark>2nd</mark> nmy Siauw, Alexandr e for Engineers and S	e Ba <mark>yen, Pythor</mark>	n Programming and Numer er), <mark>2020</mark>		3. Ti	hijssei	n, Con	nputatio	onal Pi	nysics,	2nd ed	I, CUP	, 2007	,					

				Summative							
	Bloom's Level of Thinking	CLA-1 A <mark>vera</mark>	ative ge of unit test %)	CL	g Learning LA-2 <mark>0%)</mark>	Final Examination (40% weightage)					
		Theory	Practice	Theory	Practice	Theory	Practice				
Level 1	Remember	15%	A STEEL STATE OF THE STATE OF T	15%		15%	-				
Level 2	Understand	25%		20%		25%	-				
Level 3	Apply	30%	3	25%		30%	-				
Level 4	Analyze	30%	-	25%	A -	30%	-				
Level 5	Evaluate	A .		10%	7	-	-				
Level 6	Create		*-A	5%		-	-				
	Total	100	) %	10	00 %	10	0 %				

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Inter <mark>nal Expe</mark> rts
1. Dr. Avik Chatterjee, Chief Scientist, Centre for Advanced Manufacturing and	1. Dr. M. S. Shunmugam, Professor, Department of Mechanical	1. D <mark>r. Rudra B</mark> anerjee, SRMIST
Metrology Group Advanced Design a <mark>nd Analy</mark> sis Group- CSIR-CMERI	Engineering, IIT Madras	
2. Dr. Soumen Mandal, Senior Scientist, Central Mechanical Engineering	2. Dr. Jose Mathew, Professor, Department of Mechanical	2. Dr <mark>. Payel B</mark> andyopadhyay, SRMIST
Research Institute, Durgapur, WB	Engineering, NIT Calicut	

**Professional Core Courses** 

Regulations 2021



## SRM INSTITUTE OF SCIENCE AND TECHNOLOGY

(Deemed to be University u/s 3 of UGC Act, 1956)

Course	21NTC211J	Course	ELECTRIC, ELECTRONICS AND DIELECTRIC PROPERTIES OF	Course	)	PROFESSIONAL CORE	L	Τ	Р	С	1
Code	2111102113	Name	MATERIALS	Category	C	PROFESSIONAL CORE	3	0	2	4	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this co	ourse is to:	11	7	1-		Progr	<mark>am</mark> Ou	tcome	s (PO	)					ogran	
CLR-1:	outline the fundamentals	and applications <mark>of electric fiel</mark> d and	d electric potential	1	2	3	4	5	6	7	8	9	10	11	12		ecific tcome	
CLR-2:	illustrate the basics of ele electric emission	ctrical conduct <mark>ion of me</mark> tals and se	emiconductors, thermionic emission, photo		L.	X	Jo		ety	Sustainability		×						
CLR-3:	introduce dielectric consta	ant, polariz <mark>ation, ferr</mark> oelectricity, pie	zoelectricity	ledge		velopment of	ions	Φ	society	stain		Work		inance	_			
CLR-4:	explain the working of var	ious cap <mark>acitors, t</mark> he capacitor with	dielectric and electric displacement	nowled	'SiS	bme	stigations slems	Usage	and	& Su		Team	⊑	ш	aming			
CLR-5:	introduce the concepts of PN junction diode	energ <mark>y bands</mark> in solids, intrinsic ar	nd extrinsic semiconductor, Hall effect and	ering K	n Analysis	/develo	inve	Tool	engineer			∞ర	ommunication	Mgt. &	ong Lear			
Course O	utcomes (CO):	At the end of this course, learn	ners will be able to:	Engine	Problem	Design	Conduct	Modern	The er	Environment	Ethics	Individual	Comm	Project	Life Lo	PS0-1	PS0-2	PSO-3
CO-1:	apply the concepts of elec	ctri <mark>c field an</mark> d electric potential to va	arious systems of charge distribution	3	-	40	2	-	4	-	-1	-	-	-	-	3	-	-
CO-2:	analyze the electron cond	uc <mark>tion and</mark> thermal conduction in m	netals and semiconductors	.3	140	44	2	-	9	-	-	-	-	-	-	3	-	-
CO-3:	gain knowledge on dielec	tri <mark>cs, frequ</mark> ency dependence of pol	arization, ferroelectricity, piezoelectricity	3	2	De l	1-	-	-	-		-	-	-	-	-	3	-
CO-4:	acquire knowledge on diff	er <mark>ent types</mark> of capacitors		3	20		2	-	1	-	-:	-	-	-	-	-	-	3
CO-5:	utilize the concepts of ene	erg <mark>y bands t</mark> o examine the metals,	semiconductors for various applications	3			2	<b> </b>	_	-		-	-	-	-	-	-	3

Unit-1 – Electrostatics 15 Hour

Coulomb's law, Electric field, Electric field due to discrete and continuous charge distributions, Gauss law in integral and differential form, Applications of Gauss law for symmetric charge distributions, Electric dipole in an electric field, Torque, Electric potential - Calculating electric potential from electric field and vice-versa - Potential inside and outside of a spherical shell of charge - Equipotential lines and surfaces - Energy expended in moving a point charge in an electric field - Calculation of electric potential due to a system of discrete and continuous charge distributions.

Lab1 - Calibration of ammeter using Potentiometer,

Lab-2 - Calibration of voltmeter using Potentiometer

#### Unit-2 - Electrical Conduction in Solids

15 Hour

Metals, Semiconductors, Ionic Solids; Drude Model; factors affecting the resistivity of electrical materials, motion of an electron in an electron of motion of an electron, current carried by electrons, mobility, energy levels of a molecule, emission of electrons from metals, thermionic emission, photo electric emission, field emission, effect of temperature on electrical conductivity of metals, electrical conducting materials, thermal properties, thermal conductivity of metals, thermoelectric effect

Lab 3 - Determination of resistivity using four probe method

Unit-3 - Dielectric Properties 15 Hour

Introduction, effect of a dielectric on the behavior of a capacitor, polarization, the dielectric constant of monatomic gases, frequency dependence of permittivity, dielectric losses, significance of the loss tangent, dipolar relaxation, frequency and temperature dependence of the dielectric constant, dielectric properties of polymeric system, ionic conductivity in insulators, insulating materials, ferroelectricity, piezoelectricity, Lab 4 - Determination of Internal resistance of the given cell using Potentiometer

Unit-4 - Capacitors 15 Hour

Calculating the capacitance of a parallel plate capacitor, a cylindrical capacitor, a spherical capacitor, and for an isolated spherical capacitor, Capacitor with a dielectric, Gauss's law in presence of linear dielectrics, Electric displacement.

Lab 5 - Determination of dielectric constant

#### Unit-5 - Semiconductors

15 Hour

Energy band in solids, conductors, semiconductors and insulators, types of semiconductors, Intrinsic semiconductors, impurity type semiconductor, diffusion, the Einstein relation, hall effect, Thermal conductivity of semiconductors, electrical conductivity of doped materials, p-n junction diode, Forward and Reverse Bias,

- Lab 6 Determination of energy band gap of a semiconductor materials,
- Lab 7 Determination of Hall coefficient

Learning Resources
Resources

- 1. H. Goldstein, C. Poole and J. Fafko, Classical Mechanics, (Pearson Education Inc., 2002)
- 2. Rana & Joag, Classical Mechanics, McGraw Hill Education, 2017)
- 3. D.S. Mathur, Elements of Properties of Matter, (S. Chand, 2010

- 4. J. P. Suchet, Electrical Conduction in Solid Materials, Elsevier, 1st edition, 1975
- 5. R. P. Deshpande, Capacitors, McGraw-Hill
- 6. P C Chattopadhyay, D. Rakshit, Electronics Fundamentals and Applications, New Age International Private Limited, 2020

Learning Assessm	nent			THE PARTY OF THE P							
		- A.	Continuous Learnin	Cum	Summative						
	Bloo <mark>m's</mark> Level of <mark>Thinking</mark>	Forma CLA-1 Average (45%	of unit test	CL	n Learning A-2 5%)	Final Examination (40% weightage)					
		Theory	Practice	Theory	Practice	Theory	Practice				
Level 1	Remember	15%	the other man	一种电影特殊。	20%	20%	-				
Level 2	Understand	25%			20%	20%	-				
Level 3	Apply	30%	the same with the	1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	40%	40%	-				
Level 4	Analyze	30%		14F18: 34	20%	20%	-				
Level 5	Evaluate		The state of the s	A service of	-	-	-				
Level 6	Create		T - 100%	-	- Y - Y - J	-	-				
	Tota <mark>l                                    </mark>	100 9	%	100	0 %	10	0 %				

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. D.K. Aswal, National Physical Laboratory,	1. Prof. S. Ananthakumar, NIIST, Trivandrum,	1. Dr.T.Vi <mark>jayakuma</mark> r, SRMIST
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2. Dr. H. Sreemoolanadhan, VSSC,	2. Prof. V. Subramanian, IIT Madras, manianvs@iitm.ac.in	2. D <mark>r.K.Kamala</mark> Bharathi, SRMIST
h_sreemoolanadhan@vssc.gov.in	Lilin Mar	- ACT

Course	21NTC212T Course	ENGINEERING THERMODYNAMICS	Course	_	PROFESSIONAL CORE	L	Т	Р	С	
Code	Name	ENGINEERING THERMODYNAMICS	Category	C	PROFESSIONAL CORE	3	0	0	3	

Pre-requisite Courses	Co- requisite Courses	Nil Progressive Courses	Nil
Course Offering Department	Physics and Nanotechnology	Data Book / Codes / Standards	Nil

Course L	earning Rationale (CLR): The purp	ose of l <mark>earning this co</mark> urse is	to:	11	4			Progr	am Ou	ıtcome	s (PO	)					rogram
CLR-1:	understand the fundamental laws of t	nermo <mark>dynamics</mark>	0	1	2	3	4	5	6	7	8	9	10	11	12		pecific itcomes
CLR-2:	introduce the concept of different qua	si <mark>-static proc</mark> ess in thermodynan	nics	agp		Jo	SI	,				Work		9			
CLR-3:	explain the importance of Carnot cycl	e and Carnot engine	- 10 m 2 m	(i)	S	velopment of	stigations roblems	Usage	Ъ	, 1		Μ		Finan	ning		
CLR-4:	understand the basic concept of qu <mark>ar</mark>	<mark>tum st</mark> atistics relevant for engine	eers	Knowle	alysis	ldol	estig orobl		r and	∞ ∞ >	N.	Team	ion	≪ ĕ	arnii		
CLR-5:	introduce the fundamentals of en <mark>sem</mark>	<mark>ble t</mark> heory		ering	An	n/deve	≥ ×	T00	engineer ety	ment ability		al &	unical	Mgt.	Long Le		
Course C	Outcomes (CO): At the en	d of this course, learners will	be able to:	Engine	Problem	Design	Conduct of comple	Modern	The en society	Enviroi Sustair	Ethics	Individual	Communication	Project	Life Lo	PSO-1	PSO-2 PSO-3
CO-1:	apply the laws of thermodyna <mark>mic</mark> s in	real systems	12 July 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	3	- 3	17	- 1	-	/	-		-	-	-	-	3	- 3
CO-2:	analyze the importance of quasi-station	process and adiabatic process	The state of the s	3	2	40	- 19	-	4	-		-	-	-	-	3	-   -
CO-3:	gain knowledge on different <mark>thermod</mark> y	namic quantities	With the St. Co.	3	17.	4.4	-34	-	_	) -	-	-	-	-	-	3	
CO-4:	acquire knowledge on ense <mark>mble the</mark> o	ry		3 -		Gg t	-	-	-	- 1		-	-	-	-	2	3 3
CO-5:	utilize the concepts of quantum statis	ics in future	Photo Day North	3	2	6.	7 -	_		-		-	-	-	-	-	3 -

#### Unit-1 - Microscopic and Macroscopic Point of View

9 Hour

Thermal equilibrium and zeroth law, Temperature, System and surrounding. Extensive and Intensive properties. Zeroth law, .Ideal gas, reversible and irreversible processes. Thermo-dynamic equilibrium, equation of states, Work, quasi-static process, pV diagram, calculation of jpdV for hydrostatic systems

#### Unit-2 - Adiabatic Process and Work

9 Hour

1st law of thermodynamics; internal energy and enthalpy; heat capacities of gases, liquids and solids; application of the 1st law to isothermal, adiabatic, constant pressure and constant volume processes with ideal gas as system; thermochemistry; Kirchoff's Law, Stefan-Boltzmann Law, First law of thermodynamics and internal energy, constant pressure process

#### Unit-3 - Equation of State of Gas

9 Hour

Internal energy of gas, quasistatic adiabatic process, work & heat conversation, 2nd law of thermodynamics, Heat Engine, refrigerator, Kelvin-Plank and Clausius statement of 2nd law, Reversibility, Carnot cycle and refrigerator, Carnot Theorem and thermodynamic temperature, absolute zero and Carnot efficiency, Entropy, Entropy of various systems, TS diagram

#### Unit-4 - Enthalpy, Gibbs and Helmholtz Free Energies

9 Hour

T dS relations, Maxwell relations; Joule-Thomson effect; First order and Second order phase transition, Clausius-Clapeyron equation and phase diagram, Entropy of reversible and irreversible systems, Principles of increasing entropy, entropy and chaos

#### Unit-5 - Statistical Mechanics

9 Hour

Random walk problem, Maxwell velocity, energy and momentum distribution, Statistical distribution, Maxwell Boltzmann statistics, Quantum statistics, Bose-Einstein and Fermi-Dirac Statistics, Specific heat at constant temperature and pressure, Ensemble, Introduction to micro-canonical, canonical and grand canonical ensembles, Partition function, Partition function of canonical ensemble and ideal monoatomic gas

Learning	1.	M. Zemansky, and R.Dittman, Heat and Thermodynamics, 8th Ed., McGraw- Hill Education, 2012.		Arthur Beiser, Concepts of Modern Physics, Sixth Edition, McGraw-Hill, 2003 Sonntag R.E., Borgnakke C. & Van Wylen C. J, Fundamentals of Thermodynamics, 6th
Resources	2.	BB Laud, Fundamentals of Statistical Mechanics., New Edge International, 2009	7.	Ed, Wiley, 2002
			٠.,	

Learning Assessm	nent	, , , ,									
	Bloom's		ative		g Learning		native amination				
	Level of Thinking	CLA-1 Average of unit test (50%)			LA-2 0%)	(40% weightage)					
		Theory	Practice	Theory	Practice Practice	Theory	Practice				
Level 1	Remember	20%	-	20%		20%	-				
Level 2	Understand	20%		20%	2 - 1	20%	-				
Level 3	Apply	40%	DEF SERVICE	40%	- A- V	40%	-				
Level 4	Analyze	20%	27 TO 10	20%	400	20%	-				
Level 5	Evaluate		A 5 A 3 A 5 A 5 A 5 A 5 A 5 A 5 A 5 A 5			-	-				
Level 6	Create				1	-	-				
	Tota <mark>l</mark>	100	)%	10	00 %	100	0 %				

Course Designers		3 7.
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Priyanks Biswas, Graphene Research Lab Pvt Ltd.,	1. Prof. B. R. K. Nanda, IIT Madras, nandab@iitm.ac.in	1. Dr. Rudra Baner <mark>jee, SR</mark> MIST
RI India	[발] (19) 마일 다마 (19) [마일의 (19), 4]	
2. Dr. Pralay K. Santra, Scientist D, Centre for Nano and Soft	2. Prof. Arabinda Haldar, IIT Hyderabad, arabinda@phy.iith.ac.in	2. Dr. Jaivardhan S <mark>inha, S</mark> RMIST
Matter Sciences, Bengaluru		

Course	21NTC213T	Course	KINETICS, DIFFUSION AND MASS TRANSFER	Course	_	DDOEESSIONAL CODE	L	Т	Р	С
Code	2111102131	Name	KINETICS, DIFFUSION AND MASS TRANSFER	Category	U	PROFESSIONAL CORE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

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Course L	earning Rationale (CLR):	The purpose of learning this course is to:	$\cup I$				Prog	am Oı	ıtcome	s (PO	)					rogram	
CLR-1:	understand the fundamen	tal of reactions	1	2	3	4	5	6	7	8	9	10	11	12		pecific Itcomes	
CLR-2:	illustrate the basics of rea	ction kinetic, method of analysis, reaction rate	doe	b	of	SI		. "			Work		8				
CLR-3:	introduce fluxes, law of di	ffusion, ma <mark>ss transfer</mark> and theory of diffusion	Knowlec		evelopment of	stigations	Usage	ъ	٠, ١		Μ		Finance	БC			
CLR-4:	R-4: explain diffusion problems, diffusion-controlled evaporation				lopi	estig		r and	∞ ∞ >	h.	Team	ion	⊗ ⊡	arning			
CLR-5:	5: introduce binary mixture, mass transfer, equation of diffusion					t inve	20	engineer sty	nment nability	1	<u>8</u>	mmunication	Mgt.	g Le			
				roblem Ang	p/ugi	nduct in	lern T		ron	S	/idu	nuı	roject	Long	7	)-2	3
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	<u> </u>	Prof	Des		Mod	The	Sus	Ethics	Individual	Con	Proj	Life	PSO-1	PSO-2	5
CO-1:	demonstrate the fundame	ntal <mark>s of reac</mark> tion, order of reactions	2		3 +	3	-	-7	-		-	-	-	-	3		- ]
CO-2:	20-2: analyse the basics of reaction kinetics, method of analysis, reaction rate		2	-	40.0	3	-	1	-		-	-	-	-	3		- ]
CO-3: gain knowledge on ficks law of diffusion, theory and mass transfer		2	MI IT		3	-	-	) -		-	-	-	-	3		- ]	
CO-4:	<b>0-4:</b> acquire knowledge on diffusion problems, diffusion controlled evaporation		2	2	705	3	-	-	- 1		-	-	-	-	3		-
CO-5:			2			3	_		_	-	-	-	-	-	3	- ;	3

Unit-1 - Introduction 9 Hour

Classification of reactions: homogeneous vs heterogeneous, single vs multiple; elementary vs non-elementary, reversible vs irreversible; molecularity and order of reactions; types of intermediates for non-elementary reactions; search for reaction mechanism.

#### Unit-2 - Temperature Dependence of Reaction Rate

9 Hour

Definition of fluxes; relation of fluxes relative to stationary coordinates and average velocities; Fick's 1st law of diffusion; analogy of momentum, heat and mass transfers; temperature and pressure dependence of mass diffusivity; theory of diffusion in gases and liquids.

#### Unit-4 - Boundary Conditions in Diffusion

9 Hour

Applications of shell mass balance and boundary conditions in solving diffusion problems: diffusion- controlled evaporation of a liquid through a stagnant gas film at steady state; mixed control oxidation of a metal

Unit-5 - Fick's Law

Three-dimensional equation of diffusion with convection in a binary mixture A-B: Fick's 2nd law of diffusion. Mass transfer coefficient and concentration boundary layer on a flat plate: exact solution method and approximate integral method

Learning	1. Michel Soustelle, An Introduction to Chemical Kinetics, Wiley, 2011	3. E. L. Cussler, Diffusion: Mass Transfer in Fluid Systems, Chembridge University Press, 3rd Edition, 2009
Resources	2. Keith J. Laidler, Pearson, Chemical Kinetics, 3rd Edition, 1987	4. James S. Vrentas, Christine M. Vrentas, Diffusion and Mass Transfer, CRC Press, 1st Edition, 2013

			Summative							
	Bloom's Level of Thinking	CLA-1 Avera	native ge of unit test %)	CL	Learning A-2 0%)	Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	20%	ALTERNA	20%		20%	-			
Level 2	Understand	20%		20%		20%	-			
Level 3	Apply	40%	3	40%		40%	-			
Level 4	Analyze	20%	-	20%		20%	-			
Level 5	Evaluate		-	- 7	/	-	-			
Level 6	Create		-A - A A	-	2 - 1	-	-			
	Total	100	) %	100	0 %	10	0 %			

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. S. Ramaseshan, IGCAR, Kalpakkam	1. Prof. K.Jeganathan, School of Physics. Bharathidasan University	1. Dr.D. C.Gopa <mark>lakrishna</mark> n, SRMIST
2. Dr. G. Krishnan, IGCAR Kalpakkam	2. Prof. N. Ponpandian, Bharathiyar University, Coimbatore	2. Dr.Payel Band <mark>opadhya</mark> y, SRMIST
	cdramo@annauniv.edu	

Course	21NTC214 I	Course	OPTICAL AND PHOTONIC PROPERTIES OF MATERIALS	Course	_	DDOEESSIONAL CODE	L	Т	Р	С
Code	2111102140	Name	OF IICAL AND PHOTONIC PROPERTIES OF MATERIALS	Category	U	PROFESSIONAL CORE	3	0	2	4

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	111	- 4			Progr	<mark>am Օ</mark> ս	itcome	s (PO	)					rogram	
CLR-1:	acquire knowledge on va	arious basic princip <mark>les of super</mark> position of waves	1	2	3	4	5	6	7	8	9	10	11	12	_	pecific utcomes	
CLR-2:	modify properties of ligh	t using non-line <mark>ar optics in</mark> metamaterials	dge		of	SI		. ".			Work		8				1
CLR-3:	understand the concept	of image for <mark>mation and</mark> design of optical systems	Knowlec	S	nent	estigations roblems	Usage	ъ	. 1				Finan	Бu			
CLR-4:	3			alysis	velopment of	estig	NS.	r and	∞ ∞ >	h.	Team	ion	∞ ⊢	arning			
CLR-5:	5: gain knowledge on optical and photonic properties of materials		ering	A	n/deve	l.≧ ×	n Tool	engineer ety	nment nability		ual &	mmunication	t Mgt.	Long Le			
Course C	ourse Outcomes (CO):  At the end of this course, learners will be able to:		Engine	Problem	Design solutio	Conduct of comple	Modern	The en society	Enviro S <mark>ustai</mark>	Ethics	Individual	Comm	Project	Life Lo	PS0-1	PSO-2 PSO-3	
CO-1:	apply the principles of 's	uper <mark>position'</mark> in the design of interferometer	3	- 3	1.5	- 1	-	-,/	-		-	-	-	-	3	2 -	
CO-2:	2-2: analyze the non-linear optical properties of material surface to design a metamaterial		3	2	10.00	- 19	-	4	-		-	-	-	-	3	- 3	
CO-3:	O-3: apply the knowledge of image formation to design optical systems		3	2	4.7	13	_	_	-		-	-	-	-	3	- 3	
CO-4:	0-4: utilize the opportunities in the emerging field of photonics		2	3		-	-	-	-		-	-	-	-	3	- 3	
CO-5:	2-5: apply the concepts of scatte <mark>ring to p</mark> robe the material properties		3	- 2	-	-	_		-		-	_	-	-	3	- 2	

#### Unit-1 - Introduction to Wave Propagation and Wave Superposition Principle

15 Hour

Interference and Diffraction, Basics of coherence: Temporal and spatial coherence, Shape and width of spectral lines and broadening mechanisms, Michaelson and Fabry-Perot Interferometers, Introduction and analysis of speckle pattern and speckle contrast imaging,

- Lab 1: Determination of wavelength using Newton's rings experiment.
- Lab 2: Determination of wavelengths of mercury spectrum using diffraction grating in minimum deviation
- Lab 3: Measurement of wire thickness using air wedge technique.

#### Unit-2 - Photonics

15 Hour

Electrons in periodic structures, Photons in periodic structures, 2D and 3D photonic crystals, Photons in non-periodic structures, Photonic glass, Light-matter interactions, Regimes of light scattering through disordered media, Introduction to Random lasing, Plasmonic materials, Surface Plasmon Resonance (SPR), SPR in nanostructures, Losses in plasmonics, Localization of light in dielectric materials, Optical properties of metal dielectric composites, Introduction to metamaterials, Electric and magnetic metamaterials. Negative index metamaterials. Non-linear optics with metamaterials

#### Unit-3 - Optics

15 Hour

Image formation (first-order optics), Mirrors and prisms, Phenomenon of spherical and chromatic aberration, Stops and apertures, Basic optical devices and Design of optical systems, Solid immersion lens and Numerical aperture increasing lens (NAIL),

- Lab 4: Determination of refractive index of material of prism by drawing the i-d curve,
- Lab 5: Determination of numerical aperture and acceptance angle of optical fiber using laser Lab 6: Determination of refractive index of liquid using spectrometer

#### Unit-4 - Introduction to Electromagnetic Wave Theory

15 Hour

Maxwell's equations, Different scattering regimes, Rayleigh and Mie scattering, Geometry dependence resonance, Static and dynamic light scattering, Basic theory of optical tweezers, Introduction to Atomic Force Microscopy (AFM), AFMolloidal probe technique, Magnetic chaining technique, Beam width measurement techniques, Knife-edge scanning technique, Introduction to Snell's law, Liquid Refractometer Lab 7: Study of laser beam parameters: (a) measurement of wavelength of He-Ne laser light using ruler (b) measurement of thickness of wire with laser (c) determination of particle size using laser

#### Unit-5 - Basics of Optical Microscopy

15 Hour

Bright field microscopy, Dark field microscopy, Introduction to polarization, Polarizing microscopy, Phase contrast microscopy, Concept of fluorescence, Different kinds of dyes used in microscopy, Fluorescence microscopy, Confocal fluorescence microscopy, Light sheet fluorescence microscopy, Two-photon fluorescence optical microscopy, Introduction to non-linear optical properties, Non-linear optical microscopy, Lab 8: Optical microscopy for different samples to see the microstructural features

#### Learning Resources

- 1. A.Ghatak, Optics, McGraw Hill, 7th Ed, 2020.
- 2. E. Hecht. Optics. Pearson. 5th Ed. 2019.
- 3. R. Boyd, Nonlinear Optics, Academic Press, 3rd Ed,
- 4. C.Dainty, Laser Speckle and Related Phenomena, Springer, 2nd Ed. 1984.
- 5. M. Bornand, E. Wolf, Principles of Optics, Cambridge University Press, 7th Ed., 1999.
- 6. S. V. Gaponenko, Introduction to Nanophotonics, Cambridge University Press, 1st Ed, 2010
- V. Shalaevand W. CAI, Optical Metamaterials: Fundamentals & Applications, Springer, 2<sup>nd</sup> ed., 2010.
- 8. J. Mertz, Introduction to Optical Microscopy, Roberts & Company publishers, 1st Ed., 2010.
- 9. C.F. Bohren and D. R. Huffman, Absorption and scattering of light by small particles, Wiley-VCH. 4th Ed., 2009
- 10. J. W. Goodman, Statistical properties of laser speckle patterns, Springer-Verlag, 1st Ed. 1975

earning Assessn	nent		<u> 2 1대, 양산년 -                                  </u>	245753						
	Bloom's Level of <mark>Thinkin</mark> g	Forma CLA-1 Averag (45)	e of unit test	Life-Long CL	Learning A-2 5%)	Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	15%			20%	20%	-			
Level 2	Understand	25%	1	200	20%	20%	-			
Level 3	Apply	30%		1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	40%	40%	-			
Level 4	Analyze	30%			20%	20%	-			
Level 5	Evaluate		- A) (4)	-	-4	-	-			
Level 6	Create	- L	- 1.9	-		-	-			
	Total	100	%	100	0 %	10	0 %			

Course Designers		/ / / / / / / / / / / / / / / / / / / /
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
Mr. Sameer Sharda, New Age Instruments & Materials Pvt.     Ltd, Gurgaon, sameer@newagein.com	Prof. V. Subramanian, IIT Madras, Chennai, manianvs@iitm.ac.in	1. Dr. Junaid Masud Laskar, SRMIS
Mr. Mohammed Shafi, Holmarc Opto-Mechatronics Pvt. Ltd, Cochin, optics@holmarc.com	2. Prof. C Vijayan, IITM, Chennai, cvijayan@iitm.ac.in	2. Dr. K Shadak Alee, SRMIST

Course	21NTC2151	Course	PHYSICAL METALLURGY	Course	_	DDOEESSIONAL CODE	L	Т	Р	С
Code	2111102100	Name	FITISICAL WETALLONGT	Category	U	PROFESSIONAL CORE	3	0	2	4

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	TIME.	11	4			Progr	am Oı	itcome	s (PO	)					rogram
CLR-1:	gain knowledge on Phase	diagrams includ <mark>ing Fe-C pha</mark> se diagram		1	2	3	4	5	6	7	8	9	10	11	12	_	pecific Itcomes
CLR-2:	discussing about nucleati	on and growth <mark>kinetics</mark>		dge		o	SL		. "			Work		99			
CLR-3:	understanding electroche	mical exper <mark>iments an</mark> d parameters		(I)	w	velopment of	estigations roblems	Usage	ъ			Μ		Finan	ning		
CLR-4:	introduction to steels and	their pro <mark>perties</mark>	-17.77	Knowle	alysis	ndol	estig/ probl		r and	ج × ح ×	h.	Team	fion	∞ర	arni		
CLR-5:	exploring the properties o	f alumi <mark>nums an</mark> d its alloys	377/19	ering	An	a	- ×	Tool	engineer ety	ment	, 1	<u>8</u>	Sommunication	Mgt.	ig Le		
				ine	roblem	ign/d	nduct ir omplex	dern		tain	S	Individual	l E	Project	Long	7	)-2 )-3
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	and the second	Engi	Prof	Des	Con	Moc	The	Env Sus	Ethi	Indi	Sol	Proj	Life	PSO-1	PSO-2 PSO-3
CO-1:	leaning the phase diagrar	ns i <mark>ncluding</mark> the Fe-C phase diagrams	V 305 717	2	- 5	3	-	-	-7	-		-	-	-	-	3	
CO-2:	understanding the diffusion	n, <mark>nucleati</mark> on and growth kinetics	N. Mar.	ı	2	4 745	3	-	4	-	-	-	-	-	-	3	2 -
CO-3:	exploring the electrochem	ic <mark>al corros</mark> ion prevention techniques		2	17/30	4.7	3	-	-	-		-	-	-	-	3	- 3
CO-4:	introduction to steels and	th <mark>eir prope</mark> rties	37.4	3	1.5		2	_	-	-		-	-	-	-	-	3 3
CO-5:	study on properties and a	op <mark>lications</mark> of light metals and their alloys	N 18 11	3	4		7-	2		-		-	-	-	-	-	2 3

#### Unit-1 - Concept of Phase Diagram

Fe-C system, equilibrium and non-equilibrium cooling of Fe-C systems, Free energy composition curves for binary systems, Effects of alloying elements and cooling rate on Fe-C diagram, Ternary phase diagram Lab1: Specimen Preparation techniques for Metallographic Analysis – Optical Microscopy

Lab2: Pb – Sn Phase diagram

#### Unit-2 - Diffusion and Nucleation

15 Hour

15 Hour

Diffusion in solids, Nucleation and Growth Kinetics, Solidification, TTT diagram and CCT diagram - hardenability measurement, annealing, normalising - hardening and tempering - heat treatment furnaces, Quench Cracks, case hardening techniques

Lab3: Microstructural Analysis of Carbon Steels

Lab4: Microstructural Analysis of Cast Iron

#### Unit-3 - Galvanic Cell

15 Hour

Electrode Potential, Polarization, Passivation, General methods of corrosion prevention, Cathodic protection, coatings, Corrosion prevention by alloying

Lab5: Study of the Microstructure of heat-treated plain carbon steels.

Lab6: To find out the hardness of various heat treated and untreated plain carbon steels

#### Unit-4 - Types of Steels

15 Hour

plain carbon steels, alloy steels, tool steels; stainless steels types of cast irons compositions, properties and applications, heat treatment (specific examples)

Lab7: Microstructural Analysis of Non-Ferrous Metals: Brass & Bronze

Unit-5 - Aluminum and its Alloys

physical, chemical and mechanical properties of aluminium of aluminium alloys, magnesium, titanium alloys - microstructural features, typical properties and applications - heat treatment (specific examples Lab8: Standard test Methods for Estimation of Grain Size

Lab9: Determination of density of defects in given copper wire at different temperatures using resistivity measuremen

Learning Resources
Resources

 Raghavan, V., "Physical Metallurgy", (Prentice Hall of India, 2006) Sidney Avner, Introduction to Physical Metallurgy, McGraw Hill Education, 2nd edition, 2017

- 2. Herman W. Polack, Materials Science and Metallurgy, 4th Edition, A Reston Book, A Pearson Education Company, NJ, 1988:
- 3. Geroge L Kehl, The Principles of Metallographic Laboratory practice (1949)

Learning Assessme	ent 🦯										
	Bloom's Level of Thinking	CLA-1 Avera	Continuous Learning ative ge of unit test %)	CL	Learning A-2 %)	Summative Final Examination (40% weightage)					
		Theory	Practice	Theory	Practice	Theory	Practice				
Level 1	Remember	15%	174 × 164 115 × 1	74.5	20%	20%	-				
Level 2	Understand	25%		A. A. 14	20%	20%	-				
Level 3	Apply	30%	1 15 M 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	THE R. LEWIS CO., LANSING	40%	40%	-				
Level 4	Analyze	30%		82 J. 183 19 19 19 19 19 19 19 19 19 19 19 19 19	20%	20%	-				
Level 5	Evaluate	- , s. (f. )		PROPERTY AND THE			-				
Level 6	Create	Z NATALIA		. 人名英格兰姓氏	)	-	-				
	T <mark>otal</mark>	100	)%	100	0 %	100	0 %				

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. D. Sivaprahasam, ARCI, Chennai,	1. Prof. M. Anbarasu, IIT Madras, anbarasu@ee.iitm.ac.in	1. Dr. Suresh Pe <mark>rumal, SR</mark> M IST
sprakash@arci.res.in	2.	
2. Dr. Ajay Singh, BARC, Mumbai, ajay@barc.ac.in	2. Prof. R. Ranjith, IIT Hyderabad, ranjith@msme.iith.ac.in	2. Dr. Ravikiran <mark>a, SRM I</mark> ST

Course	21NTC216T	Course	POLYMER MATERIALS AND COMPOSITES	Course	_	DDOEESSIONAL CODE	L	Т	Р	С
Code	2111102101	Name	POLYMER MATERIALS AND COMPOSITES	Category	U	PROFESSIONAL CORE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offerin	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR): The purpose of learning this course is to:	11	4			Progr	<mark>am O</mark> u	tcome	s (PO	)					rogram	1
CLR-1:	acquire knowledge about fundamentals of polymers	1	2	3	4	5	6	7	8	9	10	11	12	_	pecific itcomes	
CLR-2:	understand basics concepts about polymerization reactions	dge		of	SL		L "			Work		8				
CLR-3:	gain insight into the importance of po <mark>lymers in</mark> nanotechnology	Knowlec	S	nent	estigations roblems	Usage	ъ			am W		inance	р			
CLR-4:	understand the physical and mech <mark>anical pro</mark> perties of polymer		alysis	udoli	estig	l Us	r and	∞ ×	h.	Teal	tion	δ. F	arning			
CLR-5:	gain knowledge about the preparation and properties of nanocomposites	ering	٩	n/development of	t inve	Tool	engineer ety	ment ability	. 1	<u>8</u>	Sommunication	Mgt.	g Le			
		9	plem	ign/	onduct in complex	Aodern T		iron	S	ndividual	nur	Project	Long	7	)-2	
Course O	utcomes (CO):  At the end of this course, learners will be able to:	Engi	Prof	Des	Con	Moc	The	Env Sus	Ethi	İndi	Col	Proj	Life	PSO-1	PSO-2 PSO-3	
CO-1:	apply the basic concepts to understand the functionality of the polymers	3	- 2	17.	-	-	-7	-		-	-	-	-	-		
CO-2:	analyze the mechanism of d <mark>ifferent p</mark> olymerization reactions	3	2	er Park	1	-	4	-	-	-	-	-	-	-		
CO-3:	express the various method <mark>s and ap</mark> proaches employed in the molecular weight of the polymer	3	برزوانا	1.7	43	-	-	-		-	-	-	-	-		
CO-4:	acquire knowledge on crystal strucuture and mechanical properties of the polymer	3	147	125	-	_	-	d -		-	-	-	-	-		
CO-5:	analyze the types of matrix, reinforcements and nanoadditives available for the preparation of nanocomposites	3	2	-54	3-	-		-		-	-	-	-	-		

#### Unit-1 - Fundamentals of Polymers

9 Hour

Basic concepts & definitions: monomer & functionality, polymer, repeating unites, degree of polymerization, molecular weight & molecular weight distribution. Natural Polymers: Chemical & Physical structure, properties, source, important chemical modifications, applications of polymers

#### Unit-2 - Concepts about Polymerization Reactions

9 Hour

Polymerization: Classification of polymers, the moplastic and thermosetting, different types of polymerization mechanism, Step reaction polymerization: mechanism and kinetics, Ionic and coordination chain polymerization: mechanism and kinetics, Copolymerization: mechanism and kinetics motor

#### Unit-3 - Polymers in Nanotechnology

9 Hour

Characterization: Criteria for solubility, Thermodynamics and phase equilibrium of polymer solution, Measurement of molecular weight, Chemical analysis, thermal analysis, End group analysis, colligative property measurement, ultra centrifugation, light scattering, gel permeation chromatography

#### Unit-4 - Physical and Mechanical Properties of Polymer

9 Hour

Configuration of polymer chain, Crystal structure, crystallization and melting, factors affecting Crystallization and melting, viscous flow, viscoelasticity, Mathematical models for viscoelasticity, Glassy state and glass transition, Mechanical properties of crystalline polymers

#### Unit-5 - Preparation and Properties of Nanocomposites

9 Hour

Commonly used matrix reinforcement system, Fiber, Flake and particulate reinforced composites, Nano particle dispersion in polymer matrix, Polymer- nanoclay composites and polymer-carbon nanotubes composites

Learning Resources
Resources

- 1. Fred W Billmeyer, Textbook of Polymer Science, Wiley, 3rd Edition, 1984
- Anil Kumar, Rakesh K Gupta, Fundamentals of Polymer Engineering, Marcel Dekker Inc., 2nd Edition, 2003
- 3. Mc Crum, Principles of polymer Engineering, 2nd Edition, Oxford, 2001
- HullD., and Clyne W., An Introduction to Composite Materials, Cambridge University Press, 2nd Edition, 2017
- 5. Jones R.M., "Mechanics of Composite Materials", Taylor & Francis, 2nd Edition, 2018

			Cum	Summative							
	Bloom's Level of Thinking		ative ge of unit test %)	CL	g Le <mark>arning</mark> .A-2 0%)	Final Examination (40% weightage)					
		Theory	Practice	Theory	Practice	Theory	Practice				
Level 1	Remember	15%		15%		15%	-				
Level 2	Understand	25%	Act In the	20%	4 4	25%	-				
Level 3	Apply	30%	70 E 10 TO 10	25%	( P)	30%	-				
Level 4	Analyze	30%	N. A. S. 1777	25%		30%	-				
Level 5	Evaluate			10%	1 - 2	-	-				
Level 6	Create			5%		-	-				
•	Tot <mark>al</mark>	100	)%	- 10	0 %	10	0 %				

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. P. Sudhakara, CLRI – CSIR, Ja <mark>landhar</mark> ,	1. Dr. Kothandaraman Ramanujam, IITM Chennai, rkraman@iitm.ac.in	1. Dr. N. Angeline Little Flower. SRMIST
sudhakarp@clri.res.in		
2. Dr. Sudhakar Selvakumar, CSIR-Central Electrochemical	2. Dr. Arthanreeswaran, NIT Trichy, arthanareeg@nitt.edu	2. Dr. C. Siva, SRMIST
Research Institute,		



Course	21NTC2111 Cours	MATERIAL CHARACTERISATION LABORATORY	Course		PROFESSIONAL CORE	L	Τ	Р	С	
Code	21NTC311L Name	MATERIAL CHARACTERISATION LABORATORY	Category	U	PROFESSIONAL CORE	0	0	6	3	

Pre-requisite Courses	Ni	Co- requisite Courses	NI	ressive urses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR): The purpose of learning this course is to:	W	4			Progr	am Ou	ıtcome	s (PO	)					rogram
CLR-1:	utilize X ray material characterization techniques to analyze their morphological, structural and chemical behavior	1	2	3	4	5	6	7	8	9	10	11	12		pecific itcomes
CLR-2:	R-2: introduce spectroscopy techniques and understand electronic transition			of	SI					Work		e Se			
CLR-3:	introduce advance spectroscopy tec <mark>hniques</mark>	Knowledge	alysis	sign/development of	estigations problems	Usage	ъ		L.	Μ		inance	б		
CLR-4:	7			udoli	estig	l Us	ır and	∞ >		Team	Įį.	∞	aming		
CLR-5:			Æ	deve	≥ ×	Tool	engineer ety	ronment a	١. ١	<u>8</u>	Communication	Mgt.	g Le		
		ineering	roblem	ign/	anduct in complex	Modern To	et el	io i	S	ndividual	חשר	Project	Long	7	)-2 )-3
Course C	Outcomes (CO): At the end of this course, learners will be able to:	Engi	Pro	Des	Conduct i	Moc	The	Enviror Sustain	Ethics	ngi	Sol	Proj	Life	PSO-1	PSO-2 PSO-3
CO-1:	acquire knowledge on different types of crystal structure and analyze it through X- Ray techniques	3	3	ill of	- 1	-	1	-		-	-	-	-	3	3 -
CO-2:	analyze materials using spe <mark>ctroscop</mark> y technique	3	3	100		-		-		-	-	-	-	-	2 -
CO-3:	<b>D-3:</b> gain knowledge on advance spectroscopy techniques		134	- Zi-	7	_	-	-		-	-	-	-	3	- 3
CO-4:	-4: acquire knowledge on glass transition temperature		-		3.5	_	_	-		-	-	-	-	2	- 3
CO-5:			3	51	h _	_		-		-	-	-	-	2	- 3

Practice		90 Hour
Lab 1:	XRD to determine lattice parameters for 3 different crystals	
Lab 2:	Determination of mineral concentration using XRF spectrometer for metal oxide / sulfide nanoparticles synthesized by chemical precipitation method	
Lab 3:	Determination of the wavelength absorbance, particle size, and band gap using UV-Vis spectroscopy of metal oxide nano thin film fabricated using dip coating / spin coating technique.	
Lab 4:	Identification of functional group using FTIR of different polymer materials	
Lab 5:	Thermal characterization: DSC, TGA, DTA, Determination of glass transition temperatures of polymer materials.	
Lab 6:	Raman Spectroscopy	
Lab 7:	Preparation of metal/alloy/metal oxide samples and determination of microstructure using SEM.	
Lab 8:	Preparation of metal/alloy/metal oxide samples and determination of composition using TEM	
Lab 9:	Preparation of metal/alloy/metal oxide thin films and determine the surface roughness using AFM.	
Lab 10:	Preparation of metal/alloy/metal oxide samples and determination of composition using EDS	

	1.	Sam Zhang, Lin Li, Ashok Kumar, Materials Characterization Techniques, Taylor and Francis,	3.	Introduction to Thermal Analysis, Michael Ewart Brown, Springer, 2nd Edition, 2001
Learning		1st Edition, 2008	4.	Robert Pecora, Dynamic Light Scattering, Springer, 1985
Resources	2.	Colin Banwell, Elaine McCash, Fundamentals for Molecular Spectroscopy,4th ed., Mc Graw	5.	Jürgen H Gross, Mass Spectrometry, Springer, 3rd Edition, 2017
		2016		

			Co									
	Bloom's Level of Thinking	exper	ge of first cycle iments 0%)	cycle exp	nge of second periments 0%)		eightage)	Final Examination (0% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember		20%		20%		20%	-	-			
Level 2	Understand		20%	Ref Fig.	20%		20%	-				
Level 3	Apply		40%		40%	- T	40%	-	-			
Level 4	Analyze		20%	17 July 1777	20%	-	20%	-	-			
Level 5	Evaluate	N- /	mile (i)	1.00	- A	-	V 4-	_	-			
Level 6	Create		2.24	W-912 - 1	3414			-	-			
	Total	10	0 %	100	0 %	10	0 %		-			

Course Designers	
Experts from Industry	Experts from Higher Technical Institutions Internal Experts
Dr. Soumee Chacroborty, Scientific Officer, IGCAR (soumee@igcar.in)	1. Dr. Sudhashu Sekar Pati, NIT Jamshedpur (sspati.chem@nitjsr.ac.in) 1. Dr. S. Anbumozhi Angayarkanni, SRMIST
2. Dr. Ranjini. P. Antony, IGCAR (raji.anna@gmail.com)	2. Dr. Shima dhamodharan, Kannur University, Kerela. 2. Dr.Payel Banda <mark>podaya,</mark> SRMIST
	(shimachem@kannuruniv.ac.in)

Course	O4NITC24OT	Course	MECHANICAL BEHAVIOR OF MATERIALS	Course	_	PROFESSIONAL CORE	L	Τ	Р	С
Code	21N1C3121	Name	MECHANICAL BEHAVIOR OF MATERIALS	Category	C	PROFESSIONAL CORE	3	0	0	3

Pre-requisi Courses	te N	Co- requisite Courses	Nil Progre	Nil
Course Of	fering Department	Physics and Nanotechnology	Data Book / Codes / Standards	 Nil

Course Le	earning Rationale (CLR): The purpose of learning this course is to:	W.	H	4			Progr	<mark>am</mark> Οι	ıtcome	s (PO)	)					ogram	
CLR-1:	outline the fundamentals of elasticity and plasticity		1	2	3	4	5	6	7	8	9	10	11	12		ecific come	
CLR-2:	introduce stress, strain, strengthening mechanisms		dge		of	าร		. "			Work		æ				
CLR-3:	R-3: Learn different mechanism of mechanical testing including fracture			ဟ	nent	ation	Usage	Ф	. '		_   ≽		Finance	ng			
CLR-4:				alysis	development s	ivestigations c problems		er and	t &		Team	tion	∞ర	arni			
CLR-5:				٩	deve	⊨ ഒ	<u></u>	engineer aty	Environment 8 Sustainability	. \	रू ज	ommunication	Mgt.	g Le			
		741	ineering	plem	lign/	Conduct of comple	Jern	eng ety	iron tain	S	Individual	nwu	Project	Long	7	5-5	-
Course O	utcomes (CO): At the end of this course, learners will be able to:	100	Eng	Pro	Des	Cor	Mod	The en society	Env	Ethics	Indi	Š	Proj	Life	PS0-1	PSO-2	PSO-3
CO-1:	apply the concepts of deformation behavior of materials to understand the mechanical be materials	havior of	3	3	They		1	1	-	•	-	-	-	-	3	3	-
CO-2:	appropriate the concent of strace and strain in evaluating the strength of materials and hardening		3	3	4	Ġ.	-				-	-	-	-	3	-	3
CO-3:	co-3: analyze the mechanical properties of materials using various testing methods		3	120	Ge t	-	-	-	<b>.</b>	-	-	-	-	-	3	-	2
CO-4:	O-4: acquire knowledge on fractu <mark>re mech</mark> anics, toughening mechanisms in ceramics and creep		3			7 -	-		-		-	-	-	-	3	-	3
CO-5:	O-5: obtain the knowledge on fatigue of engineering materials, strain-controlled fatigue and fatigue failure		3	3		-	7-	X	-	-	-	-	-	-	3	-	3

Unit-1 - Introduction 9 Hour

overview of the subject and fundamentals of the atomic structure and types of bonding in different classes of materials and its relation to the physical and mechanical properties, Elasticity - Analysis of stress, State of stress at a point. Normal and shear stress components. Stress components on an arbitrary plane, Principal stresses. Plane stress & Plane strain

#### Unit-2 - Hooke's Law and Elastic Behaviour

9 Hour

Generalized Hooke's law, Atomic equivalent of Hooke's law, Elastic behavior of anisotropic and isotropic materials. Plastic deformation in single & polycrystalline, semi crystalline materials, strengthening mechanisms in solids, Work hardening, Solid solution strengthening, Grain boundary strengthening, Particle hardening, High temperature deformation of amorphous; crystalline materials

#### Unit-3 - Mechanical Testing

9 Hour

A review, Common states of stress in real life, Tension, Indentation, Compression, Torsion, Bending, Fracture of solids/Fracture mechanics - Linear elastic stress field in cracked bodies - Crack deformation modes, Singular stress field and displacement fields Stress intensity factor solutions - Crack growth based on energy balance - Griffith's criterion for brittle fracture - Strain energy release rate, Stress intensity factor equivalence - Crack stability, R curves

#### Unit-4 - J Integral Concepts

Critical stress intensity factor fracture criterion - Fracture criterion - Experimental determination of fracture toughness (KIC) - Non-linear fracture - Toughening mechanisms (in ceramics). Creep, mechanisms of creep, Creep of pure metals, solid solutions, MMCs, Creep of ceramics and polymers, creep asymmetry. Superplasticity in materials

#### Unit-5 - Fatigue of Engineering Materials

9 Hour

Characteristics of fatigue fracture -Fatigue crack propagations laws, Strain controlled fatigue, Fatigue failure models - Fatigue life calculations, High cycle fatigue design- Surface fatigue failure models- dynamic contact

Learning	
Resources	

- 1. Thomas H Courtney, Mechanical behavior of materials, Waveland Press, 2nd Edition, 2005.
- 2. R. W. Hertzberg, Deformation Behaviour and Fracture Mechanics of Engineering Materials, John Wiley & Sons, 2020
- Marc Meyers, and Krishna Chawla, Mechanical behavior of materials, Cambridge, University Press, 2009.
- 4. William F. Hosford, Mechanical Behavior of Materials, Cambridge, University Press, 2010
- 5. D. Hull and D.J. Bacon, Introduction to Dislocations, Butterworth-Heinemann; 5th ed., 2011
- 6. G.W. Dieter, Mechanical Metallurgy, TMH, 3rd ed, 2017

			Continuous Learning Assessment (CLA)								
	Bloom's Level of Thinking	CLA-1 Avera	mative age of unit test 50%)	Life-Lonç CL	g Learni <mark>ng</mark> _A-2 0%)	Summative Final Examination (40% weightage)					
	/ /	Theory	Practice	Theory	Practice	Theory	Practice				
Level 1	Remember	20%	4.50	20%	- A- TO	20%	-				
Level 2	Understand	20%	10 S 10 S 10 S	20%	A 27.7	20%	-				
Level 3	Apply	40%	20 mg 27%	40%		40%	-				
Level 4	Analyze	20%		20%	(-2 T	20%	-				
Level 5	Evaluate	- A-	ALTH WATER OF	1000		-	-				
Level 6	Create	-	Charles To the Control	THE PARTY			-				
	Total	10	00 %	. 10	00 %	10	0 %				

Course Designers	
Experts from Industry	Experts from Higher Technical Institutions Institutions Internal Experts
1. Dr.Gaurav Singh, Engineering Lead, Infosys,	1. Dr. Eswara Prasad, IIT Indore, eswar@iitm.ac.in 1. Dr. Kiran Mangalampalli, SRMIST
gauravsingh90@gmail.com	
2. Dr. Sunil Varughese, CSIR-NIIST, Tridendrum,	2. Dr. Rajesh K, rajeshk@iith.ac.in 2. Dr. Payel Bandyopadhyay, SRMIST
s.varughese[at]niist.res.in	

Course	21NTC313T Course	ELECTROCHEMISTRY AND CORROSION	Course	_	PROFESSIONAL CORE	Г	Τ	Р	С	
Code	Name	ELECTROCHEINISTRY AND CORROSION	Category	C	PROFESSIONAL CORE	3	1	0	4	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

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Course L	Learning Rationale (CLR): The purpose of learning this course is to:	111	4			Prog	am Oı	ıtcome	s (PO	)					gram
CLR-1:	outline the fundamentals of electrochemistry and corrosion	1	2	3	4	5	6	7	8	9	10	11	12		ecific comes
CLR-2:	illustrate the kinetics of corrosion	dge		of	SI		. "			Work		8			
CLR-3:	introduce different forms of corrosion	1 (1)	S	nent	estigations roblems	Usage	ъ	10 7		M W		Finan	ning		
CLR-4:	explain the principles of prevention & protection of corrosion	Knowle	alysis	velopment of	estig orobl		r and	∞ ×	h.	Team	ig	∞ర	ä		
CLR-5:	introduce the concepts of corrosi <mark>on and e</mark> lectrochemistry in biological systems	ering	A	gn/deve	> -	Tool	engineer sty	ment		<u>a</u>	mmunication	Mgt.	ng Le		
		9	roblem	figi/	nduct in complex	dern T		io i	S	ndividual	l II	roject	Long	7 3	7 2
Course C	Outcomes (CO):  At the end of this course, learners will be able to:	Engi	Prof	Des	of or	Moc	The	Env Sus	Ethi	ln j	Col	Proj	Life	PSO.	PSO
CO-1:	apply the principles of electrochemistry	3		2	-	-	-7	-		-	-	-	-	3	
CO-2:	analyze the corrosion proces <mark>s with e</mark> mphasis on its kinetics	3		2	- 19	-	4	-	-	-	-	-	-	3	- 3
CO-3:	gain knowledge on different forms of corrosion	.3	de rese	42-	13	_	-	<i>-</i>		-	-	-	-	3	- 3
CO-4:	acquire knowledge on prevention & protection of corrosion	3	2	2	-	_	-	- 1		-	-	-	-	-	3 3
CO-5:	utilize the concepts of corros <mark>ion and</mark> electrochemistry for bio applications	3	20	2	7 -	-		-	-	-	-	-	-	-	3 3

#### Unit-1 - Principles of Electro-Chemistry

12 Hour

Electrode Potential, Reference Electrode, Half-cell reaction, Nernst's equation, Application of Thermodynamics to Feasibility of corrosion of metals and alloys in various environments, Pourbaix diagram of common metals, Electrolytes, potentiometric and conductometric titration, Debye-Huckel theory of strong electrolytes, transport of ions in solution: electrolytic conduction, Debye-Huckel-Onsager treatment of the conductance of strong electrolyte and its limitations, the electrical double layer,

#### Unit-2 - Kinetics of Corrosion

12 Hour

Polarization: Activation, Concentration and Resistance Polarization, Overvoltage, Basics of electrodics, rates of simple electrode reactions, elementary electron electrode process, Butler-Volmer equation, exchange current density and symmetry factor, polarisable and non-polarisable electrodes Tafel's Equation, Corrosion rate determination by Tafel extrapolation and Linear polarization methods, Passivity and passivity breakdown, Cyclic polarization, Evan's diagram, Practical applications of polarization diagrams

#### Unit-3 - Forms of Corrosion

12 Hour

Uniform attack, Galvanic, Crevice, pitting, Intergranular, Erosion corrosion, Stress induced Corrosion: SCC, CF, HIC, Testing slow strain rate and Fracture mechanics K 1C

#### Unit-4 - Principle of Prevention and Protection of Corrosion

12 Hour

Anodic protection, Cathodic Protection, Application of Inhibito<mark>rs, Organic c</mark>oating and paints, Metallic coating, Anodizing, phosphating, Chro<mark>mate coating</mark>, Atmospheric corrosion & Oxidation at elevated temperature, Factors affecting atmospheric corrosion and remedy, doping of p and n type metallic oxide, various kinetic laws of Oxidation,

#### Unit-5 - Microbial Corrosion

12 Hour

Accelerated degradation of metals in presence of Aerobic and Anaerobic microorganisms, Corrosion for Beneficial purpose: Introduction to Fuel cell and Battery. Bioelectrodics - membrane potentials, electrochemical communication in biological organisms, enzymes as electrodes, electrochemical sensors, electrochemical biosensors.

	1.	E.E. Stansbury, R.A. Buchanan, Fundamentals of Electrochemical Corrosion, ASM
Learning		International, 2000
Resources		Nestor Perez, Electrochemistry and Corrosion Science, Springer, 1st edition, 2004
	3.	D. R. Crow, Principles and Applications of Electrochemistry, 4th edition, 2017

- 4. Physical Electrochemistry: Fundamentals, Techniques, and Applications, Noam Eliaz, Eliezer Gileadi, 2nd Edition, 2018
- 5. E McCafferty, Introduction to Corrosion Science, Springer-Verlag New York, 1st Edition, 2010
  6. Zaki Ahmad, Principles of Corrosion Engineering and Corrosion Control, Elsevier, 2006

earning Assessm	Bloom's Level of Thinking	Form CLA-1 Averag	ative ge of unit test	CL	Learning A-2 %)	Summative Final Examination (40% weightage)					
	_	Theory	Practice	Theory	Practice	Theory	Practice				
Level 1	Remember	20%	- 4 - 4	20%	2	20%	-				
Level 2	Understand	20%	A CONTRACTOR	20%	- A-	20%	-				
Level 3	Apply	40%	20 E 10 E 10	40%		40%	-				
Level 4	Analyze	20%	N. J. St. 1777	20%		20%	-				
Level 5	Evaluate			- Table 1	1 - 2	<u> </u>	-				
Level 6	Create			3414		-	-				
	Tot <mark>al</mark>	100	)%	100	) %	100	0 %				

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Anju VP, Carborandum Universal Ltd., Cochin	1. Prof. Santosh Haram, Savitribai Phule Pune University, Pune	1. Prof. Sasidharan, SRMIST
2. Dr. Santoshkumar D. Bhat, CSIR-CECRI	2. Prof. Kodandaraman, IIT Madras	2. Dr. Venkatesh P <mark>rasad B</mark> hat, SRMIST



Course	21NTC2151 Course	MAGNETISM AND MAGNETIC MATERIALS	Course	C	PROFESSIONAL CORE	L	Т	Р	С	
Code	Name Name	MAGNETISM AND MAGNETIC MATERIALS	Category	C	PROFESSIONAL CORE	2	0	2	3	

Pre-requisi Courses	te N	Co- requisite Courses	Nil Progre	Nil
Course Offering Department		Physics and Nanotechnology	Data Book / Codes / Standards	 Nil

Course Lo	earning Rationale (CLR): The purpos	e of le <mark>arning this co</mark> urse is to:	11	4			Progr	am Oı	itcome	s (PO	)					ograr	
CLR-1:	outline the fundamentals of magnetostate	ics <mark>and magnet</mark> ism in materials	1	2	3	4	5	6	7	8	9	10	11	12		pecifi tcom	
CLR-2:	illustration and overview of the basics of	theories and postulates in magnetism	dge		o	SL		. "			or S		9				
CLR-3:	introduce about the various phenome <mark>na</mark>	in magnetism and magnetic materials	Knowlec	S	nent	estigations roblems	Usage	ъ	. 1		am W		nan	Бū			
CLR-4:	explaining magnetization and mag <mark>neto t</mark>	<mark>rans</mark> port phenomena		alysis	velopment	estig		r and	× ×	h.	Teal	ation	% ⊢	arni			
CLR-5:				A	/deve	t inv	Tool	engineer aty	ment ability		<u>∞</u>	nica	Mgt.	ng Le			
			ineering	plem	ign/e	nduct ir omple:	dern	eng ety	ironi	S	Individual	mmunic	roject l	으	7	0-2	80-3
Course O	utcomes (CO): At the end	of this course, learners will be able to:	Eng	Pio	Des	Con	Moc	The	Env Sus	Ethics	İpu	Sol	Proj	Life	PSC	PSC	PSC
CO-1:	gaining knowledge about the <mark>fun</mark> dament	als of magnetostatics and magnetism in materials	3	- 2		-	-	-7	-		-	-	-	-	3	2	-
CO-2:	developing through understa <mark>nding o</mark> n th	e basics of theories and postulates involved in magnetism	3	2	an Talk	7-19	-	4	-	-	-	-	-	-	3	2	-
CO-3:	CO-3: gaining knowledge about the phenomena involved in magnetism and magnetic materials		3	2	1.0	13	-	-	7 -	-	-	-	-	-	3	2	3
co-4: acquiring knowledge and sound understanding about advanced magnetization and magneto transpor		3		112	2	-	-	-		-	-	-	-	2	2	3	
CO-5:	O-5: utilizing knowledge and understanding of magnetic properties for innovative applications viz. Spintronic		3	2		2	-	0	-	-	-	-	-	-	2	2	3

Unit-1 -

Magnetic force and fields, Fields due to cu<mark>rrent, Ma</mark>gnetic dipole moment of a magnetic dipole, Lorentz Law of force, Magnetic field intensity – Biot–savart Law Application of Biot–savart Law: Magnetic field (i) Due to steady current in long straight wire, (ii) Near a straight current filament of finite length, (iii) Interaction between two parallel long current wires, (iv) Along the axis of circular coil, and (v) Helmholtz galvanometer; Ampere's Law – Magnetic field due to straight conductors, circular loop, infinite sheet of current – Magnetic flux density (B) – B in free space; Magnetization –Boundary conditions for Magnetic field Magnetic Potentials (Scalar and Vector Potential), Magnetic dipole moment, Maxwell's equations and magnetic field calculations, Magnetostatic energy and forces

Lab 1: Introduction to the laboratory, Lab 2: Determination of horizontal component of earth magnetic field-field along the axis of the coil

Unit-2 - 12 Hour

Classical and quantum mechanical model of magnetic moment of electrons, Magnetic properties of free atoms, Classification of magnetic materials, Theories of Diamagnetism, Theories of Paramagnetism, Theories of Ferrimagnetism, Theories of Ferrimagnetism, Theories of ordered magnetism, Quantum theory of magnetism: electron-electron interactions, Localized electron theory, Itinerant electron magnetism

Lab 3: Magnetic domain imaging using magnetic force microscopy (MFM), Lab 4: Determination of magnetic moment and ratio of magnetic moments by Searles vibration magnetometer method

Magnetic Interactions and Magnetic Couplings. Origin of exchange interaction, Direct exchange interactions, Indirect exchange interactions, Double exchange interaction, Anisotropic exchange interaction, Magnetization Reversal by Spin Rotation, Magnetization Reversal by Wall Motion Magnetic Annealing, Magnetic Irradiation, Magnetostatic Energy and Domain Structure (Uniaxial and Cubic Crystals), Magnetization in Low Fields. Magnetization in High Fields

Lab 5: Magnetization Reversal curve recording using magneto- optical Kerr effect (MOKE) Lab 6: Magnetic susceptibility measurement of nanomaterials

Unit-4 -

Magnetic Domain theory, Bloch and Neel Wall theory, Magnetic Domain wall pinning, Spin Waves and Magnons, Magnetic anisotropy, Exchange Anisotropy, Thin Film and Multilayers Magnetoresistance (MR), Giant Magnetoresidence (GMR), Tunnel Magnetoresistence (TMR), Superparamagnetism, Single-Domain vs Multi-Domain Behavior, Zero-field-cooled (ZFC), field-cooled (FC) curves and Blocking temperature Spintronics, Magnetorestriction; Spin glass, Heisenberg and Ising models, Magnetic Resonance, Ferromagnetic Resonance, Nuclear Magnetic Resonance, Magnetic Recording, Perpendicular Recording Lab 7: Magnetization Reversal curve recording using Vibrating sample magnetometer (VSM)

Unit-5 - 12 Hour

Magnetic shielding, Faraday cage, Faraday balance magnetometer, AC susceptometry (ACS), Torque magnetometry, Vibration sample magnetometer (VSM), Magneto-optical Kerr effect (MOKE), Magnetic Forcer Microscopy (MFM), Magnetic circular dichroism (MCD), Superconducting quantum interference device (SQUID) magnetometer, Experimental method in low temperature.

Lab 8: Magnetic Anisotropy measurement using magneto-optical Kerr effect (MOKE)

Learning Resources	2.	S. Blundell, Magnetism in Cond <mark>ensed Ma</mark> tter (OUP,2001) J. M. D. Coey, Magnetism and Magnetic Materials (CUP,2012) N. Spaldin, Magnetic Materials: Fundamentals and Applications (CUP,2012,2nd ed)	5.	B.D. Cullity, C.D. Graham, Introduction to Magnetic Materials (Wiley, 2nd ed.,2008) H. Zabel and S. D. Bader (Eds.), Magnetic Heterostructures (Springer,2008) A Planes L.Ma~nosa ASaxena (Eds.), Magnetism and Structure in Functional MaterialsSpringer,2005
	υ.	14. Opalain, magnetic materials. Landamentals and Applications (OOL, 2012, 2nd ed)	U.	A Flaires E. Ma 103a A Saheria (Eus.), Magnetisin and Structure III i unctional Materials Springer, 2000
			10.65	

Learning Assessm	nent		J / .		71 - 677						
	Bloom's Level of <mark>Thinking</mark>	n	Formative CLA-1 Average of ui (45%)	1884 B. C.		Learning A-2 %)	Summative Final Examination (40% weightage)				
		CAL	Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember		20%	38 Sept. 1917	7 10 10 10 10	20%	20%	-			
Level 2	Understand		20%	1. The Control of the	1、柳枝类(3)类者。	20%	20%	-			
Level 3	Apply		40%	90.7°C 2°C		40%	40%	-			
Level 4	Analyze		20%	1 mg - 466 N	200	20%	20%	-			
Level 5	Evaluate				1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1		-	-			
Level 6	Create							-			
	Total Total		100 %	10.77	100	0 %	10	0 %			

Course Designers		_ \ \
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Muhammad Shahid Anwar, CSIR - Institute of Minerals and	1. Prof. K. Sethupathi, IITM, ksethu@iitm.ac.in	1. Dr.Jitend <mark>ra Kumar</mark> Tripathi, SRMIST
Materials Technology, Bhubaneswar,shahid@immt.res.in		
2. Dr. Ashutosh Rath, CSIR - Institute of Minerals and Materials	2. Dr. Dinesh Kumar Shukla, UGC-DAE CSR, Indore,	2. Dr. Jaivardhan Sinha, SRMIST
Technology, Bhubaneswar, ashutosh@immt.res.in	dkshukla@csr.res.in	

Course	21NTC316T	Course	GLASS AND CERAMIC MATERIALS	Course	_	DDOEESSIONAL CODE	L	Т	Р	С
Code	2111103101	Name	GLASS AND CERAMIC MATERIALS	Category	U	PROFESSIONAL CORE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is	s to:	11	4			Progr	am Ou	tcome	s (PO	)					rogram
CLR-1:	gain knowledge on import	ance of Glasses and their formation	1.0	1	2	3	4	5	6	7	8	9	10	11	12	_	pecific itcomes
CLR-2:	emphasize the significand	e of transpor <mark>t and mech</mark> anical properties o	of Glasses	lge		of	SI	-	. ".			Work		9			
CLR-3:	explore the ceramic-base	d materials <mark>and their c</mark> haracteristics	- 10 m 3 ft s -	Knowledge	S	Jent	stigations	Usage	ъ			Μπ		Finan	В		
CLR-4:	understanding the micros	tructures <mark>of Ceram</mark> ics	ATTACA		alysis	velopment of	estig		r and	∞ ~ >	N.	Team	ion	≪ ≪	arni		
CLR-5:	study of functional proper	ties of c <mark>eramics</mark>		ering	An	(a)	t inve	<u>P</u>	engineer ety	ment ability		<u>a</u> &	Sommunication	Mgt.	ong Le		
			and the state of t	9	roblem	ign/d	nduct ir omple	dern		iron <mark>tain</mark>	S	ndividual	nmu	Project		7	)-2 )-3
Course C	Outcomes (CO):	At the end of this course, learners w	ill be able to:	Engi	Pro	Des	Se	Mo	The	Env S <mark>us</mark>	Ethics	la	ပ်	Pro	Life	PSO-1	PSO-2 PSO-3
CO-1:	introduce the structure an	d fo <mark>rmation</mark> for glasses	12 10 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	2	- 5	3	-	-	-7	-		-	-	-	-	-	
CO-2:	explore the functional pro	pe <mark>rties of g</mark> lass-based materials		<i>i</i>	2	40 745	3	-	4	-		-	-	-	-	3	-   -
CO-3:	learning about ceramic-ba	ase <mark>d mater</mark> ials and their structures		2	1772	3	1.3	_	-	-		-	-	-	-	-	
CO-4:	knowing the importance of	f <mark>microstru</mark> ctures on Ceramics		3 -	1		2	_	-	-		-	-	-	-	2	-   -
CO-5:	understand the functional	an <mark>d mech</mark> anical properties of Ceramics		3	4		2	_		-		-	-	-	-	-	

Unit-1 - Introduction to Glass

Definition and Historical Summary, Structure of Glass, glass melting, Structure of Special Melts and Glasses, Composition of Glass, Glass Formation, Crystallization and Liquid Immiscibility, Viscosity of Glass Forming Melts, Density and Thermal Expansion

#### Unit-2 - Transport Properties of Glasses

9 Hour

Transport Properties, Mechanical Properties, Optical and Magnetic Properties, Water in Glasses and Melts, Thermal Analysis of Glasses, Glass Technology, Compositions and Properties of Commercial Glasses, Doped Vitreous Silica, Oxyhalide Glasses

#### Unit-3 - Structural Properties of Glasses

9 Hour

Introduction, Ceramic Processes and Products, Characteristics of Ceramic Solids, Structure of Crystals, Structure of Glasses, Structural Imperfections, Surfaces, Interfaces, and Grain Boundaries, Atom Mobility

Unit-4 - Microstructure of Glasses

9 Hour

Development of Microstructure in Ceramics, Ceramic Phase Equilibrium Diagrams, Phase, Transformation, Glass Formation and Glass-Ceramics, Reactions with and between Solids. Grain Growth, Sintering and Vitrification, Microstructure of Ceramics.

#### Unit-5 - Physical Properties of Glasses

9 Hour

Thermal Properties, Optical Properties, Plastic Deformation, Viscous Flow and Creep, Elasticity, Anelasticity and Strength, Thermal and Compositional Stresses, Electrical Conductivity, Dielectric Properties, Magnetic Properties

Learning
Resources

- 1. Textbook of Polymer Science, Fred W Billmeyer, Wiley, 3rd Edition, 1984
- Fundamentals of Polymer Engineering, Anil Kumar, Rakesh K Gupta, Marcel Dekker Inc., 2nd Edition, 2003
- 3. Mc Crum, Principles of polymer Engineering, 2nd Edition, Oxford, 2001.
- 4. Fundamentals of Inorganic Glasses, Arun Varshneya John Mauro, Elsevier, 3rd Edition, 2019
- 5. Introduction to Ceramics, William David Kingery, H. K. Bowen, Wiley, 2nd edition, 1976
- Introduction to Glass Science and Technology, James E Shelby, Royal Society of Chemistry, 3rd edition, 2020
- 7. Fundamentals of Ceramics, Michel Barsoum, CRS press, 2nd edition, 2020
- 8. HullD., and Clyne W., An Introduction to Composite Materials, Cambridge University Press, 2nd Edition, 2017
- 9. Jones R.M., "Mechanics of Composite Materials", Taylor & Francis, 2nd Edition, 2018

earning Assessm	iciit		Continuous Learning	g Assessment (CLA)		2				
	Bloom's Level of Thinking	CLA-1 Avera	native ge of unit test 0%)	Life-Long CL	Learning A-2 )%)	Summative Final Examination (40% weightage)				
	/ 6	Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	15%	19 F 19 F 19	15%		15%	-			
Level 2	Understand	25%	- SOLE 978	25%		25%	-			
Level 3	Apply	30%		30%	- C- 2	30%	-			
Level 4	Analyze	30%		30%		30%	-			
Level 5	Evaluate		Charles T. Allen and	- 12			-			
Level 6	Create		1 1 1 1 2 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	1 - 1 1 de la		-	-			
	Total	10	0%	100	0 %	100	0 %			

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. P. Sudhakara, CLRI – CSIR, Jal <mark>andhar,</mark>	1. Dr. Kothandaraman Ramanujam, IITM Chennai, rkraman@iitm.ac.in	1. Dr. N. Angeline Little Flower. SRMIST
sudhakarp@clri.res.in		
2. Dr. Sudhakar Selvakumar, CSIR-Central Electrochemical	2. Dr.Arthanreeswaran, NIT, Trichy,arthanareeg@nitt.edu	2. Dr. C. Siva, SR <mark>MIST</mark>
Research Institute, ssudhakar79@gmail.com	The state of the s	V 4 3



Course	24NTC4441 Course	NANOINDENTATION AND NANOTRIBOLOGY	Course	)	PPOEESSIONAL CORE	L	Т	Р	С	
Code	Name Name	NANOINDENTATION AND NANOTRIBOLOGY	Category	C	PROFESSIONALCORE	0	0	6	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	rogressive Courses	Nil
Course Offerin	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course Le	earning Rationale (CLR): The purpose of learning this course is to:	11	4			Progr	am Ou	ıtcome	s (PO	)					rogram
CLR-1:	outline the fundamentals of elastic and plastic deformations	1	2	3	4	5	6	7	8	9	10	11	12	_	pecific utcomes
CLR-2:	introduce the nanoindentation and theory	dge		of	SL	-	. "			Work		9			
CLR-3:	learn the data analysis and factors affecting indentation results	Knowlec	ဟ	nent	ation	Usage	ъ	· ·				Finance	рu		
CLR-4:	explain the time-dependent deform <mark>ation me</mark> chanisms, and mechanical behavior of soft materials		Analysis	lopr	investigations ex problems		er and	y t S	h.	Team	tion	∞	arning		
CLR-5:	introduce the tribology principles at nanoscale contacts and applications	ering	m An	n/development of	nduct invi complex p	n Tool	engineer sty	nment nability	1	ual &	ommunication	t Mgt.	Long Le		
Course O	utcomes (CO):  At the end of this course, learners will be able to:	Engine	Problem	Design solutio	Conduct of comple	Modern To	The eng	Enviro Sust <mark>ai</mark>	Ethics	Individual	Comm	Project	Life Lo	PSO-1	PSO-2 PSO-3
CO-1:	apply the concepts of deformation behavior of materials to understand the mechanical behavior of materials	3		3		-	1	-	-	-	-	-	-	-	3 -
CO-2:	appreciate the instrumented nanoindentation technique in quantifying the mechanical properties of materials	3	i Trigge	, MF	Ġ.	-	(	١.	-:	-	-	-	-	-	3 -
CO-3:	analyze the indentation data and identify the factors affecting mechanical properties	3	-	3	4	-	-	- 1	-	-	-	-	1	-	3 -
CO-4:	acquire knowledge on mechanical deformation of polymers and the importance of time-dependent mechanical characterization	3		-51	Z .		Č	-		-	-	-	-	-	3 -
CO-5:	obtain the knowledge on nan <mark>oscale tr</mark> ibology contacts and utilize it in various applications	3		3	-	-	-	-	-	-	-	-	-	-	3 -

Practice		90 Hour
Lab 1:	Evaluation of mechanical properties of glass and ceramics - ph curve analysis (ISO 14577/ASTM E 2546)	
Lab 2:	Evaluation of mechanical properties of polymer - ph curve analysis (ISO 14577/ASTM E 2546)	
Lab 3:	Evaluation of mechanical properties of metal - ph curve analysis (ISO 14577/ASTM E 2546	
Lab 4:	Evaluation of mechanical properties of thin film - ph curve analysis (ISO 14577/ASTM E 2546	
Lab 5:	Demonstration of indentation size effects	
Lab 6:	Demonstration of effect of indenter geometry on mechanical properties	
Lab 7:	Demonstration of loading rate effect on mechanical properties	
Lab 8:	Demonstration of substrate effect on mechanical properties in case of thin films	
Lab 9:	Extraction of stresses-strain curves from nanoindentation data	
Lab 10:	Study of creep and relaxation from quasi-static nanoindentation technique	
Lab 11	Nano DMA analysis to find storage and loss modulus	
Lab 12	Nano/micro scratch experiment to measure coefficient of frinction	
Lab 13	Quantification of wear volume using nano/micro tribology (ASTM G 99	

Learning	1. 2.	Introduction to contact mechanics, Anthony C Fischer-Cripps, Springer, 2nd Edition, 2007 Nanotribology and Nanomechanics: An Introduction, Bharat Bhushan, Springer, 2nd Edition,	Nanoindentation, Anthony C Fischer-Cripps, Springer, 2nd Edition, 2004. C. Mathew Mate, "Tribology on the Small Scale" Oxford University Press, 2008.Bharat
Resources		2008	Bhushan," Principles and Applications to Tribology", Wiley Publication, 2013.

			Co							
	Bloom's Level of Thinking	exper	ge of first cycle iments 0%)	cycle exp	ge of second periments (%)		eightage)	Final Examination (0% weightage)		
	4	Theory	Practice	Theory	Practice	Theory	Practice Practice	Theory	Practice	
Level 1	Remember	- 4	20%	-	20%	7.1	20%	-	-	
Level 2	Understand		20%	- A - A	20%	~ )	20%	-		
Level 3	Apply	-	40%	ME TOWN	40%		40%	-	-	
Level 4	Analyze	1	20%	\$4.1 THE REAL PROPERTY.	20%		20%	-	-	
Level 5	Evaluate	7~		N. J. Sec. 2787		- /	-	-	-	
Level 6	Create	- A	salar (i)	3.77	A STATE OF THE STA	- \	T	<b>.</b>	-	
	Total	10	0 %	100	) %	10	0 %		-	

Course Designers		9 3 7.
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Gaurav Singh, Engineering Lead, Infosys,	1. Dr. Eswara Prasad, IIT Indore, eswar@iitm.ac.in	1. Dr. Kiran Manga <mark>lampalli,</mark> SRMIST
gauravsingh90@gmail.com		
2. Dr. Krishna Muvvala, Saint Gobain	2. Dr. Rajesh K, rajeshk@iith.ac.in	2. Dr. Payel Bandy <mark>opadhya</mark> y, SRMIST

Course	24NTC/412T	Course	COET MATTED	Course	_	DDOEESSIONAL CODE	L	Τ	Р	С
Code	2111104121	Name	SOFT MATTER	Category	C	PROFESSIONAL CORE	3	0	0	3

Pre-requisite		Co- requisite		Progressive		
Courses	Nil	Courses	Nil	Courses	Nil	
Course Offe	ring Department	Physics and Nanotechnology	Data Book / Codes / Standa		Nil	

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	11	4			Progr	<mark>am O</mark> ı	utcome	s (PO	)					ogran	
CLR-1:	introduction to soft matter		1	2	3	4	5	6	7	8	9	10	11	12		ecific	
CLR-2:	explaining the concept of b	pasics of poly <mark>mer materi</mark> als	0)		1/	of		ciety			~						
CLR-3:	introduce the ways to cha various semiconductor dev	aracterize the polymer matters for various applicarionsnd understand the rices	Knowledge	S	elopment of	stigations lems	Usage	S			m Work		Finance	ng			
CLR-4:	explain the concept of solu	tion pr <mark>ocessed t</mark> hin film formation and their characterizations	Α̈́	alysis	lopr	vestigat oblems	I Us	er and	y t		Team	tion	∞ర	earning			
CLR-5:	introduce the physical prop	pertie <mark>s of the s</mark> oft matter for various practical applicataions	ering	٩	\ \delta	.⊑ ₫	희은	engineer	Environment 8 Sustai <mark>nabi</mark> lity		<u>∞</u>	ommunication	Mgt.				
	•		nginee	oblem	ign/de	70	ern	enĝ	ironi taina	SS	ndividual	חשונ	roject l	Long	7	-5	-3
Course C	outcomes (CO):	At the end of this course, learners will be able to:	Eng	Prof	Des	Com	Mod	The	Envi	Ethics	lpdi	Com	Proj	Life	PS0-1	PS0-2	PSO-3
CO-1:	understanding the basic co	on <mark>cept and</mark> mechanism soft matter materials properties	2	10	R Sy		-	1	-	-	-	-	-	-	2	-	-
CO-2:	understanding soft matter l	b <mark>ased thin</mark> film for various applications	3	-	1		-	7	-		-	-	-	-	-	2	-
CO-3:	gain knowledge on various	state of soft matter and their application to various practical applications	1.57	2	J.	7	-	-	-		-	-	-	-	2	-	-
CO-4:	acquire knowledge on vario	o <mark>us physi</mark> cal properties of the soft matter	3	-	1	2.2	_	-	-	-:	-	-	-	-	-	2	-
CO-5:	utilize the concepts soluti	io <mark>n based</mark> thin film formation in the soft matter materials for commercia	2	3		-	-	9	-	-	-	-	-	-	-	2	-

Unit-1 – Definition 9 Hour

Soft matter definition, Overview of the main classes, Self-assembly versus self-organization, Dynamic versus static self-assembly, Central role of Entropy, Energy scales compared to covalent bonding energies, Van der Waals interactions: three types of attractive interactions and steric repulsion, Hamaker constant and its application, Hydrogen bonds, Hydrophobic effect, Aromatic interactions, Ionic interactions and ion dissolution, Electric double layer, Models for the electric double layer, ζ potential and the hydrodynamic radius, Hamaker constant, Entropy, Poisson-Boltzmann theory and concepts Debye screening length and ionic strength, Definition of colloids and overview of main classes, Preparation of colloids, Stability of colloidal liquids: Brownian motion vs. gravity and viscosity, Exercise on hydrogen bonds, hydrophobic effect charged surfaces and ions in solution.

#### Unit-2 - Sedimentation and Centrifugation

Hour

Sedimentation and Centrifugation, Stabilization of colloids, Colloid flocculation/coagulation, DLVO Theory-introduction, Casimir Force, Poisson-Boltzmann, Colloid Synthesis, Jamming and Gelation, Percolation and its applications, Wetting/ dewetting and hydrophobicity/hydrophilicity, Capillary phenomena, Synthetic opals, Marangoni effect and Coffee Ring Effect, Life at low Reynolds number, Granular matter, Depletion attraction, Surface/interfacial tension and Ostwald ripening, Surfactant self-assembly (beginning), Supramolecular Self-Assembly of surfactants, Micelle formation and the packing parameter, Colloid crystallization, Colloid preparation and stabilization/destabilization.

Unit-3 - Colloid Preparation 9 Hour

Lab on colloid preparation and the properties of colloids, Liquid crystal's introduction, Phases (nematics, smectics, columnar phases) and their building blocks. Typical molecule structures, Nematic elasticity and director field deformations in nematics and smectics, Topological defects-introduction, Mixtures and phase diagrams, Phase transitions, Surfactant self-assembly, Topological defects, The Volterra process, Phase transitions, Landau expansion, Landau rules and symmetry considerations in liquid crystals, Glass transition, Mixtures and phase diagrams, Colloid crystallization, Optical anisotropy, Characterization: polarizing optical microscopy, Fundamentals of the microscope, Michel-Levy diagram and determination of birefringence. Use of phase plates.

#### Unit-4 - Viscous, Elastic and Viscoelastic Behaviour

9 Hour

Viscous, Elastic & viscoelastic behaviour and connection to glass transition, Nucleation and growth, Spinodal decomposition, Anisotropic viscous properties of liquid crystals, Miesowicz and rotational viscosities of nematics, Response of nematic liquid crystals to electric fields and elastic relaxation after field removal, Liquid crystal displays, Polarizing microscopy, Nematic elasticity, Liquid crystal topology, Liquid crystal viscosity, Optics of the Twisted Nematic explained using the Poincaré sphere, Cholesteric phases and their peculiar optical properties: Mauguin-type polarization guiding, Optical activity and selective reflection.

Unit-5 - Liquid Crystals 9 Hour

Surface anchoring of liquid crystals & control of the bulk director field via boundary conditions, Langmuir films, Self-assembled Monolayers, More on lyotropic liquid crystals, Vesicles, Bio membranes, Block copolymers and their self-assembly in water & without solvent, Liquid Crystal Displays (LCDs), Poincaré sphere, Twisted nematics, Cholesterics, Liquid crystal polymers/elastomers and their applications, Biological soft matter: nucleic acids and their self-assembled structures, Natural and artificial Biological soft matter, Protein self-assembly, Self-assembled monolayers, Bio membranes, Block co-polymers, Liquid crystal elastomers, Biological soft matter.

Learning	
Resources	

- Alan S. Wineman and K. R. Rajagopal, Mechanical Response of Polymers: An Introduction, Cambridge University Press, 2000 (1st Edition)
- 2. R. Byron Bird, Robert C. Armstrong and Ole Hassager, Dynamics of Polymeric Liquids, Volume 1:
- 3. Fluid Mechanics, 2nd Edition, Wiley & Sons Ltd, 1987. (2nd Edition)
- 4. Richard A.L. Jones, Soft Condensed Matter, OUP Oxford, 2002 (1st Edition).
- 5. Nhan Phan-Thien, Nam Mai-Duy, Understanding Viscoelasticity: An Introduction to Rheology, Third Edition, Springer 2017

Learning Assessme	ent			N PROPERTY.	1,442			
	Bloo <mark>m's</mark> Level of <mark>Thinkin</mark> g		Formative CLA-1 Average of un (50%)	C Maria Car	CL	Learning A-2 )%)	Final Exa	native amination eightage)
	2	23.1	Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember		15%	7.5	15%	-	15%	-
Level 2	Understand		25%		25%	J -	25%	-
Level 3	Apply		30%	and the same	30%		30%	-
Level 4	Analyze		30%		30%		30%	-
Level 5	Evaluate				/ L			-
Level 6	Create		-	- 1077	·	-4	-	-
	Total	-	100 %	1.7	100	0 %	10	0 %

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	√ Inte <mark>rnal Expe</mark> rts
Dr Bhaskar Sahu, Schneider Electric Ltd,	1. Dr. Satyajith Gupta, IIT Bhilai, satyajit@iitbhilai.ac.in	1. Dr. K. <mark>Arul varm</mark> an, SRMIST-KTR
bhaskar.sahu@se.com	I / IS VARN - FRAD TRAIN	
2. Dr.S.Paramasivam, ESAB, paramsathya@yahoo.com	2. Dr. Vijay Shinde, IIT (BHU), vijay.che@iitbhu.ac.in	2. D <mark>r.K.Mohan</mark> raj, SRMIST

Course	21NTC/12T	Course	ALLOVO: EEDDOLIG AND NON EEDDOLIG	Course	^	DDOEESSIONAL CODE	L	Т	Р	С
Code	2111104131	Name	ALLOYS: FERROUS AND NON-FERROUS	Category	U	PROFESSIONAL CORE	3	1	0	4

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	rogressive Courses	Nil
Course Offerin	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	111	Program Outcomes (PO)											rogram		
CLR-1:	gain knowledge on the fu	ndamentals of a <mark>lloy theory an</mark> d introduce iron –Iron carbide Phase diagram	1	2	3	4	5	6	7	8	9	10	11	12	_	pecific utcomes	
CLR-2: emphasize the significance of phase transformation in metals and alloys			dge		of	SI	4	. "			Work		8				
CLR-3:				S	Jent	ations	age	Ъ	. 1		am W		Finan	б			
CLR-4:			ᅙ	alysis	elopme	estig	S	r and	∞ >	h.	Теаг	ion	≪ ⊡	arni			
CLR-5:	acquire knowledge non no	on ferro <mark>us alloy</mark> s	ering							mmunication	Mgt.	g Le					
				plem	/ugi	duct	ern	er er	ng in	SS	/jg	I III	şç	l P	7	2 5	
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	Eng	Program	Desi	of Color	Mod	The	Sust	E	Individual	Con	Proje	Life	PSO	PSO-2	,
CO-1:	introduce the concept of a	illoy <mark> theory a</mark> nd apply it to Fe-C system	3	- 3	1	-	-	-7	-		-	-	-	-	-		
CO-2:	co-2: analyse the mechanism of solidification and solid-state transformation in metals and alloys		3	3	40.70	-19	-	4	-		-	-	-	-	3		
CO-3:	gain knowledge on diffusion process and various phase transformation involving diffusion process		3	el vis		3	_	_	-		-	-	-	-	-		
CO-4:	20-4: acquire knowledge on microstructural and Mechanical properties of different types of Steels		3	17.7	100	11-	2	-	-		-	-	-	-	-		
CO-5:	introduce the different types of non ferrous alloys, production microstructure and applications		3	-	.3			-	_	_	_	_	_	_	_	2 -	

Unit-1 - Alloy Theory

Alloy theory-Definition of mode of alloying, solid solutions, terminal solid solutions and intermediate phases, chemical compounds in metallic alloys, eutectic and eutectoid phase and microstructural elements in metallic alloys, Free energy-composition diagrams, Ideal and non-ideal behaviour of alloy systems, Binary and ternary phase diagrams examples, introduction to high entropy alloy Fe-C system: The Fe-Fe3Cphase diagram, Classification of Iron-Carbon alloys based on equilibrium phase diagram.

#### Unit-2 - Transformation in Metals and Allovs

12 Hour

solidification and solid-state transformation, Solidification of a pure metal, continuous growth, lateral growth, Alloy solidification – Solidification of single phase alloys-cellular and dendritic solidification; eutectic solidification, off-eutectic solidification, Peritectic solidification, Kinetics of solid-state transformation, C-curve, segregation, precipitation reaction

#### Unit-3 - Diffusional Transformations in Solids

12 Hour

Homogeneous and heterogenous nucleation, Precipi<mark>tate growt</mark>h, overall transformation kinetics – TTT and CCT diagrams, Precipitation in age hardening alloys (Aluminium-Copper alloys, Aluminium-Silver alloys), Age hardening, Spinodal decomposition, Particle coarsening, Precipitation of ferrite from austenite, cellular precipitation, eutectoid transformations-Pearlite reaction, Bainite transformation, Massive transformation, Order-disorder transformations

#### Unit-4 - Steel

12 Hour

Plain carbon steels, Terminology of plain carbon steels, Mechanical properties, Classification and main types of plain carbon steels, Characteristic microstructure of plain carbon steels, Alloyed steels, The main alloying elements of steel and their effects, effects of alloying elements on the phase diagram, the effect of alloying element on the non-equillibrium phase transformations, Main types of alloyed steels, Manganese steels, Chromium steels, Nickel steels, Recent development trends in steel, Methods to increase the strength of steels, Heat treatment principles

#### Unit-5 - Non-ferrous Metals and Alloys

12 Hour

Aluminium and its alloys, –, Classification of main types of aluminium alloys, Magnesium and its alloys, beryllium and its alloys, Titanium and its alloys, Copper and its alloys, Brasses and Bronze, Lead and its alloys, Solder Alloy, Ni and Co based superalloys

Lagraina	1.	David A Porter; K E Easterling; Mohamed Y Sherif, Phase transformations in metals and	3.	Tisza, Miklós, ed. Physical metallurgy for engineers. ASMInternational, 2001.
Learning		alloys, CRC Press, [2009]	4.	R. E. Smallman, A. H.W. Ngan, Physical Metallurgy and Advanced Materials, (Elsevier Ltd.,
Resources	2.	Sydney H. Avner, Introduction To Physical Metallurgy, Mcgraw-Hill Book Company [2017]		2007) ISBN: 978 0 7506 6906 1

Learning Assessm	nent								
			Continuous Learning	g Assessment (CLA)	*,	Summative Final Examination (40% weightage)			
	Bloom's Level of Thinking	CLA-1 Averag	ative ge of unit test %)	C	ng Learning SLA-2 10%)				
	_	Theory	Practice	Theory	Practice Practice	Theory	Practice		
Level 1	Remember	15%	-	15%		15%	-		
Level 2	Understand	25%	- 6 - 6	25%	2 - 1	25%	-		
Level 3	Apply	30%		30%	V /2- V	30%	-		
Level 4	Analyze	30%	20 TO 10	30%	( P)	30%	-		
Level 5	Evaluate	\ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \	N. A. St. 1777			-	-		
Level 6	Create				1 1 2		-		
	Tota <mark>l</mark>	100	)%	1	00 %	100	0 %		

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. R. Mythili, SO/E, IGCAR, rm@igcar.gov.in	Dr. Srinivasa Rao Bakshi, Assosiate professor, IIT Madras,     sbakshi@iitm.ac.in	1. Dr.Ravikirana, S <mark>RMIST</mark>
2. Dr. Pramod S L, Lead Engineer	Dr.Anuradha M Ashok, Associate professor,     PSGIAS,anu@psgias.ac.in	2. Dr. Suresh Perumal, SRMIST

Course	24NTC414T	Course	ENGINEEDING DIOMATEDIALS	Course	(	DDOEESSIONAL CODE	L	Т	Р	С
Code	21N1C4141	Name	ENGINEERING BIOMATERIALS	Category	C	PROFESSIONAL CORE	3	1	0	4

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	17	Program Outcomes (PO)										Program			
CLR-1:	LR-1: learning importance of biomaterials				3	4	5	6	7	8	9	10	11	12		pecific tcomes	,
CLR-2:	2: introduce processing and study of biomaterials  3: complete cell meterial interaction  8 9 5 9 9 9 9 9 9 9 9 9 9 9 9 9 9 9 9 9																
CLR-3:	explain cell material intera	action	wled		Jent	estigations roblems	age	ъ			× ×		Finance	ÐΩ			
CLR-4:	introduce polymeric and d	legradab <mark>le biomat</mark> erials	eering Knowledge am Analysis n/development of ans nct investigations nplex problems rn Tool Usage ngineer and y annent & inability tal & Team Work aual & Team Work aual & Finance at Mgt. & Finance ong Learning				arnii										
CLR-5:	introduce tissue engineeri	ng and <mark>applicati</mark> ons	ering		deve	l.≧ ×	T00	engineer sty	nment nability	. 1	<u>∞</u>	ommunication	Mgt.	g Le			
	•		9	roblem	lgi/	nduct in complex	dern To		ron	S	Individual	nuı	roject	Long	7	2 5	3
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	Engi	Prof	Des	o o	Moo	The	Sus	Ethics	lpdi	Con	Proj	Life	PSO-1	PSO-2	5
CO-1:	significance of biomaterial	is the state of th	3	-	1	-	-	-7	-		-	-	-	-	2	-	- ]
CO-2:	familiar with preparation and characterization of bio materials			2	40.00	- 19	-	4	-	-	-	-	-	-	-	2	- ]
CO-3:	gain knowledge on cell-biom <mark>aterials</mark> interaction			g 172	2	13	-	-	-		-	-	-	-	2	-	-
CO-4:	: acquire knowledge on evolv <mark>ing poly</mark> meric and biodegradable materials			4.47	2	-	_	-	-		-	-	-	-	2	-	-
CO-5:	understand tissue engineering and applications			- 2			_		-	-	-	-	-	-	2	-	-

### Unit-1 - Introduction to Biomaterials

Introduction to biomaterials; Background History; importance of biomaterials; Essential Properties of biomaterials; Materials for Biomedical Applications; essential properties of biomaterials; Metallic ceramic and polymeric implant materials; Practical Guidelines for the Experimental Measurements; Orthopedic, dental applications and Future of biomaterials

#### Unit-2 - Physical Properties

12 Hour

Processing and properties of different bio cer<mark>amic ma</mark>terials; evaluation of physical properties biomaterials; Mechanical Properties of biomaterials; novel materials for biomedical applications; Nanomaterials and nanocomposites for medical applications; Corrosion Behaviour of a biomaterials invitro; Bacterial growth and Biofilm Formation, Sintering Reactions and HA Stability, Cytocompatibility Property, Implication of Cell Proliferation

#### Unit-3 - Cell Materials

12 Hour

cell-material interactions and foreign body response; Cell signalling mechanism; Cell-environment interactions; affect cellular functions; Eukaryotic cell fate processes; Fibrous encapsulation; compatibility of biomaterials; In-vitro and In- vivo evaluation; Dissolution study, Antibacterial assessment: Kirby–Bauer disc diffusion method or antibiotic sensitivity test and spread plate method.

#### Unit-4 - Polymeric Biomaterials

12 Hour

Polymeric biomaterial, biodegradable polymeric biomaterial, Biodegradation properties of synthetic bio gradable polymers, Blood compatible materials; Surface-induced thrombosis Biomimetics; Advantages of biomimetics Bone biology: bone architecture, Bone as a Tissue, collagen, osteoblasts, osteoclasts, etc; Protein mediated cell adhesion, The blood-material interface in medical devices

#### Unit-5 - Tissue Engineering

12 Hour

Introduction to tissue engineering; Applications of tissue engineering; tissue compatibility assessment; Ethical issues; Animals experiments on biomaterials; Clinical Trials on Tissue Engineering; Scaffolding Strategies for Tissue Engineering; Biomaterials worldwide market; technology transfer and ethical issues; Standards for biomaterials and devices.

Learning Resources
Resources

- 1. Hench L. Larry, and Jones J., (Editors), Biomaterials, Artificial organs and Tissue Engineering, Woodhead Publishing Limited, 2005.
- 2. Biomaterials: The Intersection of Biology and Materials Science, Johnna Temenoff, Antonios Mikos (Pearson; 1st edition (5 February 2008)
- 3. Biomaterial's principles and applications biomaterials edited by joon b. park joseph d. bronzino, edited by joon b. park
- 4. joseph d. bronzino (CRC, 2003)
- 5. Foundations of biomaterials engineering 1st edition by Maria- Cristina Tanzi, Silvia Fare and Gabriele Candiani (Elsevier 2019)
- 6. Biomaterials Science, Buddy Ratner & Allan Hoffman & Frederick Schoen & Jack Lemons (Academic Press, 3rd Edition, 2012)

Learning Assessm	nent		COLUMN						
			Continuous Learning	0					
	Bloom's Level of Thinking	CLA-1 Aver	mative rage of unit test 50%)	Life-Long CL) (10	4-2	Summative Final Examination (40% weightage)			
		Theory	Practice	Theory	Practice	Theory	Practice		
Level 1	Remember	15%	18 P. P. P. B.	15%		15%	-		
Level 2	Understand	25%	10 July 1774	25%		25%	=		
Level 3	Apply	30%		30%	- C-2	30%	-		
Level 4	Analyze	30%	an its warn a c	30%		30%	-		
Level 5	Evaluate	-	Charles Mary and			-	-		
Level 6	Create					-	=		
	To <mark>tal</mark>	1	00 %	100	) %	100	0 %		

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Mr. K. Chandru, Medical Device Domain, HCL Technologies	1. Dr. Asifkhan Shanavas, INST, Mohali, asifkhan@inst.ac.in	1. Dr.P. Malar, SR <mark>MIS</mark> T
2. Mr. P. Aravind Mukesh, United Breweries, Bengaluru	2. Dr.Biman B. Mandal, IIT G, biman.mandal@iitg.ac.in	2. Dr. G. Devanan <mark>d, SRMI</mark> ST

# **ACADEMIC CURRICULA**

**Professional Elective Courses** 

Regulations 2021



# SRM INSTITUTE OF SCIENCE AND TECHNOLOGY

(Deemed to be University u/s 3 of UGC Act, 1956)

Kattankulathur, Chengalpattu District 603203, Tamil Nadu, India

Course	21NTE221T Course	CONCEDT OF NANOSCIENCE FOR ENGINEERS	Course _	PROFESSIONAL ELECTIVE	L	Т	Р	С	1
Code	21NTE2211 Name	CONCEPT OF NANOSCIENCE FOR ENGINEERS	Category <sup>□</sup>	PROFESSIONAL ELECTIVE	3	0	0	3	l

Pre-requisite Courses	Ni	Co- requisite Courses	NI	gressive ourses	Nil
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:		Program Outcomes (PO)												gram	
CLR-1:	understand the basic conce	pts and pheno <mark>menon of na</mark> noscience	1	2	3	4	5	6	7	8	9	10	11	12		ecific comes	;
CLR-2:	demonstrate the different ro	outes to syn <mark>thesize va</mark> rious nanomaterials	0		1	of		ciety	1		¥						
CLR-3:	explain the different principal	edge	<b>1</b>	nt of	ions	- Φ	socie			Work		Finance					
CLR-4:	introduce the various char properties of the nanomate	\Z	Analysis	evelopment	investigations problems	Usag	and	t &	l.	Team	tion	∞ర	earning				
CLR-5:	R-5: demonstrate the current real time applications using nanomaterials						Adern Tool Usage	he engineer	vironment stainability	S	ndividual &	ommunication	roject Mgt.	Long Le	<u></u>	.,	ب
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	Engineering	Problem	Design/de	Conduct	Mode	The (	Envir Susta	Ethics	ndiv	Som	Proje	Life L	PSO	PS0-2	-55
CO-1:	apply the basic concepts an	d principles of nanoscience	3		2		-	L	-		-	-	-	-	-	-	-
CO-2:	acquire knowledge on differe	ent synthesis process to prepare and fabricate nanomaterials	3		2	}-	- 7	1	-		-	-	-	-	3	-	-
CO-3:	utilize the important conc <mark>epts and</mark> phenomenon related to improve the materialistic properties of nanomaterials				ļ ,- ;	-	- 1	-	-		-	-	-	-	-	-	2
CO-4:	apply different characterization techniques to determine the properties of nanomaterials					-	l - ;	ļ	-		-	-	-	-	-	-	-
CO-5:	acquire knowledge about the	3	The s	-	-	1		-	6.	-	-	-	-	-	-		

Unit-1 - Introduction 9 Hour

Scientific Revolution; Feynman's Vision – Nanoscience – Nanotechnology; Ancient Nanotechnology – Lycurgus Cup – Damascus swords – Stained Glass Windows – Nanotechnology in Nature – Insect Colours – Geckos – Hydrophobic Surfaces – Photonic Phenomena – Nanomaterials - Classification of Nanomaterials – Various Morphologies – Nanowires – Nanotubes – Nanofibres – Nanosphers – Quantum dots – Quantum confinement- Surface to volume ratio - Energy at bulk and nano scale – Band Structure of Nanomaterials - Size dependent variation in Optical, Mechanical, Physical- Chemical- electronics and catalytic properties.

## Unit-2 - Top down and Bottom-Up Approaches

9 Hour

Top down and Bottom Up approaches – Chemical Vapor Deposition- High-energy balling – Mechanical alloying –Nanostructure through Lithography – Different types of lithography techniques – Arc discharge – Physical vapour deposition - Bottom up approach: Polyol route – Colloidal precipitation – Sol-Gel process – Chemical precipitation – Hydro/solvothermal routes – Different coating techniques – Dip – Spray and layer by layer methods - Sonochemical – Microbial routes – Biosynthesis – Electrospinning method - Special Nanostructures - Quantum dots – Magnetic Nanoparticles – metal nanoparticles - Carbon Nanomaterials – Polymer based Nanocomposites.

Unit-3 - Electromagnetic Radiation 9 Hour

Electromagnetic radiation — Wave nature of light — Photoelectric effect — Band Structure — Band diagram — Fermi level — The Bohr — Exciton radius — Structure of Atoms — Oxidation and reduction — Subatomic particles — Chemical bonding— Chemical reactions — Atomic orbitals — Molecular orbitals — Intermolecular forces — hydrogen bonding — Van der Waals force — dangling bonds — electron tunning effect — Interfacial charge transfer — Surface plasmon resonance — Hydrophilic and hydrophobic effect — Nanomagnets — Superparamagnetic effect — Giant Magnetoresistance

Unit-4 - Characterization 9 Hour

Characterization of electrical- optical- mechanical and magnetic properties of nanomaterials. Electrical conductivity and permittivity- magnetic permeability- Structural characterization: X-ray diffraction- Electron microscopy – Scanningelectron and Transmission electron microscopies – UV-Vis-NIR – FTIR - Raman – X-ray Photoelectron Spectroscopies. Surface characterization: atomic force microscopy – Nano indentation. Characterization of porous structures. Characterization of quasi-static and dynamic elastic properties. Mechanical testing.

## Unit-5 - Nanocomposite Materials for Diagnosis

9 Hour

Nanocomposite materials for diagnosis - therapy and food packaging - Functional graphene- carbon nanostructures and polymer composite applications in defence and aerospace. Nanomaterials for energy sectors solar Cells – hydrogen storage and production - Rechargeable batteries – supercapacitors for vehicular and portable electronic applications - Nanomaterials for electrodes and wearable electronics- Nano based coating and paints -Nano catalysts for environmental cleaning and disinfection of pathogens – Implications of nanoscience and nanotechnology on society.

	1. T. Pradeep, Nano: The essentials, Tata McGraw-Hill Publishing Company 3. Y. Dahman, I	lanotechnology and Functional Materials for Engineers. A volume in
Learning	Limited, 2010 4. Micro and Na	no Technologi <mark>es, Elsevier,</mark> 2017.
Resources	2. Wesley C. Sanders, Basic Principles of Nanotechnology, CRC Press, 2018 5. B.S. Murty, 1	P. Shankar, Bal <mark>dev Raj, B</mark> B Rath, James Murday (auth.) Textbook of
	Nanoscience	andNanotechnology, Springer, 2013.

Learning Assessm	ent	$\sim$	40 s 500	71 - 611						
	/ 🥺 /		Continuous Learning	g Assessment (CLA)	1 4 4	Cumm	notivo			
	Bloom's Level of <mark>Thinking</mark>	Forma CLA-1 Averag (50'	ge of unit test	Life-Long CL (10	4-2	Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	15%	With the State of	15%	- C	15%	-			
Level 2	Understand	25%	35 17 35	25%		25%	-			
Level 3	Apply	30%	5 765 6 7 1	30%	3 -	30%	-			
Level 4	Analyze	30%	Additional ways and the control of t	30%		30%	-			
Level 5	Evaluate			1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1			-			
Level 6	Create					-	-			
	Total	100	%	100	) %	100 %				

Course Designers	11111	A 1
Experts from Industry	Experts from Higher Technical Institutions	/ Internal Experts
1. Dr.Priyanka Biswas, Graphene Research Lab Pvt Ltd	1. Dr.Pijush Ghosh, IIT Madras	1. D <mark>r R.Ajay</mark> Rakkesh, SRMIST
2. Dr. Pralay K. Santra, Scientist D, Centre for Nano and Soft Matter Sciences, Bengaluru	2. Dr. Somnath Chandra Roy, IIT Madras	2. Dr.Payel Bandyopadhyay, SRMIST

Course	24NITE222T Course	SYNTHESIS OF NANOSTRUCTURED MATERIALS	Course	_	PROFESSIONAL ELECTIVE	L	T	Р	С	
Code	Name	SYNTHESIS OF NANOSTRUCTURED MATERIALS	Category -		PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	N	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	Learning Rationale (CLR): The purpose of learning this course is to:		4		- 1	rogra	am Ou	tcome	s (PO	)					rograr	
CLR-1:	understand the basics of Nanostructured materials	1.	2	3	4	5	6	7	8	9	10	11	12		pecific	
CLR-2: know the basics of Physical synthesis method				, of	ns s					Nork		e S		1		
CLR-3:	introduce chemical synthesis method and understand the different synthesis routes	Knowledge	Analysis	evelopment	investigations ex problems	Usage	Б	. \		_		inance	рū			ļ
CLR-4: understanding the working principle and fabrication of 2-D materials				ld of	estic orob	N C	er and	t &		Team	tion	& Fi	earning			
CLR-5: introduce the concepts of fabrication and application of 1-D materials					Ψ.	1 Tool	engineer ety	vironment stainability	N	ual &	ommunication	Mgt	ong Le			
Course C	Outcomes (CO):  At the end of this course, learners will be able to:	Engine	Problem	Design	Conduct of compl	Modern		Enviro <mark>Sustai</mark>	Ethics	Individual	Comm	Project Mgt.	Life Lo	PSO-1	PS0-2	PSO-3
CO-1:	apply the concept of top-down and bottom-up method and understand the physical and chemical propert of nanostructured materials		2	er in Mari	-	F	Ž	-		-	-	-	-	2	-	-
CO-2:	apply the concept and prepa <mark>re the n</mark> anostructured materials for physical method	3	2	-		- 7		-		-	-	-	-	-	2	-
CO-3:	gain knowledge on various <mark>chemical</mark> synthesis method	2	144	2	-	- 1	-	-		-	-	-	-	-	2	-
CO-4:	CO-4: acquire knowledge on different types of fabrication of 2-D thin film materials				2	-	-	-	7	-	-	-	-	2	-	-
CO-5:	utilize the concept and prepa <mark>ration o</mark> f 1-D nanostructured materials to analyze the material nature	3	2	44.5	_	- 1	7	-		-	_	_	-	-	2	_

Unit-1 - Introduction 9 Hour

Introduction of Nanostructured materials- Scientific Revolution-Atomic Structure and atomic size, emergence and challenges of nanoscience and nanotechnology, top-down, bottom-up approaches-carbon agenew form of carbon (CNT to Graphene), influence of nano over micro/macro, size effects and crystals, large surface to volume ration, surface effects on the properties.

# Unit-2 - Synthesis 9 Hour

Synthesis and preparation of Nanomaterials: Vacuum: Different levels – Pumps: Rotary- Diffusion- Turbomolecular- Ion and Sublimation— Gauges: Penning- Pirani and Bayard-Alpert – Inert gas condensation: Low resistive boats – Joule heating process- Role of inert gases- Post oxidation process – Sputtering processes—Rapid solidification-Synthesis of bulk nanostructured materials, solid- state, processing- bulk and nano composite materials - Grinding - high energy ball milling – injection moulding - extrusion - melt quenching and annealing - PVD - PLD - Ultra high vacuum synthesis - Arc discharge, RF-plasma, Plasma arc techniques - Laser ablation - Spray Pyrolysis - Sputtering

- Direct current sputtering (DC sputtering), Radio frequency sputtering (RF sputtering) - - Advantages and disadvantages.

# Unit-3 - Dimensions 9 Hour

Zero dimensional, one dimensional and two dimensional nanostructures, Nucleation theory, Homogeneous and heterogeneous nucleation, Metal nanocrystals by reduction, Sol- gel, Hydrothermal-Sonochemical—Microbialroutes—Biosynthesis—Template route: DC and Pulsed electrodeposition and Electroless deposition—Combustion route, Photochemical synthesis, Electrochemical synthesis, Thermolysis routes, microwave routes, Sonochemical routes, Hybrid methods, Micelles and microemulsions, Bio-Synthesis-Polyol route—Colloidal precipitation—Chemical precipitation: Normal and Reverse reactions- Role of surfactant—Hydrolysis: Reaction kinetics.

Unit-4 - Synthetic Technique

9 Hour

Synthetic Technique (Physical and Chemical): Self-Assembly-Self Assembled Monolayers (SAM) - Vapour Liquid Solid (VLS) approach - Chemical Vapour Deposition (CVD) - MOCVD technique-Langmuir-Blodgett (LB) films - Spin coating- Templated self-assembly electrochemical approaches: thin films - Epitaxy - Lithography. Vacuum thermal evaporation, Electron beam evaporation, Laser beam evaporation, lon plating evaporation-Inert gas condensation, aerosol method, Gas-phase synthesis, -Advantages and disadvantages.

Unit-5 - One Dimensional Nanostructure

9 Hour

One dimensional nanostructured: Nanowires and Nanotubes- Evaporation-condensation — Electrospinning-Vapor- liquid - solid (VLS) - surface and bulk diffusion — kinetics — growth of various nanowires —control of size — precursors and catalysts - single- and multi- wall CNT - Si nanowires — density and diameter — doping in nanowires

ı	Learning
	Resources
	Resources

- 1. W. Gaddand, D. Brenner, S. Lysherski and G. J. Infrate (Eds), Handbook of nanoscience, Engg. and Technology, CRC Press, 2012.
- G. Cao, Naostructures and Nanomaterials: Synthesis, properties and applications, imperical college press, 2004.
- 3. J. George, Preparation of thin films, Marcel Dekker, InC., NewYork, 2005.
- 4. C. N. R. Rao, A. Muller, A. K. Cheetham (Eds), The chemistry of nanomaterials: Synthesis, properties and applications, Wiley VCH Verlag Gmbh & Co, Weinheim, 2004.

_earning Assessn	icit		<i>&gt; /</i>	Continuous Learnin	g Assessment (CLA)			
	Bloom's Level of T <mark>hinking</mark>	7	CLA-1 Avera	native ge of unit test 0%)	Life-Long I CLA (109	-2		native amination eightage)
			Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	20	15%	William Commence to the	15%		15%	-
Level 2	Understand		25%	All the second	25%		25%	-
Level 3	Apply		30%	N. 1. 1. 1. 1. 1. 1. 1. 1. 1. 1. 1. 1. 1.	30%		30%	-
Level 4	Analyze		30%	20 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	30%	E	30%	-
Level 5	Evaluate		47,-2-	The same was a			-	-
Level 6	Create				12.5			-
	Tot <u>al</u>		100	0 %	100	%	100	0 %

Course Designers	////	
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Krishna SurendraMuvvala, Saint Gobain Research India,	1. Dr.K.Sethupathi. IIT Madras, ksethu@iitm.ac.in	1. Dr.M.Nava <mark>neethan,</mark> SRMIST
India,Krishna.muvvala@saintgobain.com		/ / / / / / / / / / / / / / / / / / / /
2. Dr.M.Saravanan, CSIR-NPL, nvijayan@nplindia.org	2. Dr.S.Balakumar. University of Madras, Madras,	2. Dr. S.H <mark>arish, SR</mark> MIST
	balakumar@iunom.ac.in	

Course	24NTE224T Course	ADVANCED DRUC DELIVERY SYSTEMS	Course	-	PROFESSIONAL ELECTIVE	L	Т	Р	С	
Code	Name	ADVANCED DRUG DELIVERT STSTEMS	Category	-	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil Progress Course	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards	Nil

Course L	earning Rationale (CLR):	The purpose of learning	n <mark>g this</mark> course is to:	TIME!	· .			F	rogra	<mark>am</mark> Ou	tcome	s (PO	)					gram	
CLR-1:	understand the concept of dr	rug delivery	11.2		1	2	3	4	5	6	7	8	9	10	11	12		ecific come	
CLR-2:	acquire knowledge on contro	lled drug d <mark>elivery</mark>	20.		ge		of	SL			1		ork		8				
CLR-3:	learn the concept of targeted	drug d <mark>eliver</mark> y	A		Knowledge	S	nent	vestigations x problems	Usage	ъ	1		≥		Finance	gu			
CLR-4:	know about the methods of o	lrug d <mark>elive</mark> ry	N	37 (A. )	Αno	Analysis	lopi	estig	- N	er and	× ×		Team	Į.	∞ర	earning			
CLR-5:	understand the concept of dr	rug <mark>delivery</mark>	7 (5)		Engineering	-	sign/development utions	.≒ 6	T00	enginee ety	Environment 8 Sustainability	N	<u>8</u>	ommunication	Project Mgt.				
				1 3 THE	jine	Problem	sign/d	onduct i	Modern	enç ietv	/iron stain	Ethics	ndividual	JIII.	ject	ife Long	0-1	PS0-2	PSO-3
Course C	Outcomes (CO):	At the end of this coul	rse, learners will be able to:	100	Enç	Pro	Des	of of of	₩	The	En Sus	Eth	pul	Col	Pro	Life	PSO.	PS	PS
CO-1:	explain various drug delivery	<mark>systems</mark>	1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	V 30% 213 1	3	9.1	1	-	-	1	-		-	-	-	-	2	-	
CO-2:	analyse a controlled drug rele	ease profile	State of the	15/2011	3	2	12/21	-	- 1	I.	-	-	-	-	-	-	-	2	-
CO-3:	formulate different drug delive	ery systems		44. I V. V	3	2.4	2		- (	-	-	-	-	-	-	-	2	-	-
CO-4:	apply the concept of drug tar	<mark>get</mark> ing		37 6 77 7	-3	-	2	-	-	-	-		-	-	-	-	2	-	-
CO-5:	differentiate among various n	anocarriers	F. N. P	A	3	2	14	-	- 3	-	-	-	-	-	-	-	2	-	-

Unit-1 - Introduction 9 Hour

Drug delivery systems, Traditional drug delivery, Advantages and disadvantages of various traditional drug delivery systems, Modes of drug delivery, Routes of administration, Novel drug delivery system, Pharmacokinetics, ADME studies, Kinetics of drug delivery, zero order kinetics, First order kinetics, Controlled drug delivery, Mechanism of controlled drug release, Therapeutic index, Drug release profile, Rate controlled drug delivery, Time controlled drug delivery

## Unit-2 - Trageted Delivery

9 Hour

Targeted drug delivery system, Site specific drug release, Types of drug targeting, Active targeting, Passive targeting, Barriers for drug targeting, Strategies for site specific drug delivery, Receptors, Ligands, Antibodies based drug delivery, Metabolism based drug delivery, Surface modification of nanoparticles, Bioconjugation of nanoparticles, PEGylation of nanoparticles, reticuloendothelial system, Opsonaization, Renal clearance, Steric repulsion

## Unit-3 - Metal Nanoparticles for Drug Delivery

9 Hour

Gold based drug delivery systems, Multifunctional nanoparticles, Multifunctional gold nanoparticles for drug delivery and imaging, Virus based drug delivery system, Polymeric nanoparticles, Classifications of polymers, Polymer micelles, Synthesis of polymeric nanoparticles for drug delivery, Dentrimers, Magnetic nanoparticles for drug delivery, Nanoscaffolds, CNT in drug delivery, Liposomes, Protein drug delivery, Gene transfection. Methods of gene transfection

## Unit-4 - Drug Delivery to Cancer

у пои

Cancer therapy, Drug delivery to cancer, Targeted drug delivery to cancer, Enhanced permeability and retention, Cancer markers, Folate receptor, Angiogenesis, Leaky vasculature, Cancer specific targeting, Combinational therapy, Neutron capture therapy, targeting tumor vasculature for imaging, Anticancer drugs, Pharmacodynamics, Photothermal therapy, Cancer imaging, Nanoparticle–Aptamer Conjugates for Cancer Cell Targeting and Detection., Fluorescent Silica Nanoparticles for Tumor Imaging

Unit-5 - Theranostic Metal Nanoshells 9 Hour

Theranostic metal nanoshells, Photothermally-modulated drug delivery using nanoshell, Hydrogels, Nanoporous systems for drug delivery, Molecularly-derived therapeutics, transdermal drug delivery, low-frequency sonophoresis, implants for controlled drug delivery, Responsive release system, Fabrication and Applications of Microneedles, Micropumps, microvalves, Implantable microchips, Quantum Dot Probes, Applications Nano biotechnologies for Single-Molecule Detection, Nanorobots, Drug delivery to Central Nervous systems, Drug delivery across Blood brain barrier

Learning	1. Drug Delivery: Engineering Principles for Drug Therapy, M. Salzman, Oxford University	3.	Drug Delivery: Principles and Applications, B. Wang, Wiley Intersceince, 2005.
	Press, 2001.	4.	Nanoparticle Technology for Drug Delivery, Ram B. Gupta, Uday B. Kompella Taylor &
Resources	2. Drug Delivery and Targeting, A.M. Hillery, CRC Press, 2002		Francis, 2006

Learning Assessm	nent					1				
	Bloom's Level of Thinking	Forma CLA-1 Averag (509	ative ne of unit test		g Learning A-2 0%)	Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	15%		15%	(- \( \)	15%	-			
Level 2	Understand	25%		25%		25%	-			
Level 3	Apply	30%	A Company of the Company	30%		30%	-			
Level 4	Analyze	30%	A 1 1 2 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	30%	. 1	30%	-			
Level 5	Evaluate	A - 2.1	Will the same of the	Sec. 1 32. "7"		-	-			
Level 6	Create	F 1777	Mary Mary Table	F Water State of the	- 3	-	-			
	T <mark>otal = = = = = = = = = = = = = = = = = = =</mark>	100	%	10	0 %	100	0 %			

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Mr. K. Chandru, Medical Device Domain, HCL Technologies	1. Dr. Asifkhan Shanavas, INST, Mohali, asifkhan@inst.ac.in	1. Dr. G. Devana <mark>nd Venka</mark> tasubbu, SRMIST
2. Mr. P. Aravind Mukesh, United Breweries, Bengaluru	2. Dr.Biman B. Mandal, IIT G, biman.mandal@iitg.ac.in	2. Dr. N. Selvamurugan, SRMIST

Course	21NTE322P Course	VACUUM AND THIN FILM TECHNOLOGY	Course _	PROFESSIONAL ELECTIVE	L	Т	Р	С	1
Code	Name	VACOUNI AND THIN FILM TECHNOLOGY	Category -	PROFESSIONAL ELECTIVE	2	1	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	NI	gressive ourses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	1				F	rogra	am Ou	tcome	s (PC	))					rogra	
CLR-1:	understand the thin film			1	2	3	4	5	6	7	8	9	10	11	12		pecifi ıtcom	
CLR-2:	introduce methods of thin film	n growth, <mark>Physical an</mark> d Chemical		dge	7	of	SL			N.		ork		99				
CLR-3: explain various characterization tools to study structural and compositional properties			Knowledge	S	evelopment	vestigations problems	зде	ъ	, N.		×		Finance	Б				
CLR-4:	explain the methods of elec-	trical, <mark>optical a</mark> nd thickness measurements	٠, ١	Kno	Analysis	lobi	estig	ol Usage	r and	∞ ×		Team	igi	<b>⊗</b>	earning			
CLR-5:	introduce the major applicati	on a <mark>rea of t</mark> hin film technology		=ngineering		deve	in X	P	engineer sty	ment		al &	ommunication	Project Mgt.				
		A STATE OF THE STA	100	ine	Problem	ign/	onduc	Modern	et e	ironme tainab	S	ndividual	l III	ect	Long	7	)-2	-3
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	-25	Eng	Prof	Des	Col	Mo	The Soci	Environi Sustaina	Ethics	ibu	Sol	Proj	Life	PSO-1	PS0-2	PSO.
CO-1:	apply the principles of vacuu	<mark>m techno</mark> logy		3	2	-		Ŧ	7	-		-	-	-	-	2	-	-
CO-2:	gain knowledge on physical a	and chemical methods of thin film deposition	7	2	2	177	-	- 1	-	-	-	-	-	-	-	-	2	-
CO-3:	understand the importance o	f structural and compositional characterization of thin films		3	2		-3-	- (		-		-	-	-	-	2	-	-
CO-4:	acquire knowledge on optica	l <mark>, electri</mark> cal and thickness measurement methods	17	-2		3	-	-	-	-		-	-	-	-	-	2	-
CO-5:	understanding the utilization	of thin film technology in various application areas	- 1	2	4.	2	-	- ;	-	-	7	-	-	-	-	2	-	-

Unit-1 - Introduction 9 Hour

Introduction to vacuum technology- What is vacuum?, units, vacuum ranges, flow types, adsorption, desorption, vacuum pumps, rotary, diffusion, turbo molecular, getter ion pumps, design and operation, design of vacuum pumping stations, vacuum measurement, total pressure measurement equipment, partial pressure measurement equipment / Mass spectrometers, leak detection, Helium leak detection, vacuum-suitable components, Detachable and non-detachable connections, Flange systems and seals, valves, compatible materials, vacuum systems examples

## Unit-2 - Introduction to Thin Film Growth

9 Hour

Introduction to thin film growth, Kinetic theory of gases, types of thin growth, epitaxial and polycrystalline growth of thin films, Physical vapour deposition method, Thermal evaporation, e-beam evaporation, sputtering principle, DC and RF sputtering, Pulsed laser deposition, Molecular beam epitaxy: Chemical vapor deposition (CVD) method, CVD reaction types, Plasma Enhanced CVD (PECVD), Metallorganic CVD, atomic layer deposition, comparison of PVD and CVD techniques

## Unit-3 - Thin Film Characterization

9 Hour

Thin film characterization tools: Structural analyses using X-ray and electron diffraction, Surface studies using electron microscopy (SEM, TEM) Atomic force microscopy, Compositional studies using Energy dispersive E-ray emission, X- ray photoelectron spectroscopy XPS, Rutherford Back Scattering spectroscopy (RBS), depth profiling using Secondary Ion Mass Spectroscopy (SIMS).

## Unit-4 - Measurements

9 Hour

Thickness, electrical and optical properties measurements- In-situ and ex-situ methods, RHEED for epitaxial growth monitoring, Quartz crystal monitoring, contact and non-contact profiler for thickness measurement methods, resistivity, Hall measurements, UV-vis-NIR spectroscopy measurements for determination of reflectance, transmittance, absorbance, optical bandgap determination in semiconducting thin films

## Unit-5 - Application

9 Hour

Application areas of thin film technology- optical coatings, antireflective coatings, electronic devices, magnetic, diffusion barriers in chemical processes, ceramic and friction reduction in mechanics, transparent conducting oxide film, transparent devices, thin film solar cells

	1. A User's Guide to vacuum Technology, 3rd edition, by J. F. O'Hanlon, John Wiley,	and 3. Milton Ohring, "Materials Science of Thin films" Published by Academic Press Limited 19
Learning	Sons,2003	4. Vacuum Physics and Techniques by T. A. Delchar, Chapman, and Hall, 1993
Resources	2. Rointan. F, Bunshah," Hand Book of Deposition technologies for Thin Films and coat	ngs 5. K. L. Chopra, "Thin Film Phenomena", McGraw Hill, New York, 1969
	by Science, Technology and Applications", Second Edition, Noyes Publications, 19	93. 6. L. T. Meissel and R. Glang, "Hand book of thin film technology", McGraw Hill, 1978.

			Co	ntinuous Learnin	g Assessment (CL	A)			
	Bloom's Level of Thinking	CLA-1 Avera	native ge of unit test 0%)	CL	sed Learning A-2 0%)		od Viva Voce 20%)		ramination eightage)
		Theory	Practice	Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	15%	- 1		15%		15%	-	-
Level 2	Understand	25%		MET THE	20%		25%	-	-
Level 3	Apply	30%	-	P 1 1 - 1 4	25%	- Y	30%	-	-
Level 4	Analyze	30%	-	N. S. W. 1777	40%	-	30%	-	-
Level 5	Evaluate	~ ·	mt be Si		A	-	T		-
Level 6	Create		5,90,475	A 4 5 4 7	3414			-	-
	Total Total	10	0 %	10	0 %	10	00%		-

Course Designers	
Experts from Industry	Experts from Higher Technical Institutions Internal Experts
<ol> <li>Dr. Mohan Bhan, OAI, USA, mbhan@oainet.com</li> </ol>	1. Dr. Ramesh Chandra Mallik, IISc Bangalore 1. Dr. P. Malar, SRM IST
2. Mr, C P Sridhar, SIMCO Groups, Bangalore,	2. Dr. Bhaskar Chandra Mohanty, Thapar University 2. Dr. C. Gopalakrishnan, SRM IST
sridhar.cp@simcogroup.in	

Course	21NTE323T	Course	ADDITIVE MANUFACTURING TECHNIQUES	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С
Code	ZINTESZST	Name	ADDITIVE MANUFACTURING TECHNIQUES	Category	Ц	PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offerin	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	7					Progr	am Oı	ıtcome	s (PC	))					gram
CLR-1:	introduce the basic principles	, advantages <mark>and the chall</mark> enges of additive manufacturing		1	2	3	4	5	6	7	8	9	10	11	12		cific omes
CLR-2:	acquire the knowledge of diff		ge		ot	SI					ork		9				
CLR-3:	understand the additive man	Knowledge	S	velopment	stigations oblems	Usage	ъ			Μ		nance	Б				
CLR-4:							estig		rand	∞ >		Team	ioi	& Fin	arning		
CLR-5:	explain the significance of po	st-p <mark>rocessing</mark> in additive manufacturing	ď.	ering	λ Analysis	deve	t inve	T00	enginee	ment		<u>8</u>	mmunication	Project Mgt.	ong Le		
			77	inee	roblem	/ugi	onduct	Modern	et e	ronm tainab	S	ndividual	E E	ect	Lon	7 3	7 5
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	À.	Engine	Pod	Des	of Col	Moo	The	Env	Ethics	lpd	Con	Proj	Life	PSO	PSO-3
CO-1:	define the various processes	and materials used in additive manufacturing	1	3	-	-	-	Ŧ	7	-	-	-	-	-	-	2	
CO-2:	analyze suitable process in a	additive manufacturing	7	3	-	3	-	- 3		-	-	-	-	-	-	2	
CO-3:	explain the components and	working of various machine tool systems		3	11	3	3-	-		-		-	-	-	-	2	-   -
CO-4:	apply CAD technique and reverse engineering for geometry transformation in additive manufacturing				75	3	-	-	-	-		-	-	-	-	2	-   -
CO-5:	employ the knowledge of ad	employ the knowledge of additive manufacturing for various applications				3	-	-	_	-	-	-	-	-	-	2	.   -

Unit-1 - Overview 9 Hour

Basic principle needs and advantages of additive manufacturing, Procedure of product development in additive manufacturing, Classification of additive manufacturing processes, Materials used in additive manufacturing, Challenges in Additive Manufacturing.

## Unit-2 - Z-Corporation 3D-Printing

9 Hour

Z-Corporation 3D-printing, Stereolithography apparatus (SLA), Fused deposition modelling (FDM), Laminated Object Manufacturing (LOM), Selective deposition lamination (SDL), Ultrasonic consolidation, Selective laser sintering (SLS), Laser engineered net shaping (LENS), Electron beam free form fabrication (EBFFF), Electron beam melting (EBM), Plasma transferred arc additive manufacturing (PTAAM), Tungsten inert gas additive manufacturing (TIGAM), Metal inert gas additive manufacturing (MIGAM).

## Unit-3 - Axes

9 Hour

Axes, Linear motion guide ways, Ball screws, Motors, Bearings, Encoders/ Glass scales, Process Chamber, Safety interlocks, Sensors. Introduction to NC/CNC/DNC machine tools, CNC programming and introduction, Hardware Interpolators, Software Interpolators, Recent developments of CNC systems for additive manufacturing.

#### Unit-4 - 3D-CAD Model

9 Hour

Preparation of 3D-CAD model, Reverse engineering, Reconstruction of 3D-CAD model using reverse engineering, Part orientation and support generation, STL Conversion, STL error diagnostics, Slicing and Generation of codes for tool path, Surface preparation of materials.

## Unit-5 - Techniques

9 Hour

Techniques used in additive manufacturing, Support material removal, surface texture improvement, accuracy improvement, aesthetic improvement, preparation for use as a pattern, property enhancements using non-thermal and thermal techniques, Brief information on characterization Applications of additive manufacturing in rapid prototyping, rapid manufacturing, rapid tooling, repairing and coating.

	1.	Chua Chee Kai, Leong Kah Fai, "3D Printing and Additive Manufacturing: Principles &	3.	Additive Manufacturing Applications and Innovations Edited By Rupinder Singh,
Learning		Applications", 4 <sup>th</sup> Edition, World Scientific, 2015		J. Paulo Davim (CRC Press)
Resources	2.	Ian Gibson, David W Rosen, Brent Stucker., "Additive Manufacturing Technologies: 3DPrinting,		
		Rapid Prototyping, and Direct Digital Manufacturing", 2 <sup>nd</sup> Edition, Springer, 2015	١.	

			Continuous Learning	Assessment (CLA)		C				
	Bloom's Level of Thinking	Form CLA-1 Avera (50		C	g Learning LA-2 10%)	Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	15%	- 100 m 140	15%	A - 1	15%	-			
Level 2	Understand	25%		25%	T 2.	25%	-			
Level 3	Apply	30%	4 - 4-34	30%	V 777	30%	-			
Level 4	Analyze	30%	A C 15 No. 3 (1)	30%		30%	-			
Level 5	Evaluate		The Asset of	74.5			-			
Level 6	Create			J. A. 14		-	-			
,	Tot <mark>al</mark>	100	)%	10	00 %	10	0 %			

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Course Designers		- I
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Mr. Aditya Kumar, Marcopolo Produ <mark>cts</mark> P Ltd,	1. Dr. Murugaiyan Amirthalingam, IIT Madras,	1. Dr. Venkata Rav <mark>indra A,</mark> SRMIST
aditya.kumar@marcopolo.co.in	murugaiyan@iitm.ac.in	
2. Mr. Venkatesha N, SABIC Research & Technology Pvt. Ltd.,	2. Dr. Pulak Mohan Pandey, IIT Delhi, pmpandey@mech.iitd.ac.in	2. Dr. Payel Band <mark>yopadhya</mark> y, SRMIST
Venkatesha.N@sabic.com		

Course	21NTE324T	Course	DUVCICO OF ELECTRONIC MATERIAL	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С
Code	Z 11N 1 E 3 Z 4 1	Name	PHYSICS OF ELECTRONIC MATERIAL	Category	Ц	PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	NI	gressive ourses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:		ď ,		1	. 1	rogr	am Oı	ıtcome	s (PO	))					gram	
CLR-1:	understand the physics of se	emiconductor e <mark>lectronic m</mark> aterials		1	2	3	4	5	6	7	8	9	10	11	12		ecific comes	
CLR-2:							દ		7			ork		9				
CLR-3:	familiarize with different physical properties of electronic materials and devices					evelopment	estigations problems	Usage	ъ			Μ		Finance	ng			
CLR-4:	understand the physics of magnetism and magnetic materials-based devices					lopi	estig		rand	∞ >		Team	ioi	⊗ E	arni			
CLR-5:	understand the properties of	f mat <mark>erials tha</mark> t result in specific electrical, optical and magnetic behavior		ineering	Analysis	deve	ĕ ⊇.	Tool	enginee	nability		<u>ھ</u>	ommunication	Project Mgt.	g Le			
			-0.0	nee	roblem	lgn/	compl	Modern	eng et<	ro la	SS	ndividual	חשו	ect	Long	7 9	7 5	27
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	. 42	Engi	Prok	Des	o o	Mod	The	Envi	Ethics	lpdi	Con	Proj	Life	PSO	PSO-2	755
CO-1:	use knowledge of physics to	understand the properties of Electronic Materials		2	3	-	2		7	-	-	2	-	-	-	-	-	-
CO-2:	analyze different mechanism	n <mark>s that de</mark> termine the properties of electronic materials	1	3	2	100	2	- 4	_	-	-	2	-	-	-	2	-	-
CO-3:	determine the applications o	f electronic materials based on their properties		2	2	-1	2	-		-		2	-	-	-	3	-	-
CO-4:	evaluate the material charac <mark>teristics</mark> by applying laws of physics		11.2	-3	3	1-	3	-	-	-	1	2	-	-	-	3	-	-
CO-5:	develop in depth understand	develop in depth understanding of the physical processes of electronic materials				1	3	-	-	-	4	2	-	-	-	3	-	-

Unit-1 - Introduction 9 Hour

Introduction to crystals – Symmetry operations – Point groups and space groups – absence of five-fold symmetry - Basis and Motif – Crystal Unit cell – Types of crystal lattices – Miller indices - Reciprocal lattice – Crystal directions and planes – Cubic lattice in reciprocal space - Distance between two parallel crystal planes - Wigner Seitz Unit cell – Brillouin zone – Diffraction condition - Crystal properties - defects and vacancies

#### Unit-2 - Postulates of Quantum Mechanics

9 Hour

Postulates of Quantum Mechanics – Formalism – Schrodinger equation – Simple potentials – Particle in infinite well – Particle in finite well - Quantum tunnelling – Transmission coefficient - Classical Drude model – Quantum free electron theory – Particle subjected to periodic potential - Bloch's Theorem – Bloch's waves – Origin of Energy gap – Conductors – Semiconductors and Insulators – Effective mass – E vs k diagram – Intrinsic and Extrinsic semiconductors – Semiconductors doping – Doping methods – Direct and Indirect band gap semiconductors

## Unit-3 - Thermal Properties of Materials

9 Hour

Thermal properties of materials – specific heat capacity - thermal expansion - conductivity and thermal stress - Einstein and Debye model of heat capacity - Seebeck effect - thermoelectricity in semiconductors - 2D electronic materials - future perspectives

#### Unit-4 - Optical Properties of Material

9 Hour

Optical properties of material - refractive index, dispersion, transmittance, reflectance and refractivity - light propagation in a homogeneous medium - absorption - scattering - luminescence - phosphors - fiber optics - LEDs - polarization - LCDs - Band to band absorption - Direct and indirect transitions - Laser operation - spontaneous and stimulated emission - photoluminescence and electroluminescence - electro optic effects - magneto optic effects - MOKE

## Unit-5 - Magnetism

9 Hour

Magnetism - Dipole moment - Orbital and spin magnetic moment of an electron - magnetic susceptibility and magnetic permeability - Classification of Magnetic materials - saturation and Curie temperature - exchange interaction - Magnetic domains and domain walls - Superconductivity - Meisner effect - Introduction to BCS Model - Josephson effect - Introduction to magneto resistance - TMR - GMR - TAM

	1.	S O Kasap, "Principles of Electronic Materials and Devices" – McGraw Hill, Fourth Edition, 2017	5.	David K. Ferry, Jonathan P. Bird "Electronic Materials and Devices" – Academic Press, First Edition. 2011.
Learning	2.	Jørgen Rammer, "Physics of Electronic Materials - Principles and Applications" Cambridge University Press, 2017	6.	Yuriy M Poplavko, "Electronic Materials: Principles and Applied Science" – Elsevier, First Edition, 2019
Resources	3.	Wei Gao, Zhengwei Li, Nigel Sammes, "An Introduction to Electronic Materials for Engineers" – World Scientific Publishing Co. Pte. Ltd, Second Edition, 2011	7.	Rolf E. Hummel, "Electronic Properties of Materials: An Introduction for Engineers" – Springer,
	4.	David Jiles, "Introduction to the Electronic Properties of Materials: - Nelson Thornes Ltd. Second Edition. 2001	8.	Kittel, C., Introduction to solid state physics Eighth edition, 2021.

Learning Assessm	ent	<b>3</b> (0)	Continuous Learnin	g Assessment (CLA)						
	Bloom's Level of Thinking	CLA-1 Avera	native ge of unit test 0%)	Life-Long I CLA (109	-2	Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	20%	<b>医毛头球状</b> 体	20%	( - 1 )	20%	-			
Level 2	Understand	20%		20%		20%	-			
Level 3	Apply	40%	Carlotte Carlotte	40%		40%	-			
Level 4	Analyze	20%	A 10 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	20%	. 1 - 7	20%	-			
Level 5	Evaluate		100 may 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	Sec. 1 30 77		-	-			
Level 6	Create	3	All the second	7 10 10 10 10		-	-			
	T <mark>otal  </mark>	10	0 %	100	%	10	0 %			

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr.Hemant Dixit, Global Foundries, aplahemant@gmail.com	1. Prof. Ranjit Kumar Nanda, IITM Chennai, nandab@iitm.ac.in	1. Dr.Arijit Sen, S <mark>RMIST</mark>
2. Dr.Murali Kota, Global Foundries, USA, kvrmmurali@gmail.con	1 2. Prof. G.P.Das, IIT KGP, msgpd@iacs.res.in	2. Dr.Saurabh G <mark>hosh, SR</mark> MIST

Course	21NITE225T	Course	PHYSICS OF SOLID-STATE DEVICES	Course	_	PROFESSIONAL ELECTIVE	L	Т	Р	С
Code	21NTE3251	Name	FITISICS OF SOLID-STATE DEVICES	Category	E	PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses		Nil	
Course Offeri	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		• •	Nil	

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	71	4 .		- 1	rogr	am Oı	ıtcome	es (PC	<b>)</b> )					gram	
CLR-1:	understand the physics of p	-n junction	1	2	3	4	5	6	7	8	9	10	11	12		ecific come:	
CLR-2:	familiarize with the concept	of metal/semiconductor junctions and semiconductor heterojunctions	dge		ot	w			l.		논		8				
CLR-3:	describe the operation of ba	asic semic <mark>onductor</mark> diodes	- Medć			stigations oblems	e e				Wo		딞				
CLR-4:	understand the theory of va	rious ty <mark>pes of tra</mark> nsistors	Know	nalysis	velopment	stigatio	Usage	and	∞ŏ		eam	E	Ë	aming			
CLR-5:	acquire knowledge on the cells, Photodetectors, Laser	materials and working of solid-state optoelectronic devices like LEDs, So s, etc	ar   buile	Y	gn/develo	onduct inves complex pro	100 100 100	engineer etv	nment nability	S	%   E	ommunication	ct Mgt. &	ong Lea	<u>-</u>	7	0-3
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	Engine	Problem	Design	Sonc	Modern	The	Enviro Sustai	Ethics	Individu	Com	Project	life I	PSO	PS0-2	PSO
CO-1:	acquire knowledge of physic	cs of p-n junction formation and functioning of pn-junction diode	3	2	-	-	7	-	-	-	-	-	-	-	2	-	-
CO-2:	develop in depth understand	<mark>ding on th</mark> e metal-semiconductor contacts and methods to access their qualit	у 3	1.0	1777	3	- 4	-	-	-	-	-	-	-	-	2	-
CO-3:	differentiate different transis	tor technologies and know the design and working of MOSFET	3	2			- 1	-	-		-	-	-	-	-	-	
CO-4:	familiarize with III-V semicor	<mark>nductor d</mark> evice technologies	3	127		3	-	-	-	7	-	-	-	-	-	-	-
CO-5:	analyze optical processes in	semiconductor materials for various optoelectronic devices	2		-	3		_	-	-	-	-	-	-	-	3	-

Unit-1 - P-N Junction 9 Hour

Physics of the p-n junction formation, Energy band diagram of a p-n junction, Estimation of the electric field, electric potential, and built-in potential, Depletion approximation and estimation of space charge width, Depletion layer capacitance and its estimation, Linearly graded junction in thermal equilibrium, Arbitrary doping profile and understanding the doping profile from 1/C2-V plot, Qualitative description of charge flow in a p-n junction, Ideal current-voltage characteristics of a p-n junction, Derivation of Shockley equation (ideal- diode equation), Generation-recombination process and its effect, Reverse bias breakdown mechanisms in a pn junction, Zener and Avalanche breakdown, Transient behavior of a p-n junction, Concept of Noise in semiconductor devices, Terminal functions of a p-n junction diode, The concept of tunnel diode, p-n junction as rectifier, Zener diode, Varistor, and Varactor

# Unit-2 - Metal-Semiconductor Contacts 9 Hou

Metal-semiconductor contacts, Qualitative characteristics of energy band formation, Understand the ideal junction properties, Theoretical considerations in estimating the barrier height, Nonideal effects on the barrier height, Qualitative explanation of image-force-induced lowering of the potential barrier, Current transport processes in metal- semiconductor contacts, Comparison of the Schottky barrier diode and the p-n junction diode, Metal-semiconductor Ohmic contacts, Concept of ideal nonrectifying and tunneling barriers, Tunneling in Ohmic contact structures, The concept of triangular barrier and the Fowler–Nordheim tunneling formula, Methods to experimentally measure the barrier height, Current-voltage and capacitance-voltage measurements, Photoelectric measurements, Figure of merit of ohmic contacts and its determination, the concept of specific contact resistance, Contact resistance of highly doped ohmic contact

Unit-3 - BJT 9 Hour

Fundamentals of BJT operation, Operation modes of a BJT, Structure and working of p-n-p and n-p-n transistors, Band diagram and static characteristics, Factors involved in transistor amplification, BJT fabrication, Non ideal effects in BJT, The physical mechanisms of the current gain limiting factors, The current-limiting factors from the current components in the transistor, Frequency limitations of transistors, The voltage breakdown mechanisms in a bipolar transistor, Heterojunction BJT, Schottky and Photo transistors, Field-effect transistors (FETs), Principle of operation of JFET, Concept of pinch-off and saturation, I-V characteristics of JFET, MOSFET—Principle of working and fabrication, Modes of operation, MOSFET device scaling, Short channel effects in MOSFET, Advanced MOSFET structures, Metal Gate-High-k and Enhanced Channel Mobility Materials and Strained Si FETs, Complementary MOS structure and its formation, CMOS process integration, Dynamic effects in MOS capacitors—The Charge-coupled device, Basic CCD structure and its applications, 3d stacking, CMOS formation with process integration

Unit-4 - Semiconductor Hetero Structures 9 Hour

Isotype and anisotype semiconductor heterostructures - energy band diagrams, Current density equations and physical interpretation, boundary conditions, Periodic and nonperiodic structures - Concept of quantum well, superlattice, and resonant tunnelling structures, Applications of the Schrodinger equation, The importance of III-V semiconductor materials, Concept of high-electron mobility transistors (HEMT), Two-dimensional electron gas, Concept of modulation doping in HEMT, Basic device structure of AlGaAs/GaAs HEMT and I-V characteristics, Output characteristics and channel related phenomenon

Unit-5 – Photo Generation 9 Hour

Photogeneration of carriers in a p-n junction, Types of Photodiodes, Solar radiation and ideal conversion efficiency of a solar cell, Physics of solar cell, Device configuration and technology roadmap, solar cell materials, Solar cell parameters and efficiency calculation, Design principle of photodetector, Types of photodetectors and characteristics, Light-emitting diodes, Basic device structure and the concept of radiative recombination, Materials of choice and technology roadmap, Specifications used in denoting the practical LED bulbs, Physics of laser action, Gain knowledge of stimulated emission and population inversion, Fabrication of p-n junction laser, Emission spectra, Structure and need of heterojunction lasers, Materials for semiconductor lasers and quantum cascade lasers

Lagraina	1.	S M Sze, Kwok k. Ng, "Physics of semiconductor devices" - John Wiley & Sons, Inc., 200	3.	E F Schubert, "Physical Foundations of Solid-state Devices" - 2009
Learning	2.	Ben G. Streetman, Sanjay Kumar Banerjee, "Solid State Electronic Devices", Pearson Edu	- 4.	Donald A. Neamen, "Semiconductor Physics and Devices: Basic" - Principles" -
Resources		cation Ltd, 2016		McGraw Hill, Fourth Edition, 2011.

earning Assessm		Continuous Learning Assessment (CLA)							
	Bloom's Level of <mark>Thinking</mark>	Formative CLA-1 Average of unit test (50%)	Life-Long Le CLA-2 (10%)	2		native nmination nightage)			
		Theory Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	20%	20%	- 0	20%	-			
Level 2	Understand	20%	20%		20%	-			
Level 3	Apply	40%	40%	-	40%	-			
Level 4	Analyze	20%	20%		20%	-			
Level 5	Evaluate		12 E 15 5 L	T	-	-			
Level 6	Create	77 - W. H. S. T Y	A. C.	<b>1</b>		-			
	Total Total	100 %	100 %	6	100	) %			

Course Designers	11111	· V / • /
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. D.K. Aswal, National Physical Laboratory, dkaswal@nplindia.org	1. Prof. M.S. Ramachandra Rao, IITM Chennai, msrrao@iitm.ac.in	1. D <mark>r. S. Cha</mark> ndramohan, SRMIST
2. Dr. S. Sudhakar, CSIR-CECRI, sudhakar@cecri.res.in	2. Prof. S. Balakumar, University of Madras,	2. Dr. E. Senthil Kumar, SRMIST
	balakumar@iunom.acs.in	/ 15 T

Course	21NTE226T Course	MOLECULAR SPECTROSCOPY AND ITS APPLICATIONS	Course	Е	PROFESSIONAL ELECTIVE	L	Τ	Р	С	
Code	Name	WOLECOLAR SPECTROSCOPT AND ITS AFFLICATIONS	Category	E	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil	
Course Offeri	ng Department	Physics and Nanotechn <mark>olo</mark>	gy Data Book / Codes / Standard	S	Nil	

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Course L	earning Rationale (CLR):	The purpose of learning this course is to:					F	rogra	am Ou	tcome	s (PO	)					rogra	
CLR-1:	illustrate the extraction of mo	lecular symm <mark>etry using gr</mark> oup theory		1	2	3	4	5	6	7	8	9	10	11	12		pecifi ıtcom	
CLR-2:	understand light matter intera	action		dge	7	of	SL					Work		9				
CLR-3:	understand rotational and vib	orationa <mark>l transition</mark> and their spectroscopy		Knowlec	S	evelopment	investigations ex problems	зде	ъ	. \				Finance	gu			
CLR-4:	understand electronic transiti	ion in <mark>atoms an</mark> d molecules and their spectroscopy	7		Analysis	udo	estig	ol Usage	r and	۲ % ک		Team	Ej	& ∃	earning			
CLR-5:	concept of electron and nucle	ear s <mark>pin</mark>		=ngineering		ന ഗ		P	engineer sty	ment ability	N	<u>8</u>	ommunication	Project Mgt.				l
	·			ine	Problem	ign/	Conduct of compl	Modern	et et	iron	S	ndividual	E E	ect	Long	7	)-2	-3
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	À.	Elig	Prot	Des	Con	Moo	The soci	Enviro <mark>nme</mark> Sustainabi	Ethics	lndi	S	Proj	Life	PSO-1	PS0-2	PSO.
CO-1:	classify the symmetry of mole	e <mark>cules us</mark> ing group theory	1	3	3	-	-	-	-	-		-	-	-	-	2		-
CO-2:	identify the selection rules for	spectroscopic transitions within atoms and molecules	7	3	2	187	4			-	1	-	-	-	-	3		-
CO-3:	analyse spectroscopic data o	btained from Microwave, Raman and IR spectroscopy		3	2.44	-1	3	- (		-		-	-	-	-	-	2	-
CO-4:	interpret electronic transitions	s and the photoelectron spectra of molecules	1	-3	2	1-1	-		-	-		-	-	-	-	-		3
CO-5:	predict the relative intensities	and selection rules in NMR and ESR spectra		3	3	- 1	-	- 1	-	-	-	-	-	-	-	-	2	-

Unit-1 - Group Theory 9 Hour

Introduction to group theory- Properties of a group-Subgroup and Class-Symmetry point groups- Symmetry elements, operations and point groups - Molecules and point groups - Representations Reducible and Irreducible representations-Great Orthogonality Theorem and its consequences, Character tables-Wavefunctions as bases for irreducible representation- Schonflies notation-Point Group Determination-Symmetries of molecular orbitals - Symmetries of normal modes of molecules -Applications of Symmetry - Prediction of Dipole Moment and Optical Activity- Selection rules-Application of Group Theory to Quantum Mechanics- Degenerate Eigen Functions

## Unit-2 - Interaction of Radiation with Matter

9 Hour

Interaction of radiation with matter- Regions of the electromagnetic radiation- origin of spectrum-Spectroscopic transition between two stationary states-Transition probability and Selection Rules- Absorption and emission of a photon-Einstein A and B co-efficients-Line shape functions-Spectral broadening mechanisms -Fourier Transform-spectral resolution-Intensity of spectral lines-Born Oppenheimer Approximation - rotational, vibrational and electronic energy levels

## Unit-3 - Microwave Spectroscopy

9 Hour

Microwave spectroscopy-Classification of molecule– Rigid rotor model– Effect of isotopic substitution on the transition frequency- Non-rigid rotor— Stark effect - Nuclear and electron spin interaction-IR spectroscopy-Harmonic Oscillator and Vibrational energies of diatomic molecules - Force Constant and Bond strength - Anharmonicity - Morse potential energy diagram -P.Q.R. Branches - Vibration of polyatomic molecules -Factor affecting the band position & intensities-Raman Effect - Classical Theory - Quantum Theory - Pure Rotational, Vibrational and Rotational- Vibrational Raman Spectra - Mutual Exclusion Principle

## Unit-4 - Electronic Spectroscopy

9 Hour

Electronic spectroscopy-Principal quantum number and energy levels, spin-orbit coupling, singlet and triplet states-Energy of electronic transitions - Electronic states of diatomic molecules - Franck-Condon Principle - Vibrational fine structure and Herzberg-Teller vibronic coupling - UV - absorption - decay of an electronically excited state, photophysical processes, Jablonsky diagram Fluorescence - Phosphorescence - excited state lifetime and quantum yield-Photoelectron spectroscopy— Basic Principles - Photoelectric Effect - Ionization Process - Koopman's Theorm - Photoelectron spectra of simple molecules - ESCA - Chemical Information from ESCA - Auger electron transitions

Unit-5 - Atoms in Magnetic Fields 9 Hour

Atoms in magnetic fields- The normal Zeeman effect -Spin-orbit coupling in alkali atoms -The anomalous Zeeman effect -Russel-Saunders coupling and jj-coupling in many-electron atoms -Microstates and eigenstates -NMRspectroscopy -Nuclear Spin - NMR active nuclei - Spinning Nuclei-Magnetic moments-Larmor Precision - Theory of NMR - Nuclear Resonance— Nuclear Saturation and Relaxation Process—Instrumentation— Shielding of magnetic nuclei— Spin —Spin interactions-Electron Spin Spectroscopy -Types of substances with unpaired electrons (ESR active species) -Basic Principle of ESR spectrum -g-value and factors affecting g- value—Determination of value of g - Hyperfine splitting constant -Zero Field splitting-Applications of ESR Spectrum

	1.	Peter Atkins, Julio de Paula Atkins, "Physical Chemistry", W. H. Freeman and		
		Company, New York, 2010	7.	Donald A. McQuarrie and John D. Simon, Physical Chemistry - A Molecular Approach, University
	2.	Thomas Engel, Quantum Chemistry & Spectroscopy, Pearson 2013	****	science books, 1997
Learning	3.	Collin Banwell, Mc Cash, "Fundamentals of Molecular Spectroscopy", McGraw Hill	8.	Alan Vincent, Molecular Symmetry and Group Theory (Second Edition), John Wiley &Sons,
Resources		publishing, 2001		LTD, 2010 9. Online source: Molecular Spectroscopy
	4.	G.Aruldhas, "Molecular structure and spectroscopy", Prentice Hall, 2001		https://www.youtube.com/watch?v=RBPtLn3M8TI http://mpbou.edu.in/slm/mscche1p4.pdf
		P.S.Sindhu, "Fundamentals of molecular spectroscopy" New age international		
		publishers,2006	4.3	

Learning Assessm	ent	1	-11-1		TAKES IN							
			F 500	Continuous Learnin	g Assessment (CLA)		Summative					
	Bloo <mark>m's</mark> Level of <mark>Thinking</mark>	7	Formative CLA-1 Average of (50%)			Learning 4-2 %)	Final Exa	native amination eightage)				
			Theory	Practice	Theory	Practice	Theory	Practice				
Level 1	Remember		20%	100 miles	20%		20%	-				
Level 2	Understand		20%	437 2	20%	-	20%	-				
Level 3	Apply		40%	1 mg - 400 - 500	40%		40%	-				
Level 4	Analyze		20%		20%		20%	-				
Level 5	Evaluate		- W. Land P.					-				
Level 6	Create		100	- 1927	<del>}</del>	4	-	-				
	Total Total		100 %	1.7	100	) %	10	0 %				

Course Designers	7 7	100	
Experts from Industry		Experts from Higher Technical Institutions	Internal Experts
1. Dr.D.K.Aswal, National Physical Laboratory	, <mark>dkaswa</mark> l@nplindia.org	1. Dr.G.Aravind, IIT Madras, garavind@iitm.ac.in	1. Dr.R.Anni <mark>e Sujatha,</mark> SRMIST
2. Dr. Krishna Surendra Muvvala, Saint Goba	n Research India, India,	2. Dr.M.S.Ramachandra Rao, IIT Madras, msrrao@iitm.ac.i	in 2. Dr.E.Se <mark>nthil Kum</mark> ar, SRMIST
Krishna.muvvala@saintgobain.com	//	ADMINISTRATION	

Course	21NTE327T	Course	NANO CATALVETS	Course	_	PROFESSIONAL ELECTIVE	L	Т	Р	С
Code	ZINIESZII	Name	NANO CATALTSTS	Category		PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offerin	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:		Program Outcomes (PO)													rogra	
CLR-1:	aquire the concepts of chem	nistry of nanoc <mark>atalyst</mark>		1	2	3	4	5	6	7	8	9	10	11	12	_	pecifi utcom	
CLR-2:	CLR-2: understand the catalytic kinetics					of	SL		-	la.		or S		9				
CLR-3:	CLR-3: describe the reaction kinetics of adsorption and descrption processes				S	nent	ation	зде	ъ			×		Finance	Б			ł
CLR-4:					Analysis	evelopment	investigations ex problems	ool Usage	r and	∞ >		Team	igi	∞ర	earning			ł
CLR-5:	CLR-5: gain knowledge about the working mechanism of nanocatalytic materials		Engineering		deve	Ψ.	_	engineer stv	Environment & Sustainability		<u>8</u>	ommunication	Project Mgt.				ł	
	<u>'</u>		77	inee	Problem	sign/de	onduct	Modern	er et e	iron	တ္သ	ndividual	חשר	ect	Long	7	-5	<u>ښ</u>
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	, At	Eng	Prof	Designation	o o	Moc	The Soci	Env	Ethics	İndi	Sol	Proj	Life	PSO-1	PSO-2	PSO-3
CO-1:	express the mechanism of n	n <mark>aterials f</mark> or using as catalyst		2	3-1	-	3	-	-	-		-	-	-	-	-	-	-
CO-2:	apply isotherms for different	<mark>micro an</mark> d nano porous catalytic materials	7	3	2	1	14	- 1	-	-	1	-	-	-	-	3	-	
CO-3:	evaluate the photocatalyst fo	o <mark>r enviro</mark> nmental remediation		No.	2	-7	<i>-</i> -	- (	-	3	-	-	-	-	-	-	-	-
CO-4:	<b>0-4:</b> analyze the working of noble metals as nanocatalyst			-3	1.0	1	-	-	-	-		-	-	-	-	2		
CO-5:	apply the nanoscale paradig <mark>m in ter</mark> ms of catalytic property				3		-	- )	_	-	-	-	-	-	-	-	-	-

## Unit-1 - Introduction to Catalysis

9 Hour

Introduction to catalysis – classifications - heterogeneous catalysis - Reaction on the solid surfaces - Active sites- Activation energy - Adsorption isotherms - Physisorption and chemisorptions - Brunauer-Emmett-Teller (BET) theory- Total surface area- Pore volume and pore size distribution - Hg porosimetry method - N2 adsorption-desorption method - Reaction mechanism - Kinetics of the heterogeneous catalytic reactions - Activation energy (Arrhenius equation, Eyring equation) - Terminology in catalysis, TO(Turnover), TON(Turnover number), TOF(Turnover frequency) - Sequences involved in a catalysed Reaction - Asymmetric synthesis using a catalyst

## Unit-2 - Adsorption and Desorption Processes

9 Hour

Adsorption and Desorption Processes - Adsorption Rate - Desorption Rate - Catalytic activity (bulk and nanoscale) - Catalytic activity determinationfor metal/metal oxidenanostructures - Langmuir-Hinshelwood mechanism for nanocatalyst - Mass transport - Diffusion controlled process - Adsorption equilibrium on uniform - surfaces-Langmuir isotherms single-site (non-dissociative) adsorption - Dual-site (dissociative) adsorption of the Langmuir isotherm - Adsorption equilibrium on non-uniform surfaces-Langmuir isotherms- The Freundlich isotherm - The Temkin Isotherm - Activated adsorption - Catalytic efficiency - Application of metal nanoparticles in - organic reactions - Environmental remediation

#### Unit-3 - Kinetics and Photocatalytic Activity

9 Hour

Kinetics and photocatalytic activity - Introduction to photocatalyst - Basics of electrochemistry – Photochemistry - Electronic structure and photocabsorption - Jablonskii diagram - Structure of photocatalysts - Solar spectrum - Fundamental understanding of semiconductor interfaces - Principles and relevance to - photocelectrochemical mechanism - Photocatalysis mechanism - Properties of good photocatalysts - Advantages of photocatalysts - Types of photocatalysts - Homogeneous and heterogeneous photocatalyst - Carbonaceous photocatalysts - Plasmonic photocatalysts. - Application of photocatalyst

Unit-4 - Catalyst in Nanoscale 9 Hour

Catalyst in Nanoscale - Noble metals nanocatalyst (Ru, Rh, Pd, Pt, etc) - Polymer stabilized Rh and Ru nanoparticles - Oxide supports for nano-catalysts; carbon supports for nano-catalysts - Gold nanoparticles based catalyst - Gold vs. Palladium catalysts for the aerobic oxidation of alcohols - Oxide based catalyst - Metal free catalyst (CNT, Graphene based - Transition metal dichalcogenides based catalyst - Microporous materials: Zeolites-Zeotypes Catalyst) - Overall steps in zeolite crystallization - Zeolite synthesis via. - dry gel route - Zeolite Y- determination of surface acidity - Shape-selectivity - Synthesis of Mesoporous Silica MCM-41 - Mesoporous Carbon - Sulfated Zirconia - Ag/SiO2 composite nanocatalysts

Unit-5 - Applications 9 Hour

Applications of Nano-Catalyst - Toxic Gases conversion using nanocatalyst: NOx - CO oxidation using nanocatalyst - Hydrogenation of compounds with C≡C bonds, hydrogenation of aromatic compounds – Greenhouse gases: CO2 conversion - Dissociative mechanism: oxygen reduction reaction using nanocatalyst - Associative mechanism: oxygen reduction reaction using nanocatalyst - Hydrogen Production using oxide and dichalcogenides based catalyst - Energy processing: Processes involved in crude oil refinery - Gasoline production − Cracking - Fuel cell - Biomass gasification − Biodiesel - Photocatalyst for self-cleaning - Purification of water and air - Environmental remediation - Future possibilities

	1. M. Albert Vannice, Kinetics of Catalytic Reactions, Springer, 2008.	3.	Kurt W. Kolasinaski, Surface Science: Foundations of Catalysis and Nanoscience, John
Learning	2. Nick Serponeand Ezio Pelizzetti, Photocatalysis:Fundamentals and Application, Wiley		Wiley & Sons, England, 2nd Edition, 2005
Resources	Interscience, 1st Edition, 1989	4.	Nanoporous Materials: Synthesis and Applications, Edited by Qiang Xu, CRC Press, 1st
			Edition, 2013

earning Assessm	nent			2.73	A STATE OF THE	10010						
Bloom's Level of Thinking			CLA-1 Avera	native	11 11 11 11	g Assessment (CLA) Life-Long CL (10		Summative Final Examination (40% weightage)				
		1	Theory	17.	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember		20%		65.4°C 2°C	20%	A -	20%	-			
Level 2	Understand		20%	1.20	man delication	20%		20%	-			
Level 3	Apply	J. 1	40%	4 1 4		40%		40%	-			
Level 4	Analyze	7. 1	20%			20%		20%	-			
Level 5	Evaluate	1	-	design (	- 1977	-	- 4	-	-			
Level 6	Create		1-		- 11.7	-		-	-			
	Total		100	0 %	1111	100	) %	100	0 %			

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Exp <mark>erts</mark>
1. Dr. P. Sudhakara, CLRI – CSIR, Jalandhar,	1. Dr.G. Arthanareeswaran, NIT Trichy, arthanareeg@gmail.com	1. Dr. N. Angeline Little Flower. SRMIST
sudhakarp@clri.res.in	AND THE CO. PRINTS OF ALL SALES	
2. Dr. Sudhakar selvakumar, CSIR-Central Electrochemical	2. Dr. A. Kannan, IIT Madras, kannan@iitm.ac.in	2. Dr. M.Alagiri, SRMIST
ResearchInstitute, ssudhakar79@gmail.com		

Course	21NTE421T	Course	SURFACE ENGINEERING	Course	Е	PROFESSIONAL FLECTIVE	L	Т	Р	С	;
Code	Z	Name	SURFACE ENGINEERING	Category		PROFESSIONAL ELECTIVE	3	0	0	3	,

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offerin	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

The purpose of learning this course is to:

Oourse E	The purpose of learning this course is to.	11 .	4 .			i iogi	ann Ou	toomic	.5 (i O	')					:E	:_
CLR-1:	outline the fundamentals and failure micro mechanism occurrence in science engineering processes	1	2	3	4	5	6	7	8	9	10	11	12	_	pecifi utcom	
CLR-2:	illustration and overview on the co-relations about the micro mechanism failures for optimizing the surface engineered microstructures	edge		Q	of		ety	ability		ᆠ						
CLR-3:	ntroducing about the various phenomena for identifying the appropriate Engineering approach towards levice development		S	nent of	gations	age	SOCI	Sustain		m Work		inance	ming			
CLR-4:	explaining advanced surface engineering processes	Kno	alysi	elopme	estig	S	er and	t & S		Team	tion	∞ ⊤	ami			
CLR-5:	introduction on various state-of-the-art Surface Characterization techniques for thin bi- and multi-layers	neering	lem An	gn/deve	duct involex pro	ern Too	engine	onmen.	ςΩ	idual &	ommunicatior	ect Mgt.	ong Le	<u>-</u>	-2	ငှ
Course O	utcomes (CO):  At the end of this course, learners will be able to:	Engi	Prob	Design	Conc	Mode	The	Envii	Ethic	Individu	Com	Proje	Life I	PSO	PSO	PSO
CO-1:	gaining knowledge about the <mark>fundam</mark> entals and failure micro mechanisms occurrence in surface engineering process		2	77.7	7	- 1		-		-	-	-	1	3	-	-
CO-2:	earning knowledge with enhanced understanding to become capable to co-relate the micro mechanist failures for optimizing the surface engineered microstructures	<i>m</i> 3	2	1-1	-	-		-		-	-	-	ı	3	-	-
CO-3:	gaining knowledge for identifying the appropriate Engineering approach towards developing devices for innovative applications	or 3		2	-	- /		-		-	-	-	-	-	2	-
CO-4:	acquiring knowledge and sou <mark>nd unde</mark> rstanding for advanced surface engineering processes	3	-	2	-	-		-	-	-	-	-		2	-	-
CO-5:	tilizing knowledge for state-o <mark>f-the-art</mark> Surface Characterization techniques for thin bi- and multi-layers		-	2	7	-	-1-	-	- 1	-	-	-	-	-	_	3

Unit-1 - Importance 9 Hour

Importance and scope of surface engineering, conventional surface engineering practices like pickling, grinding, and buffing; Surface degradation, Wear and corrosion, Surface dependent properties and failures, Surface and surface energy: Structure and types of interfaces, surface energy and related equations, Types of wear: Abrasive wear, Adhesive wear, Surface fatigue, Fretting wear, Erosive wear, Corrosion and oxidation wear

Unit-2 - Surface Roughness 9 Hour

Role and estimate of surface roughness in Surface engineering, Surface engineering by material addition: liquid bath - hot dipping, Electrodeposition; Surface modification of steel and ferrous components: Pack carburizing; Surface modification of ferrous and non-ferrous components: Aluminizing, calorizing, diffusional coatings; Surface modification using liquid/molten bath: Cyaniding, liquid carburizing; Surface modification using gaseous medium: Nitriding carbonitriding

# Unit-3 - Surface Engineering by Energetic Beams

9 Hour

Program

Program Outcomes (PO)

Surface engineering by energetic beams: scope and principles; Laser assisted microstructural modification - surface melting, hardening, shocking; Laser assisted compositional modification - surface alloying of steel and non- ferrous metals and alloys, surface cladding, and composite surfacing; Electron beam assisted modification and joining; Ion beam assisted microstructure and compositional modification; Flame spray; Plasma coating; High-velocityoxy-fuel (HVOF), Cold spray

## Unit-4 - Thermal Evaporation

Course Learning Rationale (CLR):

9 Hour

Thermal Evaporation, Electron beam (e-beam) evaporation, Molecular beam Epitaxy (MBE), DC sputter deposition, RF sputter deposition; Ion Beam deposition; Hybrid PVD coating processes; Plasma-enhanced chemical vapor deposition (PECVD), Atomic layer Deposition (ALD; Plasma and ion beam assisted surface modification; Ion implantation and Ion beam mixing.

Unit-5 - Measurement 9 Hour

Thickness measurement: Ellipsometry; porosity & adhesion of surface coatings; Measurement of residual stress & stability; Surface microscopy & topography via. scanning probe microscopy (SPM: AFM, STM and MFM); Reflection High Energy Electron Diffraction (RHEED), Low Energy Electron Diffraction LEED, X-ray Photoelectron Spectroscopy (XPS), X-ray Diffraction (XRD), Scanning electron microscopy (SEM); Energy Dispersive X-ray analysis (EDX), Focused ion Beam (FIB)

	1.	Peter N	/lartin, "	Introduction	on to Surface E	ngin	eering and F	unc	tionally	Engineered M	aterials"
Learning Resources	2.	Devis,	/illey.20 J.R.,"	Surface	Enginee <mark>ring</mark>	for	Corrosion	&	Wear	Resistance",	Mane

- 4. K.G. Budinski, Surface Engineering for Wear Resistances, Prentice Hall, Englewood
- Publicsing.2001
- 3. Mircea K. Bologa, "Surface Engineering and Applied Electrochemistry", Springer. Journal
- 5. Yip-Wah Chung, Practical Guide to Surface Science and Spectroscopy (AP) ,2001 6. Kelly, Groves and Kidd, Crystallography and Crystal Defects (John Wiley) 2010

earning Assessm	nent		0	A(O/A)						
	Bloom's Level of Thi <mark>nking</mark>	CLA-1 Avera	continuous Learning native ge of unit test 19%)	g Assessment (CLA) Life-Long L CLA- (10%	-2	Summative Final Examination (40% weightage)				
	12/	Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	20%	Carlot Carlot Carlot Carlot	20%		20%	-			
Level 2	Understand	20%	A Section of the second	20%		20%	-			
Level 3	Apply	40%	1881 / Page 1997	40%		40%	-			
Level 4	Analyze	20%	Mile 1887 1997	20%		20%	-			
Level 5	Evaluate	27 77 11		· 中国为1967年4月			-			
Level 6	Create	and the second second	St. 337 6 7 2	1 1 1 1 1 1 1 1 1		-	-			
	Total Total	100	)%	100	%	100	0 %			

Course Designers	The state of the s	
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Muhammad Shahid Anwar, CSIR - Institute of Minerals and	1. Dr. S. Amirthapandian, Surface Science, Materials	1. Dr.Jitendra Kum <mark>ar Tripath</mark> i, SRMIST
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2. Dr. Ashutosh Rath, CSIR - Institute of Minerals and Materials	2. Dr. K. Ganesan, Materials Physics Division, IGCAR,	2. Dr. S. Chandr <mark>a m</mark> ohan, SRMIST
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Course	21NTE422T	Course	MICROELECTRONICS AND VLSI	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С	
Code	Z 11N 1 E4ZZ 1	Name	MICROELECTRONICS AND VLSI	Category		PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offerin	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

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Course Lo	earning Rationale (CLR):	The purpose of learn	ning this course is to:	CIENCI				F	rogra	ım Ou	tcome	s (PO	)				Pı	rograi	n
CLR-1:	acquire knowledge on basic e	electronic co <mark>mponents a</mark>	<mark>and</mark> physical effects at se	miconductor junctions	1	2	3	4	5	6	7	8	9	10	11	12	_ '	pecifi tcom	
CLR-2:	learn construction of MOSFE	Ts and its <mark>operation</mark>	70.		dge	7	of	SL			1		Work		9				
CLR-3:	understand operation of vario	ous type <mark>s of ampli</mark> fiers	AV A	-50 50c-	Knowlec	S	evelopment	investigations ex problems	зде	Ъ	. \				Finance	Б			
CLR-4:	realize IC and its passive cor	npon <mark>ents</mark>	N	All Carlos		Analysis	lopi	estig	ool Usage	er and	t &		Team	tion	∞ర	earning			
CLR-5:	understand usage and manag	gem <mark>ent of p</mark> ower in IC	) /		ring	-	deve	Ψ.	_	engineer ety	men		रू ज	nica	Mgt.				
Course O	utcomes (CO):	At the end of this co	urse, learners will be ab	le to:	Engineering	Problem	Design/d solutions	Conduct of compli	Modern	The en society	Environment Sustainability	Ethics	Individual	Communication	Project Mgt.	Life Long	PSO-1	PS0-2	PSO-3
CO-1:	apply basic semiconductor ph logic gates	n <mark>ysics fo</mark> r the working of	f semiconductor devices, I	Boolean algebra, operation of	3		er in Nort	2	F	Z	-	-	-	-	-	-	3	-	-
CO-2:	analyze models of MOSFET	and CMOS	100	<b>"是我是我们</b>	2	7.9	15	2	-7	-	-	÷	-	-	-	-	-	-	-
CO-3:	apply CMOS designing and c	ircuits	五千岁5.7年	18 18 18 18 18 18 18 18 18 18 18 18 18 1	3	华石	- /	3	- 1		-		-	-	-	-	-	-	-
CO-4:	visualize importance of interc	<mark>on</mark> ne <mark>ct</mark> s and its usage	Mary Carl	The second second	3		-	2	- 1	-	-	-	-	-	-	-	-	-	-
CO-5:	evaluate power management	and supply in IC		The second second	2	4	تليار	3	-(	-	-	1	-	-	-	-	-	-	-

Unit-1 - Introduction 9 Hour

Introduction to electronic materials and classification, Origin of energy band gap, Density of states, Fermi energy level, Types of semiconductors, Doping in semiconductors, Formation of p-n junction, Electrostatics of p-n junction transport and operation, Diode as circuit element, Large signal and small signal operation of diode, Applications of diodes: limiting circuits-voltage doubler-shifters and switches, Current-voltage characteristics and operation of bipolar junction transistors, Ebers-Moll representation of transistor for circuit element, AC operation of transistor, Large and small signal model, Amplifiers, Transistor connections in various modes, Number systems: Binary and octal numbering-Hexadecimal numbering-Conversions between number systems, Boolean algebra, Logic gates: Truth tables for AND, OR, NOT, NAND, NOR gates

Unit-2 - MOFET, N- and P-MOSFET 9 Hour

Introduction to MOFET, N- and P-MOSFET, DC operation of MOSFET, Derivation of I-V characteristics, Modelling of MOSFET, Small signal model, AC operation of MOSFET, Enhancement and depletion modes, Threshold voltage, Introduction to Complementary Metal Oxide Semiconductor (CMOS), CMOS inverter and its operation

Unit-3 - MOSFET 9 Hour

MOSFET amplifiers, Realization of current sources, Differential amplifier: general considerations-MOS differential pair-cascode diff. amp, Cascode stages and current mirrors, Operational amplifier: as an black box-Op-Amp based circuits-non-linear functions and non-idealities, Frequency response of MOSFET: concepts-high frequency models-low and high frequency response, process integration

Unit-4 - ICs 9 Hour

Introduction to Integrated circuits (ICs), Monolithic integration, Active and passive devices, Passive devices: resistor-capacitor-inductor, Interconnects, Interconnect Parameters: Capacitance-Resistance-Inductance, Electrical wire model: ideal wire-lumped model-lumped RC model, Transmission line response, Types of terminations, VLSI, introduction to packaging

Unit-5 - Power Management 9 Hour

Power Management in IC, MOSFET Structures and comparison, Power analysis, Scaling effects, Leakage power dissipation, Challenge of power management in IC: Multi-Vth Technology- Performance Boosters-Layout-Dependent Proximity Effects-Impacts on Circuit Design, Principles in Power Management Module: Load Regulation- Transient Voltage Variations- Conduction Loss and Switching Loss- Power Conversion Efficiency

ſ	corning	1. Behzad Razavi. Microelectronics, 2nd Ed, John Wiley & Sons, 2015	3. Ke-Horng Chen. Power management techniques for integrated circuit design, Wiley,
١.	Learning	2. Jan M Rabaey; Anantha P Chandrakasan; Borivoje Nikolic Digital integrated circuits: a	2016
ľ	Resources	design perspective, Pearson <mark>Education, 200</mark> 3	

_earning Assessm	nent			- 14/V		_					
	Bloom's Level of Thinking	CLA-1 Avera	Continuous Learnino mative age of unit test 50%)		y Learning A-2 0%)	Final Exa	Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice				
Level 1	Remember	20%		20%	(- A	20%	-				
Level 2	Understand	20%	10, 174, Walter 11	20%		20%	-				
Level 3	Apply	40%	Carlot Mary Mary	40%		40%	-				
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	T <mark>otal</mark> /	10	00 %	10	0 %	100	0 %				

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Course Designers	The second secon	
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Vinay Kumar Gupta, NPL, guptavinay@nplindia.org	1. Prof. K. Sethupathi, IITM Chennai, ksethu@iitm.ac.in	1. Dr. Abhay A. Sag <mark>ade, SRM</mark> IST
2. Dr. Pramod Rajanna, HHV Bangalore, pramod@hhv.ac.in	2. Dr. Aditya Sadhanala, IISc Bangalore, sadhanala@iisc.ac.in	2. Dr. P. Malar, SRMIST

Course	21NTE424T	Course	SENSORS AND TRANSDUCERS	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С	
Code	Z 11N 1 E4Z4 1	Name	SENSORS AND TRANSDUCERS	Category		PROFESSIONAL ELECTIVE	3	0	0	3	٦

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	. 11	1			F	rogra	m Oı	itcome	s (PC	<b>)</b> )					rogra	
CLR-1:	understand basic principles	and characteri <mark>stics of sens</mark> ors and transducers		1	2	3	4	5	6	7	8	9	10	11	12	_	pecifi ıtcom	
CLR-2:	gain knowledge on mechani	cal and ele <mark>ctromecha</mark> nical sensors		a)	1	/	of		ety	1		_						
CLR-3:	get acquainted with thermal	sensors <mark>and its ty</mark> pes		edge	h.	nt of	ions	Ф	society			Work		auce				ł
CLR-4:	know about magnetic senso	rs and <mark>radiation</mark> sensors		Knowledge	Sis	bme	vestigat oblems	Sag	and			eam	_	Finance	earning			
CLR-5:	gain knowledge on electro technologies and application	chemical sensors and apprehend knowledge on recent trends in se	nsor	ering	em Analysis	ign/development tions	.⊑ Ъ	ern Tool Usage	engineer a	vironment & stainability	S	ndividual & Te	ommunication	oject Mgt. &	ong Lear	<del>-</del>	5	က္
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	- 1	=ngine	Problem	Designation	Cond	Modern	The	Envir S <mark>ust</mark> a	Ethics	ndivi	Somi	Proje	-ife L	-0Sc	-SO-2	-080
CO-1:	analyse calibration technique	e <mark>s and si</mark> gnal types of sensors		3	*	J. 1	2	7	L	-	H	-	-	-	-	3	-	-
CO-2:	expertise in various types of	Sensors & Transducers and their working principles	J.	3	-	-	-}-	- /		-		-	-	-	-	-	-	-
CO-3:	evaluate performance chara	cteristics of different sensors and transducers	nie.	3	2	- 3	-	-	==	-	-	-	-	-	-	-	-	-
CO-4:	predict exactly the expected	performance of various sensors	. 4	3	2		-	-	-	-	1	-	-	-	-	-	-	-
CO-5:	develop advance techniques	in sensor technology and devise smart sensors for real time applications		3		2	-	-(		-	1	-	-	-	-	-	-	-

Unit-1 - Measurements 9 Hour

Measurements-basic method of Measurement, errors, classification of errors, error analysis, statistical methods, sensors/transducers-introduction, principles of sensors/transducers, classification of sensors/transducers, static characteristics of sensors/transducers, cccuracy-precision-resolution-minimum detectable signal, threshold-sensitivity-selectivity and specificity-non-linearity, hysteresis-output impedance-isolation and grounding, dynamic characteristics, zero order and first order sensors, second order sensors, electrical characterization, mechanical and thermal characterization, optical characterization-chemical/biological characterization

## Unit-2 - Mechanical and Electromechanical Sensors

Hour

Mechanical and electromechanical sensors, resistive potentiometer, strain gauge, Inductive sensors, sensitivity and linearity of sensor, ferromagnetic plunger type transducers, electromagnetic transducer, magneto strictive transducer, capacitive sensors, parallel plate capacitive sensor, serrated plate capacitive sensor, variable thickness dielectric capacitive sensor, stretched diaphragm variable capacitance transducer, electrostatic transduce, piezoelectric elements, piezoelectric materials, deformation modes and multimorphs, lead zirconate titanate (PZT) family, force/stress sensors using quartz resonators

# Unit-3 - Thermal Sensors

9 Hour

Thermal sensors- gas thermometric sensors, thermal expansion type thermometric sensors, acoustic temperature sensor, dielectric constant and refractive index of thermosensors, helium low temperature thermometer- nuclear thermometer, magnetic thermometer, resistance change type thermometric sensors, metal resistance thermometric sensors, thermistors, thermo emf sensors, materials for thermo emf sensors, (emf)-T(temperature) relations, thermosensors using semiconductor devices, thermal radiation sensors, detectors, pyroelectric thermal sensor, quartz crystal thermoelectric sensors, heat flux sensors, accelerometer

Unit-4 - Magnetic Sensors 9 Hour

Magnetic sensors-introduction, principles behind, yoke coil sensors, coaxial type sensors-force and displacement sensors, magneto resistive sensors- anisotropic magneto resistive sensing, semiconductor magnetoresistors, active semiconductor magnetic sensors, Hall effect sensor-sensor geometry and fabrication, variable inductance sensors, Eddy current sensors, radiation sensors-introduction-basic characteristics, types of photoresistors/photodetectors, photoemissive cell and photomultiplier, photoconductive cell-LDR, photocurrent, photo resistors and photo FETs and other devices, fibre optic sensors, temperature sensors-microbend sensors

Unit-5 – Electro Analytical Sensors

9 Hour

Electroanalytical sensors-introduction, electrochemical cell, sensor electrodes-molecular selective electrodes, chemFET, recent trends in sensor technologies, film sensors-thick and thin film sensors, semiconductor ICtechnology, micro electro mechanical system (MEMS)- micromachining, some application examples, nanosensors, Onboard automobile sensors-flow rate sensors-pressure sensors, temperature sensors-oxygen sensors, torque and position sensors, home appliance sensors, aerospace sensors-fluid velocity sensors, sensing direction of air flow- monitoring strain, force, thrust and acceleration, medical diagnostic sensors sensors for environmental monitoring

1 !	1. Ernest O Doebelin, "Measurement Systems – Applications and Design", 4th ed., Tata	3. D. Patranabis, Sensors and Transducers, 2nd ed., Prentice Hall of India, 2010
Learning	McGraw-Hill, 2009	4. D.V.S Murthy, Transducers and Instrumentation, 2nd ed., Prentice Hall of India, 20
Resources	2. John P. Bentley, "Principles of Measurement Systems", 4th ed., Pearson Education, 2000	

Learning Assessm	ent	7			A Property of the Park			
	Bloom's Level of <mark>Thinking</mark>	CLA-1 Averag	ative	rning	CL	g Learning A-2 0%)	Final Exa	mative amination eightage)
		Theory	Practice		Theory	Practice	Theory	Practice
Level 1	Remember	20%	10 Ten 15	4	20%		20%	-
Level 2	Understand	20%	S. 18 (1.2)		20%	-	20%	-
Level 3	Apply	40%	The second second		40%		40%	-
Level 4	Analyze	 20%			20%		20%	-
Level 5	Evaluate		1		A south a			-
Level 6	Create		J		· -	-4	- 1	-
	Tota <mark>l                                    </mark>	100	) %		10	0 %	10	0 %

Course Designers	
Experts from Industry	Experts from Higher Technical Institutions Internal Experts
1. Dr. Maximilian Fleischer, Siemens, Germany,	1. Dr. Somnath Chanda Roy, IIT Madras, somnath@iitm.ac.in 1. Dr. S. Yuvaraj, SRMIST
maximilian.fleischer@siemens.com	V I3 V ARN - I FAD AD IN
2. Dr. Shyam Sunder Tiwari, Sensor's technology Private Limited	2. Dr. Karuna Kar Nanda, IISc, nanda@iisc.ac.in 2. Dr. A. Karthigeyan, SRMIST
India, sst@sensorstechnology.com	The state of the s

Course	24NTE425T	Course	MICPO AND NANCELLIIDS	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С
Code	21NTE425T	Name	WICKO AND NANOFLOIDS	Category		PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	NI	gressive ourses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:			7.		F	rogra	am Ou	tcome	s (PC	<b>)</b> )					ogra	
CLR-1:	understand the theory of fluid	lics in a micro <mark>scale</mark>		1	2	3	4	5	6	7	8	9	10	11	12		pecifi tcom	
CLR-2:	gain knowledge in micro fluid	lics equati <mark>ons</mark>		dge	7	of	SL			N.		Work		99				
CLR-3:	understand the concept behi	nd visco <mark>us flow in</mark> micro scale		Knowledge	S	evelopment	investigations ex problems	зде	ъ	, N.				Finance	gu			
CLR-4:	acquire the knowledge in Mid	ero flu <mark>idic devic</mark> es and manufacturing	٠,		Analysis	lobi	estig	ool Usage	r and	∞ ×		Team	ion	<b>⊗</b>	.earning			
CLR-5:	gain knowledge scaling mate	rials <mark> for man</mark> ufacturing		Engineering		deve		_	engineer sty	ment		<u>8</u>	ommunication	Project Mgt.				
			-577	inee	Problem	ign/d tions	Conduct of compl	Modern	et e	tain	S	ndividual	E E	ect	Long	-1	)-2	
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	1	Eng	Prof	Des	o o o	Moo	The Soci	Environme Sustainabi	Ethics	lpdi	Sol	Proj	Life	PS0-1	PS0-2	PSO-3
CO-1:	apply the concept of fluidics i	n micro and nanoscale		3	2	-	-	-	7	-	-	-	-	-	-	3	3	-
CO-2:	analyze the flow and viscosity	v of the fluidics	7	3	2	177	-	- /	-	-	-	-	-	-	-	3	2	-
CO-3:	analyze the viscous flow of m	icro/nano fluidic devices		3	2		-4-	- (		-		-	-	-	-	3	-	3
CO-4:	utilize the knowledge gained	for designing micro/nano fluidic devices	1.5	-2	3	1-1	-	-	-	-		-	-	-	-	3	-	2
CO-5:	apply the various fluidic equa	tions to design micro/nano fluidic devices	- 1	3	2	1	-	- ,	-	-	1	-	-	-	-	3	2	-

## Unit-1 - Fundamentals of Kinetic Theory

9 Hour

Introduction: Fundamentals of molecular models, Micro and nanofluids – An Introduction, Basic concepts in microfluidics & Nanoscale fluidics, Binary collisions, Distribution functions, Laws of fluid flows determination of transport properties, Classification of fluid flow, Wall slip effects, Accommodation coefficients, Kinematics of Microscale Liquid Flow, Derivation of Kinematics of Microscale Liquid Flow, Pressure driven gas micro-flows, Micro flows with wall slip effects, Navier-Stokes equation, Equation's properties, Mechanism of micro flows under compression, Compressibility and its effects, Knudsen number

## Unit-2 - Kinetic Theory of Micro and Macroscopic Properties

9 Hour

Molecular models of micro and macroscopic properties, Governing equations, Applications- Preparatory concepts, Boltzmann equation, Maxwellian distribution functions, Continuum approximation, Limitations and drawbacks, Flow and heat transfer analysis of microscale, Couette flows, Liquid flow along surface, Effect of body forces in liquid flow, Concept of Heat transfer in micro-Poiseuille flows, Expression for Poiseuille flows, Theory of Two-dimensional Navier- Stokes equation, Two-dimensional Navier- Stokes equation for Steady and compressible flow, Steady and incompressible flow Navier-Stokes equation

## Unit-3 - Introduction to Microscale Viscous Flow

9 Hour

Structure of flow in a pipe or channel, One-dimensional temperature distributions in channel flow, Temperature distributions in channel flow (Quantitative approach), Velocity in slip flow of gases, Velocity in slip flow of liquids, the temperature distribution in fully developed tube flow, Nusselt number, Derivation - thin film under gravity, Properties of thin film equation, Mass transfer in thin films, A thin liquid film falling under gravity, Surface tension driven flow And its limitations, The stochastic nature of diffusion, Brownian motion, Simple model for blood flow, Non-Newtonian properties of blood

## Unit-4 - Elements of Electrochemistry and the Electrical Double Layer

9 Hour

Introduction, The structure of water and ionic species, Fabrication of A Simple Microfluidic Chip, Advantages of microfluidic devices, Chemical potential, Chemical potential (Quantitative approach), Scaling of materials, Silicon materials for the manufacture, Electrochemical potential, Acids, bases, and electrolytes, Fluidic structures, Manufacturing a fluidic structure, Qualitative description of the electrical double layer - triple layer model, Surface modifications, Different techniques involved in Surface modifications, Electrical conductivity in an electrolyte solution, Electrophoretic effect

## Unit-5 - Introduction to Electro Chemistry

9 Hour

Electrical double layer, Electro-chemical potential, Chemical potential-acid and base, Electrolyte & electrical conductivity, Semi-permeable membrane, Micro and nano fluidics devices, Applications in different fields, Fabrication and design of microfluid device, Testing of microfluid device, DNA transport, Development of artificial kidney, Electrochemical sensing, Electrochemical Micro/Nao fluidic devices, Receptor and Transducer based classification of biosensors, Types of Biotransducers, Nanopores and nanopore membrane for biochemical sensing, Single Molecule sensing devices

	1. TerrenceConlisk, "Essential of Micro and nanofluidics: with applications to biological and
Learning	chemical sciences". Cambridge University Press, 2012
Resources	2 Joshua Edel, "Nanofluidics" RCS publishing 2009

- 3. HenrikBruus, "Theoretical Microfluidics", Oxford Master Series inPhysics, 2007
- 4. PatricTabeling, "Introduction to Microfluids", Oxford U. Press, 2005

arning Assessm	lent		Continuous Learnin	g Assessment (CLA)		Ourse the s				
	Bloom's Level of Thinking	(1/ 1 Avorage of unit teet			Learning I-2 %)	Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	20%		20%	(-2	20%	-			
Level 2	Understand	20%		20%		20%	-			
Level 3	Apply	40%	Carlot Carlot Carlot	40%		40%	-			
Level 4	Analyze	20%	F 4 - 1 - 1 - 1 - 1 - 1 - 1 - 1 - 1 - 1 -	20%	. 1	20%	-			
Level 5	Evaluate		William Street by	20 1 W. 1		-	-			
Level 6	Create		Mary State State	The state of the s	- C	-	-			
	Total	10	00 %	100	%	10	0 %			

·		Wat N. 12.3			
Course Designers		47,-2-	All the second s		
Experts from Industry		Ex	cperts from Higher Technical Institutions	Internal Ex <mark>perts</mark>	
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2. Mr.K.Chandru Trivitron Healthca	are Pv <mark>t. Ltd. C</mark> hennai,char	dru.k@trivitron.com 2	2. Dr.Amit Kumar Mishra , IIT Jodhpur, amit@iitj.ac.in	2. Dr.V. <mark>Eswaraia</mark> h, SRMIST	

Course	21NTF520T Course	MEMS AND NEMS	Course _	DE	OCECCIONIAL ELECTIVE	L	Τ	Р	С	
Code	Name	INIEINIS AIND INEINIS	Category		ROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	rogressive Courses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR): The purpose of learning this course is to:	11	1			Progr	am Oı	itcome	s (PO	)					gram	
CLR-1:	learn what are MEMS And where they are useful	1	2	3	4	5	6	7	8	9	10	11	12		cific comes	
CLR-2:	understand the basics of fabrication of electromechanical systems at micro and nanoscale and modelii	ng g	)	of	SL		. "			Work		99				
CLR-3:	understand the principles of sensing and actuation in electromechanical systems	wlec		nent	ation	Usage	ъ					Finance	ng			
CLR-4:	explore magnetic materials for suitable for magnetic MEMS	Ā	Analysis	velopment	vestigations problems		r and	y k	l.	Team	tion	8 F	arni			
CLR-5:	gain knowledge of thermal, micro-opto-MEMS materials	ering		deve	ق∃ا₀	Tool	engineer sty	nment nability		<u>ھ</u>	Sommunication	Mgt.	g Le			
		<u>e</u>	ē	ign/	duct	dern	enc ety	iron taina	S	ndividual	nur	roject	Long	7 5	7 5	:
Course O	outcomes (CO): At the end of this course, learners will be able to:	Eng	Pog	Des	g G g	Moc	The	Envi Sus	Ethics	Indi	Con	Proj	Life	PSO-1	PSO-2 PSO-3	<u>.</u>
CO-1:	utilize mechanics principles to analyze the mechanical performance of microsystems	3	- 1	3	-	-	-7	-		-	-	-	-	3	-   -	
CO-2:	utilize optics, electrical and mechanical principles to analyze optoelectromechanical performance MOEMS	of 3	4	70 20		-	1	-	1	-	-	-	-	-	-   -	
CO-3:	use the radio frequency and thermal principles to analyze the performance of RF and thermal MEMS	3	3	<u> </u>	4-	-	_	-		-	-	-	-	-	-   -	
CO-4:	use magnetic and fluid princ <mark>iples to a</mark> nalyze the performance of magnetic MEMS and microfluidic devi	ces 3		1.4	2.5	-	-	-	-:	-	-	-	-	-		
CO-5:	analyze the tools and processes used in micromachining of MEMS	3	3	-1	· .	_	-	-		-	-	-	-	-	-   -	

## Unit-1 - MEMS and NEMS Systems

9 Hour

Micro and nano-electromechanical systems (MEMS and NEMS), Importance of MEMS in daily life, MEMS - Scaling Laws, Conventional electromechanical systems, Mathematical Modeling, Important steps for analysis and design of engineering steps, Microsensors and microactuators, Principle of sensing and actuation, capacitive sensors, pressure sensors, NEMS-Scaling Effect: Intrinsic losses: Phonon/phonon interaction, Electrical resistivity, depletion, the deactivation of dopants, Quantum confinement effect, Electron/phonon interactions, two-level, and surface effects, Extrinsic losses: Fluid interactions, Dissipation of mechanical energy in the

support, Near field effect in a nanostructure: Casimir force, Casimir force between two silicon slabs, Impact of the Casimir force in a nano-accelerometer, Optomechanical nano-oscillators, Quantum optomechanics

## Unit-2 - Nano Machining

9 Hour

Nano machining of NEMS based upon electron beam lithography, Nanoelectromechanical systems fabrication, Nanoimprint lithography, Polymeric nano fibre templates, Focused ion beam doping and wet chemical etching, Stencil lithography and sacrificial etching, Large scale integration and N-type doping in semiconductors, surface machining at macro and microscales. Wafer bonding and LIGA, MEMS Assembling and Packaging, Anodic bonding, fusion bonding, Lithography, electroforming, and molding. Basic Modeling elements in mechanical and electrical systems, Ampler element, mass/inertia element, capacitor, resistor, and inductor, Inertance, fluid resistance, fluid capacitor, Thermal systems modeling, Thermal capacitance, thermal resistance, Translational and rotational pure mechanical systems with spring, Damper and mass

## Unit-3 - Sensing and Actuation

9 Hour

Principles of sensing and actuation, Role of microsensors and microactuator with examples, components of mechanical MEMS, Beam, cantilever, microplates, Diaphragm structures theory, corrugated, diaphragms, components in sensors, Capacitive effects, piezoelement, piezomechanics, Measurement methods Strain measurement, pressure measurement, Flow measurement using an integrated paddle-cantilever structure, MEMS Gyroscopes, Nano-gyroscope device: CNT vibration-based, Shear mode MEMS, principle, Compensation in gyroscope, gripping piezo actuator, design and working principle, Inchworm technology, principle, Thermal sensors and actuators, Thermal energy basics and heat transfer processes, thermistors, thermocouple. Thermal actuators. Thermodevices, micromachine thermocouple probe, thermal flow sensors

Unit-4 - Magnetic Materials 9 Hour

Magnetic materials: properties, Magnetoresistive materials, magnetostrictive materials, hard magnetic materials, design considerations in magnetic materials, Magnetic sensing and design, Presence and direction detection of large object – an example, Magnetoresistive sensor, Principle of magnetoresistive sensor, hall effect, magnetortransitor, MEMS magnetic semsors and actuators, Construction of a MEMS magnetic sensor, the principle of operation, sensitivity of the sensor, Review of RF-based communication system-I, Tuners, resonators, switches, phase shifters, RF MEMS application area, advantages, Review of RF-based communication system-II, Varactors, Tuners Filters, Resonators, phase shifter, switches,

Unit-5 - MOEMS 9 Hour

Principles of MOEMS technology, Applications, Hybrid systems, application, advantages, MOEMS components, Light modulators, beam splitters, Microlens, micromirror, the digital micromirror device, MOEMS devices, Optical switch, waveguide and tuning, shear stress measurement, Lab-on-a-chip, Important considerations on microscale fluid, Properties of fluids, density, viscosity, nature of the flow, surface tension, Fluid actuation methods, Dielectrophoresis, electrowetting, Electrothermal flow, Thermocapillary effect, Electroosmosis flow, Optoelectrowetting, Micropumps: design consideration, Microneedle, Construction of a micropump, modeling, working principle

	arnina	1.	Mahalik N P, "MEMS", Tata McGraw-Hill Education, 2008.	4.	Sergey Edward Lyshevski, "Micro-Electro-Mechanical and Nano-Electromechanical Systems,
1_	arning	2.	Laurent Duraffourg and Julien Arcamone, "Nanoelectromechanical systems",		Fundamental of Nano-and Micro-Engineering", CRC Press, 2005
Ke	esources	3.	John Wiley & Sons, Inc., 2015.	5.	MEMS and NEMS Systems, Devices, and Structures, By Sergey Edward Lyshevski,2002 CRC Press

Learning Assessm	ent				4.5	1,44.21			
		CLA-1 Avera	Continuous L native ge of unit test 0%)	earning	CL	g Learning A-2 0%)	Final Ex	mative amination eightage)	
		Th	eory	Practice	127	Theory	Practice	Theory	Practice
Level 1	Remember	20	)%	17.	7.5	20%		20%	-
Level 2	Understand	20	0%	N 727	7	20%	-	20%	-
Level 3	Apply	41	0%	The same of the same		40%		40%	-
Level 4	Analyze	20	0%			20%	_	20%	-
Level 5	Evaluate				۱L.	ALL DON'T COMPANY	1.0		-
Level 6	Create		-	-	1777	-	- 4	-	-
	Total Total	PC4 1	100	0 %	1. 11	10	0 %	10	0 %

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Expe <mark>rts</mark>
1. Dr. Hemant Dixit, GlobalFoundaries, USA,	1. Prof. V. Subramaniam, IITM, Chennai, manianvs@iitm.ac.in	1. Dr. Ma <mark>ngalampa</mark> lli Kiran, SRMIST
aplahemant@gmail.com	/ IN FARA- / FAB TOUR	
2. Dr. Krishna SurendraMuvvala, Saint Gobain Research I	India, 2. Prof. M. Ghanashyam Krishna, UOHYD, mgksp@uohyd.ernet.in	2. D <mark>r. Ravikira</mark> na, SRMIST
India, Krishna.muvvala@saintgobain.com	V Links	

Course	24NTE524T	Course	2-D LAVERED MATERIALS	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С
Code	ZINIESZII	Name	2-D LATERED WATERIALS	Category		PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

THE RESERVE

Course Lo	earning Rationale (CLR): The purpose of learning this course is to:	11	4			Progr	<mark>am</mark> Ou	tcome	s (PO	)					rogram	٦
CLR-1:	understanding the electronic properties of 2D materials, especially Graphene	1	2	3	4	5	6	7	8	9	10	11	12	_	pecific itcomes	
CLR-2:	acquire knowledge on different synthesis methods	dge		o	SI	-	. "			Work		8				1
CLR-3:	describe the various properties of 2D-layered structure	Knowledge	w	Jent	ation	Usage	ъ	. '		am W		Finan	рu			
CLR-4:			Analysis	velopment	estigations problems		r and	∞ ~ >	N.	Teal	ion	∞ర	arni			
CLR-5:	illustrate the application of layered Nanomaterials	ering	Ang	deve	i ×	T00	engineer sty	ment ability		<u>8</u>	nicat	Mgt.	g Le			
Course O	Durse Outcomes (CO):  At the end of this course, learners will be able to:		Problem	Design/ solution	Conduct i	Modern	The eng society	Environ S <mark>ustain</mark>	Ethics	Individual	Communication	Project	Life Lon	PS0-1	PSO-2 PSO-3	
CO-1:	interpret the atomic and ele <mark>ctronic structure to understand the physical and chemical properties of graphene</mark>	3	16	2	-	-	7	-		-	-	-	-	2		
CO-2:	identify the procedure to synthesize layered materials and the concept of Raman spectra over synthesized materials	1 × x	i di	3	2	-	3	-		-	-	-	-	-	2 -	
CO-3:			2		-	_	-	-		-	-	-	-	2		
CO-4:	<b>2-4:</b> apply the concept and the uses of semiconducting and metal dichalcogenides based materials		4	1 -	3	_		-	-	-	-	-	-	-	2 -	
CO-5:			2	-	-	-	-	-	-	-	-	-	-	-	2 -	

## Unit-1 - Introduction of 2D Layered Nanomaterials

9 Hour

Introduction of different types of 2D materials beyond graphene. Dimension of carbon allotrope, electronic band structure, Force between the layer-Vander Waals- covalent bond, Crystal plane of 2D graphene, Manipulation of quantum degree of freedom, Fermi level graphene- role of doping and defect, 2D Metal Carbides, 2D material classification, 2D transition metal dichalcogenidesphos-phorene -Black phosphors- Mexene.

## Unit-2 - Preparation Techniques

9 Hour

Introduction of scotch-tape method- graphene preparation, Thermal growth of graphene- Epitaxial growth of graphene, Chemical vapor deposition (CVD), plasma enhanced CVD, combustion method, Recent advanced in free standing films-Vacuum Filtration Method, Direct Evaporation Method-CVD, mechanical exfoliation- preparation of graphene using liquid phase- exfoliation, sonication exfoliation- Intercalation exfoliation, Liquidexfoliation. Principles of Raman spectroscopy- Limitations, Raman spectrum of graphene, D band G band Raman spectra.

#### Unit-3 - Characterization of 2D Materials

9 Hour

Introduction to X-ray photoemissionspectroscopy-limitation, Introduction to X-ray-diffraction-limitation, Introduction to Optical absorption spectroscopy-limitation, Introduction and limitations of Scanning Tunnelling Microscopy, Introduction and limitations to BET analysis, Introduction and limitations to VSM analysis, ferroelectricity-Anisotropy-magnetic and catalytic properties, types interaction metal-graphene interaction, Metal – non-metal supported graphene and properties.

## Unit-4 - 2D Materials and Properties

9 Hour

Graphene and its properties, 2D materials-phase transformation, Penta-graphene and its properties, h-BN structure, synthesis, Application of h-BN and properties SiC structure, synthesis and synthesis and synthesis and synthesis and synthesis and synthesis and synthesis and synthesis an

## Unit-5 - 2D Materials and Applications

9 Hour

Introduction to SPR sensor, SPR sensing mechanism and types of sensors SPR sensor and its principles, uses smart energochromic sunscreen devices. 2D materials based thermoelectric, Application of membrane, Uses of 2D materials in hydrogen storage, Optoelectronic devices, Super capacitor, TMD —Photodetector, Piezoelectricity of 2D materials, Types of nanogenerator, 2D materials nanogenerator applications

## Learning Resources

- Houssa, Michel, Athanasios Dimoulas, and Alessandro Molle, "2D Materials for Nano- electronics" - CRC Press, 2016.
   Banks, Craig E., and Dale AC Brownson, eds. "2D Materials: Characterization, Pro-
- duction and Applications"- CRC Press, 2018.
  3. Inamuddin, RajenderBoddula, Mohdimran Layered 2D Materials and Their Allied Applications Willey-2020
- 4. Tiwari, Ashutosh, and Mikael Syväjärvi, eds. "Advanced 2D Materials" -John Wiley & Sons, 2016
- 5. Dragoman, Mircea, and DanielaDragoman,"2DNanoelectronics: PhysicsandDevicesof Atomically Thin Materials"- Springer, 2017.
- 6. Spyridon Zafeiratos 2D Nanomaterials for Energy application- Springer, 2020
- 7. Graphene and Other 2 D materials based thin films Federico Cesano, Domenica Scarano-Coat- ings, 2019.

earning Assessm	nent		Continuous Learning	g Assessment (CLA)	<del>-</del>				
	Bloom's Level of Thi <mark>nking</mark>	CLA-1 Avera	native ge of unit test 19%)	Life-Long CL		Summative Final Examination (40% weightage)			
		Theory	Practice	Theory	Practice	Theory	Practice		
Level 1	Remember	20%	ta Tarachi ta Mariana	20%		20%	-		
Level 2	Understand	20%	A 18 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	20%		20%	-		
Level 3	Apply	40%	100 may 100 mg	40%		40%	-		
Level 4	Analyze	20%	W	20%	- C	20%	-		
Level 5	Evaluate	22 2 77 3 1	TE 17 19 19 19 19 19 19 19 19 19 19 19 19 19	""中国为"特别"。		0 -	-		
Level 6	Create		5 7 1 1 1 1 L	1 July 2017	3 - J	-	-		
	Total	100	0%	100	) %	100	0 %		

Course Designers	2000		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts	
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2. Dr. Krishna Surendra Muvvala, Saint Gobain Research	2. Dr. S. Balakumar. University of Madras, Madras,	2. Dr. S. Hari <mark>sh, SRMI</mark> ST	·
India, India, Krishna.muvvala@saintgobain <mark>.com</mark>	balakumar@iunom.ac.in		

Course	24NTE522T	Course	FUNCTIONAL MATERIALS	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С	
Code	21NTE522T	Name	FUNCTIONAL MATERIALS	Category		PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	NII	ogressive Courses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course Le	earning Rationale (CLR): The purpose of learning this course is to:	W	4	-		Progr	<mark>am O</mark> u	tcome	s (PO	)					ram o:fio
CLR-1:	understand the concepts of different types of materials	1	2	3	4	5	6	7	8	9	10	11	12		cific omes
CLR-2:	create insights to the concepts of magneto-caloric effect, colossal magneto resistance and spintronic materials	6	١.	4	2.		V.	oility							
CLR-3:	introduces multiferroic materials and applications in electrocaloric devices and ferroelectric random access memory	Knowledge		gn/development of	ions of	<u> </u>	society	Sustainability	N.	Work		Finance	_		
CLR-4:	provide the knowledge on functional superconducting materials	S S	Analysis	bme	tigal	Jsag	and			Team	_		arning		
CLR-5:	comprehend the concents of ontical properties in materials, Introduces non-linear ontical and photo				duct investigations plex problems	n Tool Usage	engineer a	Environment &		•Ճ	Communication	t Mgt. &	Le		
Course O	utcomes (CO):  At the end of this course, learners will be able to:	_ Engin	Problem	Design		Modern	The el	Enviro	Ethics	Individual	Сотп	Project I	Life Long	PSO-1	PSO-3
CO-1:	identify the magnetic, ferroelectric, superconducting and optical materials	3	1	2	3	-	1	-		-	-	-	-	2	-   -
CO-2:	identify the MCE materials in Magnetic Refrigeration, and CMR materials	1	17.74	3	2	-	-	-		-	-	-	-	-	2 -
CO-3:	analyse the various types of multiferroic Materials for applications in electrocaloric and FeRAM device	3	2		4	_	-	-		-	-	-	-	2	
CO-4:	apply the background of superconducting phenomena in materials to the development of high Tc other emergingsuperconducting materials				3	-	0	1	4	-	-	-	1	-	2 -
CO-5:	utilize the Knowledge on optical properties of materials to explore Non-linear and Photonic Band-g. Materials	3	2	-	-	- 1		-/		-	-	-	-	-	2 -

Unit-1 - Introduction on Materials 9 Hour

Introduction on Materials, Crystalline and Amorphous Materials, Discussion on Non-magnetic and Magnetic materials, Dia-, Para, Antiferro, Ferri-, Ferro-, Superparamagnetism, Ferroelectric, and Multiferroic Materials, Superconductor, Types of Superconductors, Optical Materials, and Definition of functional materials, introduction to meta-materials.

## Unit-2 - Functional Magnetic Materials

9 Hour

Functional Magnetic Materials: Magnetocaloric Effect, Fundamentals of magnetic cooling and heating, Magnetic Transition and Magneto caloric effect, Relative cooling power, Magnetocaloric Materials, Challenges in MCE materials in Magnetic Refrigeration, Magnetic Nanoparticles, Spintronics Materials, Nanoparticles for High Density Magnetic recording, colossal magneto resistance (CMR) Materials, Magnetic Random-Access Memory (MRAM)

Unit-3 - Multiferroic Materials 9 Hour

Multiferroic Materials: Origin of Ferroelectricity, Mutual Exclusive Reason for Multiferroicity, Types of Multiferroic Materials, Observation of Multiferroic Properties, Examples of Multiferroic Materials: Perovskite type, Composites of Perovskites, Bismuth-based Perovskites, Applications: Electrocaloric Devices, Ferroelectric Random-Access Memory (FeRAM), Dynamic Random-Access Memory (DRAM)

## Unit-4 - Superconducting Materials

9 Hour

Functional Superconducting Materials: Background of superconducting Materials, Niobium Titanium (NbTi), A 15 Superconductors and Niobium-tin (Nb3Sn), Chevrel-Phase Superconductors, High-Tc Superconductors, MgB2, Borocarbides, and Iron Arsenide Superconductors

Unit-5 - Optical Materials 9 Hour

Functional Optical Materials: Introduction to optical Materials, Origin of different types optical materials, Optical Parameters, Optical properties of metal, insulator and nanomaterials, Non-linear Optical Materials, Examples of non-linear optical process, Glasses as non-linear optical materials, Photonic Band-gap materials

Learning
D
Resources

- 1. S. Banerjee, and A.K. Tyagi, Functional Materials: Preparation, Processing and Applications, Publisher-Elsevier (2011).
- Hasse Fredriksson and Ulla Akerlind, Physics of Functional Materials, Publisher-Wiley-Black- well (2008).
- 3. N. Spaldin, Magnetic Materials: Fundamentals and Applications, (CUP, 2012, 2nd Ed).
- 4. Junling Wang, Multiferroic Materials: Properties, Techniques, and Applications: Publisher- CRC Press (2016).
- 5. Kelly S. Potter and Joseph Habib Simmons, Optical Materials, Publisher-Elsevier 2nd Edition (2021).
- 6. C. Kittel, Introduction to Solid State Physics, 8th Ed., J. Wiley and Sons, 2005.

Learning Assessm	nent									
	Bloom's Level of Thin <mark>king</mark>	CLA-1 Avera	Continuous Learnin native ge of unit test %)	g Assessment (CLA) Life-Long CLA (10	4-2	Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	20%	2. 74. 92.25.	20%		20%	-			
Level 2	Understand	20%	Carlot Mary no	20%		20%	-			
Level 3	Apply	40%	and the second second	40%		40%	-			
Level 4	Analyze	20%	William Comment to 1886	20%		20%	-			
Level 5	Evaluate	S 100 100 100 100 100 100 100 100 100 10	Mary Mary Mary	7 M 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	- C	-	-			
Level 6	Create			"一根"在"图"和新考别。		-	-			
	T <mark>otal ====================================</mark>	100	) %	100	) %	10	0 %			

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Krishna Surendra Muvvala Saint-Gobain Glass Pvt.Ltd.	1. Prof. Prahallad Padhan, IIT Madras, Chennai, Email:	1. Dr. Bhaskar C <mark>han</mark> dra Behera, SRMIST
	padhan@iitm.ac.in	
2. Dr. S. Sudhakar, CSIR-CECRI, sudhakar@cecri.res.in	2. Prof. S. Balakumar, University of Madras, balakumar@iunom.acs.in	2. Dr. Trilocha <mark>n Sahoo,</mark> SRMIST

Course	21NTE522T Course	MATERIAL CLINDER EVERENE TEMPERATURE	Course	_	PROFESSIONAL ELECTIVE	L	Τ	Р	С	
Code	Name	MATERIALS UNDER EXTREME TEMPERATURE	Category	_	PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offer	ing Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR): The purpose of learning this course is to:	Program Outcomes (PO)												Program	
CLR-1:	acquire the concepts of High Temperature Materials	1	2	3	4	5	6	7	8	9	10	11	12		pecific tcomes
CLR-2:	LR-2: gain the knowledge about mechanical properties of materials				SL	-	. "			Work		9			
CLR-3:	LR-3: understand the various fracture and diffusion mechanism				stigations roblems	Usage	ъ			Team W		Finan	р		
CLR-4:	LR-4: gain the knowledge on the process of oxidation and corrosion				estig		r and	ج ج ک	h.		ion	≪ ⊡	arni		
CLR-5:	describe the various mechanisms involved in High -Temperature materials	ering	Problem Analysis	/development of	duct invi		engineer sty	ment ability		Jal &	unica	Mgt.	ng Le		
Course C	Course Outcomes (CO):  At the end of this course, learners will be able to:				Conduct of comp	Modern	The en society	Enviro Sust <mark>ail</mark>	Ethics	Individual	Communication	Project	Life Lor	PS0-1	PSO-2 PSO-3
CO-1:	express the properties and fu <mark>nctions of High-Temperature materials</mark>	2			3	-	/	-		-	-	-	-	2	
CO-2:	O-2: express the mechanical properties of materials				7-19	-	4	-	-1	-	-	-	-	-	2 -
CO-3:	0-3: evaluate the fracture in diffe <mark>rent mat</mark> erials				3	-	-	-		-	-	-	-	2	
CO-4:	<b>0-4:</b> analyze the oxidation and corrosion property				-	_	-	ul -		-	-	-	-	-	2 -
CO-5:	apply the High-Temperature in different materials for engineering applications by knowing its mechanism	s 2	3		7-	_		-		-	-	-	-	-	2 -

## Unit-1 - Components at Elevated Temperatures

9 Hour

Factors influencing functional life of components at elevated temperatures, Requirements of High Temperature Materials, High-Temperature Materials, Chemistry and Thermodynamics, High Temperature Materials Processing, Characterization of High-Temperature Materials

## Unit-2 - Creep Curve

9 Hour

Definition of creep curve, various stages of creep, Metallurgical factors influencing various stages, Effect of stress, temperature and strain rate, Design of transient creep, time hardening, strain hardening, Expressions for rupture life for creep, ductile and brittle materials - Monkman - Grant relationship

## Unit-3 - Fracture

9 Hour

Various types of fracture, Brittle to ductile from low temperature to high temperature, Cleavage, ductile fracture due to microvoid coalescence, Diffusion controlled void growth, Fracture maps for different alloys and oxides

#### Unit-4 - Oxidation Etc

9 Hour

Oxidation, Pilling-Bedworth ratio, Kinetic laws of oxidation, Defect structure and control of oxidation by alloy additions, sulphation, Hot gas corrosion deposit, modified hot gas corrosion, effect of alloying elements on hot corrosion

## Unit-5 - High-Temperature Materials and Mechanisms

High-Temperature Materials and Mechanisms: Applications and Challenges - Iron base, nickel base and cobalt base superalloys, composition control, solid solution strengthening, precipitation hardening by gamma prime - grain boundary strengthening, TCP phase, embrittlement - solidifi cation of single crystals, Intermetallic Materials, High-Temperature Ceramics, Glasses and Glass Ceramics, coatings and composites

Learning Resources	2.	Raj R, 'Flow and Fracture at Elevated Temperatures', American Society for Metals, 1985 Materials for High Temperature Engineering Applications, Geoffrey W. Meetham, Marcel H. Van de voorde, Springer, 2000	5	<ol> <li>Materials Under Extreme Conditions, A.K. Tyagi and S. Banerjee, Elsevier, 2017</li> <li>High Temperature Materials and Mechanisms, Yoseph Bar-Cohen, CRC press, 1st edition, 2017</li> </ol>
'			D) [	

Learning Assessm	nent		-							
	S	Form	Continuous Learning		Summative					
	Bloom's Level of Thinking	CLA-1 Avera	ge of unit test 0%)	CL	g Learning .A-2 0%)	Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice Practice	Theory	Practice			
Level 1	Remember	15%	-	15%		15%	-			
Level 2	Understand	25%	- A - A	20%	2 - 1	25%	-			
Level 3	Apply	30%	A CONTRACTOR	25%	4	30%	-			
Level 4	Analyze	30%	47.7	25%	400	30%	-			
Level 5	Evaluate	/~ ·	A Section 278	10%	1	-	-			
Level 6	Create			5%	L - L	-	-			
	Tota <mark>l</mark>	100	0%	10	0 %	100	0 %			

Course Designers	[1] [1] [1] [1] [1] [1] [1] [1] [1] [1]	3 7.
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. N. V. Chandra Shekar, IGCAR, Kalpakkam, chandru@igcar.gov.in	1. Dr. Balan Palanivel, Pondicherry Engineering College,	1. Dr. V. Kathirvel, SRMIST
	Pondicherry, bpvel@pec.edu	
2. Dr. V. Pandiyarasan, Indian Institute of Information Technology, Design,	2. Dr. G. Kalpana, Anna University, Chennai,	2. Dr. Kiran, SRMI <mark>ST</mark>
and Manufacturing (IIITDM) Kancheepuram, pandiyarasan@iiitdm.ac.in	g_kalpa@yahoo.com,	

Course Code	21NTE524T	Course Name	MICRO AND NANO	PROCESSING OF MATERIALS	_	Category E PROFESSIONAL ELECTIVE									3	- T	P 0	3			
Pre-requi		Nil	Co- requisite Courses	Nil	****	Progressive Nil															
Course (	Offering Departme	ent /	Physics and Nanotechnolog	Data Book / Codes / S	tandards								Nil								
Course Le	arning Rationale	(CLR): The	purpose of lea <mark>rning this c</mark>	course is to:	<del>(fi</del> i		-			Progr	am Ou	itcome	s (PO	)				Pi	rograr		
CLR-1:						1	2	3	Program Outcomes (PO)           3         4         5         6         7         8         9         10         11								12	S	Specific Outcomes		
CLR-2:	understand the conventional processes							<b>4</b>	S					¥		Ф		00	tcom	53	
CLR-3:	gain knowledge about non-conventio <mark>nal proces</mark> ses							ent	ation	ge	r and	ళ /		n Work	ion	Project Mgt. & Finance	g				
CLR-4:	learn Micro and nano finishing processes						alysis	lopm	stig	Usa				Team \			Learning				
CLR-5:	learn micro joining processes		19.7	Engineering Knowledge	Ans	Problem Analysis	Ans	Ang ا	gn/development of tions	Conduct investigations of complex problems	Modern Tool Usage	The engineer society	Environment 8 Sustainability		∞	Communication	Mgt.	lg Le			
						inee	blem	sign/ rtion	omp	dern	The eng society	viron	S	ndividual	l mu	ject	Long	PSO-1	PS0-2	PSO-3	
Course Outcomes (CO): At the end of this course, learners will be able to:				1 43	ο Eu	Pro	Desi solut	Sor of o	Moc	The	Sus	Ethics	lndi	Š	Pro	Life	PS(	PS(	PS(		
CO-1:	acquire the basics of various machining processe				1.11	3	- 1		-	-	-7	-		-	-	-	-	-	-	-	
CO-2:	gain knowledge	on conventi <mark>onal</mark>	<mark>proc</mark> ess of micro and nano	machining	Barry.	3	<u> </u>	45	3	2	4	-	-	-	-	-	-	3	-	-	
CO-3:	obtain the knowle	edge on no <mark>n-col</mark>	<mark>nve</mark> ntional processes using	lasers		3	$q_{jk}$		3	-	-	-		-	-	-	-	-	-	-	
CO-4:	acquire knowledg	ge on micro <mark> an</mark> d	<mark>na</mark> no finishing processesn	민준이가 되는 것이	4	3	127	Ger.	3	2	-	- 1		-	-	-	-	-	-	-	
CO-5:	gain knowledge	on micro joi <mark>ning</mark>	<mark>pro</mark> cessing using various w	relding techniques	"E 5	3		3	3	2		-		-	-	-	-	-	2	-	
Unit 4 Di	amand Taskusla				1	25	.1				_									11	
	amond Technolog		Modified HECVD proces	s, Nucleation and diamond growth, D	)enosition	on cor	mnles	v suhst	rates	Diamo	nd mic	romach	ninina						91	Hour	
	cro-Procesing	ation or substitute	o, Modifica III OVD process	s, reacication and diamona growth, b	Poposition	011 001	Πρισχ	· oubou	aics, i	Jiamo	na mio	omacı	ming.						9 /	Hour	
		licro-drilling, Mic	<mark>ro-milli</mark> ng, Product quality i	n micromachining Micro-grinding and	d Ultra-pred	cision	Proc	esses,	Micro	and na	anogrin	din <mark>g, N</mark>	l <mark>anog</mark> r	rinding	tools.						
	aser Fabrication									7		/ 6								Hour	
Introduction technologie		f lasers, Laser r	nic <mark>rofabric</mark> ation, Laser nand	ofabrication.Evaluation of Subsurface	e Damage	in Nai	no an	nd Micr	omach	ining,L	Destruc	tive ev	<mark>alu</mark> atio	on tech	nologie	es, Nor	n-destr	uctive	evalu	ation	
Unit-4 - Fir				The PARN - F	4 A D			1 1 7	₹1.	7									9	Hour	
		netic abrasive F	inishing, <mark>Magnetor</mark> heologid	al Finish, Elastic Emission Finishing,	, Magnetic	Float	Polis	hing, l	on Bea	m finis	shing.										
Unit-5 - We							-7-8-		الست	7	. "	P.							9 /	Hour	
Challenges	s, Micro Resistance	e welding, Ultras	onic welding, <mark>Micro TIG, A</mark>	oplications.																	

J. Paulo Davim, Mark J. JacksonNano and Micromachining, John Wiley & Sons, 2013
 V.K.Jain, Micro-manufacturing Processes, CRC Press, 2012.

Learning Resources

Yi Qin, Micro-manufacturing Engineering and Technology, William Andrew, 2015
 Kapil Gupta, Micro and Precision Manufacturing, Springer, 2017

			Continuous Learning	Summative					
	Bloom's Level of Thinking	CLA-1 A <mark>vera</mark>	native ge of unit test %)	CL	g Learning A-2 <mark>0%)</mark>	Final Ex	mative amination eightage)		
		Theory	Practice	Theory	Practice	Theory	Practice		
Level 1	Remember	15%	ATTEN.	15%		15%	-		
Level 2	Understand	25%		20%		25%	-		
Level 3	Apply	30%	3	25%		30%	-		
Level 4	Analyze	30%	-	25%		30%	-		
Level 5	Evaluate		-	10%	7	-	-		
Level 6	Create		*-A A	5%	2	<u>-</u>	-		
	Total	100	) %	10	0%	100 %			

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Avik Chatterjee, Chief Scientist, Centre for Advanced Manufacturing and	1. Dr. M. S. Shunmugam, Professor, Department of	1. Dr. C. Gopala <mark>krishnan,</mark> SRMIST
Metrology Group Advanced Design and Analysis Group- CSIR-CMERI	Mechanical Engineering, IIT Madras	
2. Dr. Soumen Mandal, Senior Scientist, Central Mechanical Engineering	2. Dr. Jose Mathew, Professor, Department of	2. Dr. Geethapriyan, SRMIST
Research Institute, Durgapur, WB	Mechanical Engineering, NIT Calicut	

Course	21NTE525T	Course	SMART ENGINEERING MATERIALS	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С	
Code	21NTE525T	Name	SMART ENGINEERING MATERIALS	Category		PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	N	Co- requisite Courses	Nil F	rogressive Courses	Nil	
Course Offerin	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil	
			THE PARTY OF THE P			

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	11	4			Progr	am Ou	ıtcome	s (PO	)					ogran	
CLR-1:	understand the physics of	piezoelectricity	1	2	3	4	5	6	7	8	9	10	11	12		ecific	
CLR-2:	agp		Jo	SI	7	. "			Work		8						
CLR-3:	CLR-2: familiarize with the concept of magnetostatic and spintronics  CLR-3: acquire the knowledge of different types of shape memory				Jent	atior	Usage	Ъ	. 1				Finance	БC			
CLR-4:	understand the theory of n	netamate <mark>rials</mark>	Knowlec	Analysis	udoli	vestigations problems		r and	ج ج ک	1	Team	ţį	⊗ F	arning			
CLR-5:	CLR-5: acquire knowledge on the materials and working of nano-gels				gn/development of ions	.⊑ ⊙	Modern Tool	engineer sty	Environment Sustainability	١, ١	<u>8</u>	Communication	Mgt.	g Le			
	·		ineering	Problem	ign/d tions	onduct f comple	Jern		iron	S	Individual	nuu	Project	Life Long	7	7-5	~
Course O	outcomes (CO):	At the end of this course, learners will be able to:	Engi	Prol	Des	Con of o	Мос	The	Env S <mark>us</mark>	Ethics	Indi	Con	Proj	Life	PS0-1	PSO-2	PSO-3
CO-1:	acquire knowledge of phys	sics of Piezoelectric Materials and Pieoresistivity Sensors	3	- 5		2	-	-7	-		-	-	-	-	4	-	-
CO-2:	develop in depth under Magnetoresistive	sta <mark>nding o</mark> n the Nanomagnetic Behavior and Role of Electron Spin in	2	ł.	10 27	3	-	4	-	1	-	-	-	-	-	-	-
CO-3:	apply Shape Memory for N	M <mark>anufactu</mark> ring of Shape Memory Smart Materials	3	2	45-	7	-	-			-	-	-	-	-	-	-
CO-4:	4: employ the knowledge of additive manufacturing for various applications			-		3	-	-	-	-	-	-	-	-	-	-	-
CO-5:	implement the concepts of Nanogel in real time applications				- 7	3	_		-	- #	-	-	-	-	-	-	-

Unit-1 - Piezoelectric Materials

Piezoelectric Materials, Principles of Piezoelectricity, Desired Properties of Piezoelectric Materials, Elastic Properties of Crystals, The Strained Body, Thermodynamics of Mechanical Deformation, Piezoelectric Ceramic Actuators, Energy harvesters and Sensors, Piezoresistivity Effect, Piezoresistive Strain/Stress Sensor configuration, Piezoresistive Strain Sensor, Physical Causes of Piezoresistivity, Merit of Pieoresistivity Sensors vs. Capacitive Sensors, Piezoresistivity Components

Unit-2 - Magnetostrictive Effects 9 Hour

Various Magnetostrictive Effects, Origin of Nanomagnetic Behavior, Magnetic Domains, Exchange Interaction, Magnetostatic Energy, Domain wall, Terfenol-D Availability, Properties of Terfenol-D, Gaint Magnetostrictive Materials (GMSs), Ordinary Magnetoresistance (OMR), Giant Magnetoresistive (GMR), Spintronics and GMR Effect, Spin Dependent Transport, Spin Dependent Resistivity, Applications of GMR, Role of Electron Spin in GMR, GMR in Granular Structures, GMRs as Smart Sensors, Hard Disk Drives

Unit-3 - Shape Memory Effect 9 Hour

Shape Memory Effect (SME), Shape Memory Alloys (SMAs), Properties of SMAs, Thermodynamics of martensitic transformation, Stress-Strain-Temperature dependence of SMAs, SME Variations, One-way SME (OWSME), Two-way SME (TWSME), Constitutive Equations for SMAs, Tanaka Model, The Liang and Roger Model, The Brinson Model, Cardiovascular Superelastic Stents, Medical Applications, Magnetic Shape Memory Smart Materials (MSMA), MSMA Actuators. Typical MSMA materials, MSM Mechanism, Manufacturing of MAMAs

### Unit-4 - Mechanochromic Materials

9 Hour

Mechanochromic Materials, Example of Mechanochromic Materials, Mechanochromic devices Based on Marine Biological Systems, Mechanical Metamaterials, Mechanical Metamaterials with Negative Parameters, Background of Metamaterials, Classification of Metamaterials, Reconfigurable and Tunable Metadevices, Electromagnetic Metamaterials, Elastic Metamaterials, Acoustic Metamaterials, Structural Metamaterials, Nonlinear Metamaterials, Super lens

### Unit-5 - Polymer-Based Micro/Nano Gels

9 Hour

Polymer-based Micro/Nano Gels, Synthesis of Micro/Nano Gels, Transformation from Hydrogels to Nanogels for Imaging, Characterization of Nano Gels, Polymeric Building Blocks for Designing Nanogels, Nanocomposite Hydrogels, Polymer Nanofiller Composites, Biomedical Applications, Self-healing Materials, Self-healing Cementitious and Concrete Materials, Self-healing Polymers

# Learning Resources

- Jan Tichý, Jirí Erhart, Erwin Kittinger, Jana Prívratská, Fundamentals of Piezoelectric Sensorics, Mechanical, Dielectric, and Thermodynamical Properties of Piezoelectric Materials, Publisher:Springer Berlin Heidelberg, 2010
- 2. Alberto P. Guimarães, Principles of Nanomagnetism, Springer International Publishing, 2017
- K Yamauchi, I Ohkata, K. Tsuchiya, S Miyazaki, Shape Memory and Superelastic Alloys Applications and Technologies, Elsevier Science, 1st ed., 2011
- Leonardo Lecce and Antonio Concilio, Shape Memory Alloy Engineering for Aerospace, Structural and Biomedical Applications, Elsevier Science, 2014
- Xingcun Colin Tong, Functional Metamaterials and Metadevices, Springer International Publishing, 2017
- Arti Vashist, Ajeet K Kaushik, Sharif Ahmad, Madhavan Nair, Nanogels for Biomedical Applications (Smart Materials Series) 1st Ed., Royal Society of Chemistry, 2017

arning Assessm	nent	- N	Continuous Learnin	g Assessment (CLA)					
Bloom's Level of T <mark>hinking</mark>		CLA-1 Av	ormative erage of unit test (50%)	Life-Long CL		Summative Final Examination (40% weightage)			
		Theory	Practice	Theory	Practice	Theory	Practice		
Level 1	Remember	15%	All the second	15%	77 - 48 - 45-7	15%	-		
Level 2	Understand	25%	전투하다 당시 하다	20%	- (	25%	-		
Level 3	Apply	30%	1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	25%	- Table - Tabl	30%	-		
Level 4	Analyze	30%	64 1 1 1 2 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	25%	ST -	30%	-		
Level 5	Evaluate	147, -2	and the same of the same of	10%		-	-		
Level 6	Create			5%		-	-		
	Total		100 %	100	) %	100	0 %		

Course Designers	1.7	
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. D.K. Aswal, National Physical Laboratory,	1. Prof. M.S. Ramachandra Rao, IITM Chennai,	1. Dr. Debab <mark>rata Sark</mark> ar, SRMIST
dkaswal@nplindia.org	msrrao@iitm.ac.in	
2. Dr. S. Sudhakar, CSIR-CECRI, sudhakar@cecri.res.in	2. Prof. S. Balakumar, University of Madras, balakumar@iunom.acs.in	2. Dr. Ra <mark>vikirana, S</mark> RMIST

Course	21NTF526P Course	NANO FABRICATION	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С	
Code	Name	NANO FABRICATION	Category		PROFESSIONAL ELECTIVE	2	1	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR):	The purpose of learning this course is to:	Program Outcomes (PO)					gram										
CLR-1:	introduce what is lithogra	aphy and types of <mark>lithography t</mark> ools	1		2	3	4	5	6	7	8	9	10	11	12		ecific comes	;
CLR-2:	ELR-2: explain the need for etching in lithography process and its types					of	SI					Work		8				
CLR-3:					ω	Jent	vestigations problems	Usage	Ъ	. 1				Finance	gu			
CLR-4:	introduce various applica	ation area <mark>s where n</mark> anofabrication tools are utilized	Ā		Analysis	udoli	estig		r and	م <sup>۷</sup>	h.	Team	ion	∞ర	arni			
CLR-5:	LR-5: introduce what is lithography and types of lithography tools		ering			n/development	e ≓i	1 ΤοοΙ	engineer sty	ironment tainability		ual &	ommunication	Mgt.	Long Le			
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	Engine		Problem	Design solutio	Conduction of comp	Modern T	The er	Enviro S <mark>ustai</mark>	Ethics	Individual	Comm	Project	Life Lo	PS0-1	PSO-2	PSO-3
CO-1:	understand the difference	re be <mark>tween bo</mark> ttom up and top down nanofacrication and various tools requi	red 3	-	2			-	7	-		-	-	-	-	3	-	-
CO-2:	gain knowledge on lithog	grap <mark>hy types</mark> and process	3		2	4.50	7-19	-	4	-	-1	-	-	-	-	2	-	-
CO-3:	understand the need for	etching processes during lithography fabrication process	3	gi.	2		43	-	_	-		-	-	-	-	-	3	-
CO-4:	-4: acquire knowledge on different types of replication processes in nanofabrication		3		4	25.1	-	-	-	-	-	-	-	-	-	2	-	-
CO-5:	understand the utilization of lithography process in difference application areas		3	-	4	2		_		_		-	-	-	-	-	2	-

Unit-1- Fabrication 9 Hour

Concept of Top Down and Bottom-Up Fabrication approach, Self-assembly, Bio-mediated assembly, template assisted synthesis, epitaxial growth, growth mechanism and kinetics, Substrates, cleaning, Advanced cleaning techniques, native films growth, chemical vapor deposition, atomic layer deposition, physical vapor deposition, metallization.

Unit-2 - Photoresists

Photoresists, Resist process, Optical lithography, Mask making, UV imprint lithography, Electron beam lithography (EBL), Xray lithography, focused ion beam (FIB) lithography

Unit-3 - Etching

Wet etching: basics and techniques, dry etching: mechanism, chemistry, Plasma etching, Chemical Mechanical Polishing

Unit-4 - Replication

Replication tools, PDMS casting, hot embossing, micro injection molding, nano imprint lithography, introduction to inspection

Unit-5 - Applications

Nanofabrication in semiconductor industry: Metal Oxide Semiconductor (MOS) transistor, Complementary Metal Oxide Semiconductor (CMOS) transistor, Nanofluidic devices: basics, Nano electro mechanical

devices: basics

# Learning Resources

- 1. Hans H. Gatzen, Volker Saile, Jürg Leuthold, "Micro and Nano Fabrication", Springer 2015
- 2. Stefan Landis, "Lithography and nanolithography", Published by Wiley ISTE, 2010
- 3. Nano Lithography, Stefan Landis (Editor), Wiley, 2011
- 4. Nanofabrication: Techniques and Principles, Stepanova, Maria, Dew, Steven (Eds.), Springer, 2012
- 5. Fundamentals of Nanoscale Film Analysis edited by Terry L Alford, Leonard C. Feldman and James W. Mayer (Springer 2007)
- 6. Nanofabrication: Nanolithography technique and their applications edited by Jose Maria De Teresa (IOP 2020)

9 Hour

9 Hour

9 Hour

9 Hour

Learning Assessm	ent								
			Co						
	Bloom's Level of Thinking	CLA-1 Avera	native ge of <mark>unit test</mark> 0%)	CL	ed Learning A-2 0%)		d Viva Voce 0%)		amination eightage)
		Theory	Practice	Theory	Practice	Theory	Practice	Theory	Practice
Level 1	Remember	15%		THE REAL PROPERTY.	15%		15%	-	-
Level 2	Understand	25%	J- C1	11.1	20%	-	25%	-	-
Level 3	Apply	30%	_ ( J	-	25%	1 2-	30%	-	-
Level 4	Analyze	30%			40%	VVX	30%	-	-
Level 5	Evaluate		W	-	-	4-1		-	-
Level 6	Create	-400	- ,	- V - + A	-			-	-
	Total	100	0 %	100	0 %	10	00%		

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Krishna Surendra Muvvala, Saint Gobain Research	1. Prof. S. Balakumar, Madras University,	1. Dr. P. Malar, SRMIST
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2. Dr.S.V.Pandurangaiah, Raith India P <mark>vt Ltd,</mark>	2. Dr. K. Suresh Babu, Central University,	2. Dr. Abhay A Sa <mark>gade, S</mark> RMIST
pandurangaiah.sv@simcogroup.in	sureshbabu.nst@pondiuni.edu.in	

Course	24NTE527T	Course	BIOCOMPOSITES	Course	Е	DDOEESSIONAL ELECTIVE	L	Т	Р	С
Code	21N1E52/1	Name	BIOCOMPOSITES	Category		PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisite Courses	Nil	Co- requisite Courses	Nil	gressive ourses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	earning Rationale (CLR): The purpose of learning thi	s course is to:	H	4			Progr	am Oı	ıtcome	s (PO	)					rogram	
CLR-1:	learn the different classes of biomaterials used in medicin	е	1 -	2	3	4	5	6	7	8	9	10	11	12	_	pecific itcomes	
CLR-2:	understanding of the concept of biocompatibility and the between biomaterials, proteins and cells	methods for biomaterials testing, nteractions	dge		ф	Jo Sr		ciety			Work		ee				
CLR-3:	learn about various types of biocera <mark>mics</mark>	A STATE OF THE ASSESSMENT	Knowlec	ဟ	nent	stigation lems	age	os p					Finan	ning			
CLR-4:	acquire knowledge on various types of polymers for bio a	oplication	Š	alysi	evelopment	vestiga	ool Usage	ır and	∞ ×		Team	tion	& Fi	arni			
CLR-5:	acquire knowledge about implants	A 10 (10 A 10 A 10 A 10 A 10 A 10 A 10 A	ering	n Ana	n/deve	.⊑ હ	<del>-</del>	engineer	meniabilit		Jal &	mmunication	Mgt.	ong Le			
Course O	Outcomes (CO): At the end of this course, I	earners will be able to:	Engine	Problem Analysis	Design solutio	면원	Modern	The en	Environment 8 Sustainability	Ethics	Individual	Comm	Project	Life Lo	PSO-1	PSO-2	
CO-1:	understand common use biomaterials as metals, ceran properties and morphology	ics and polymers and its chemical structure,	3	201	1	7	-	4	-	÷	-	-	-	-	2		
CO-2:	describe interactions between biomaterials, proteins and	cells	3	2	4	-3	-	-	-	-	-	-	-	-	-	2 -	
CO-3:	choose the correct ceramic for medical application		3	110	2		_	-	-		-	-	-	-	2		
CO-4:	explain methods to modify surfaces of biomaterials and c	noose material for desired biological response	3	25	2	7 -	-	$\overline{}$	-		-	-	-	-	2		
CO-5:	understand the various materials for implant application	100 B TO 100 B	3	2	1	-	-	-	-		-	-	-	-	2		٦

Unit-1 – Biomaterials 9 Hour

Definition of biomaterials, requirements & classification of biomaterials. Comparison of properties of some common biomaterials. Effects of physiological fluid on the properties of biomaterials. Biological responses (extra and intra-vascular system). Surface properties of materials, physical properties of materials, mechanical properties. Polymers, silicone biomaterials, medical fibres and biotextiles – Smart polymers – bioresorbable and bioerodiblematerials – natural materials, metals and ceramics – physicochemical surface modification.

Unit-2 - Bio Compatibility 9 Hour

Biocompatibility concepts: Introduction to biocompatibility – cell material interaction – types of materials – toxic, inert, bioactive – long term effects of materials within the body – cell response. Biocompatibility & Toxicologicalscreening of biomaterials: Definition of biocompatibility, blood compatibility and tissue compatibility. Toxicity tests: acute and chronic toxicity studies (in situimplantation, tissue culture, haemolysis, thrombogenic potential test, systemic toxicity, intracutaneous irritation test), sensitization, carcinogenicity, mutagenicity and special tests.

Unit-3 - Ceramics and Bio-Ceramics 9 Hour

Ceramic implant materials: Definition of bio ceramics. Common types of bio ceramics: Aluminum oxides, Glass ceramics, Carbons. Bio resorbable and bioactive ceramics. Importance of wear resistance and low fracture toughness. Host tissue reactions: importance of interfacial tissue reaction (e.g., ceramic/bone tissue reaction). Composite implant materials: Mechanics of improvement of properties by incorporating different elements. Composite theory of fiber reinforcement (short and long fibers, fibers pull out). Polymers filled with osteogenic fillers (e.g. hydroxyapatite). Host tissue reactions.

Unit-4 - Polymer Implant Materials 9 Hour

Polymeric implant materials: Polyolefin's, polyamides, acrylic polymers, fluorocarbon polymers, silicon rubbers, acetyls. (Classification according to thermo sets, thermoplastics and elastomers). Viscoelastic behavior: creep- recovery, stress-relaxation, strain rate sensitivity. Importance of molecular structure, hydrophilic and hydrophobic surface properties, migration of additives (processing aids), aging and environmental stress cracking. Physiochemical characteristics of biopolymers. Biodegradable polymers for medical purposes, Biopolymers in controlled release systems. Synthetic polymeric membranes and their biological applications.

## Unit-5 - Metallic Implant Material

9 Hour

Metallic implant materials: Stainless steel, Co-based alloys, Ti and Ti-based alloys. Importance of stress-corrosion cracking. Host tissue reaction with bio metal, corrosion behavior and the importance of passive films for tissue adhesion. Hard tissue replacement implants: Orthopedic implants, Dental implants. Soft tissue replacement implants: Percutaneous and skin implants, Vascular implants, Heart valve implants-Tailor made composite in medium.

Learning Resources
Resources

- 1. Biomaterials Science: An Introduction to Materials in Medicine, By Buddy D. Ratner, ET. Al. Academic Press, San Diego, 1996.
- 2. Sujata V. Bhat, Biomaterials, Narosa Publishing House, 2002.
- 3. J B Park, Biomaterials Science and Engineering, Plenum Press, 1984.
- 4. Buddy D Ratner, Allan S Hoffman, "Biomaterials Science An introduction to materials in Medicine",
- 5. Elsevier academic press, (2004).

arning Assessm			Commention							
	Bloom's Level of Think <mark>ing</mark>	CLA-1 Avera	mative age of unit test 10%)	g Assessment (CLA) Life-Long CLA (10	4-2	Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	15%		15%	G- /2	15%	-			
Level 2	Understand	25%	10, 174, WEST 1 1 1 1	20%		25%	-			
Level 3	Apply	30%	to the second	25%		30%	-			
Level 4	Analyze	30%	1 4 1 1 2 1 N 1 1 1	25%	. 1	30%	-			
Level 5	Evaluate		William Commence	10%		-	-			
Level 6	Create	- Frank 1777	No. 100 100 100 100 100 100 100 100 100 10	5%	- C	-	-			
	Total	10	00 %	100	) %	10	0 %			

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Mr. K. Chandru, Medical Device Domain, HCL Technologies	1. Dr. Asifkhan Shanavas, INST, Mohali, asifkhan@inst.ac.in	1. Dr. G. Devana <mark>nd Venka</mark> tasubbu, SRMIST
2. Mr. P. Aravind Mukesh, United Breweries, Bengaluru	2. Dr.Biman B. Mandal, IIT G, biman.mandal@iitg.ac.in	2. Dr. N. Selvam <mark>urugan, S</mark> RMIST

Course	21NTE528T	Course	ATOMISTIC MODELING	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С
Code	Z 11V 1 E 3Z0 1	Name	ATOMISTIC MODELING	Category		PROFESSIONAL ELECTIVE	3	0	0	3

Pre-requisi Courses	te N	Co- requisite Courses	Nil Progre	Nil
Course Of	fering Department	Physics and Nanotechnology	Data Book / Codes / Standards	 Nil

Course L	earning Rationale (CLR): The purpose of learning this course is to:	11	1			Prog	ram Oı	ıtcome	s (PO	)					rogram	
CLR-1:	learn about basic modeling	1	2	3	4	5	6	7	8	9	10	11	12		Specific utcomes	
CLR-2:	understand the DFT for materials modeling	dge	)	of	SL					Work		8				
CLR-3:	understand the MD simulation	Knowlec		nent	estigations roblems	Usage	ъ			am W		Finan	gu			
CLR-4:	gain knowledge about Monte Carlo Simulation			elopment	estig		r and	∞ >	h.	Teal	igi	∞ర	arni			
CLR-5:	learn advanced modeling technique	ering	An	e e	t in y	20	engineer stv	nment		<u>8</u>	mmunication	Mgt.	g Le			
		9	ā	p/ub	onduct ir	dern		. S . W	SS	ndividual	חוו	ect	Long	7	2 2	
Course O	Outcomes (CO): At the end of this course, learners will be able to:	Engi	Problem	Desi		Mod	The	Envi	Ethics	Indi	Con	Project	Life	PSO-1	PSO-2	
CO-1:	acquire the basics of design a <mark>nd mat</mark> erials modeling	3	- 3	1	-	-	-7	-		-	-	-	-	-		
CO-2:	gain knowledge on DFT and the approximations in the context of materials modeling	3	3	40.0	7 Fr - 19		4	-	-	-	-	-	-	3		
CO-3:	obtain the knowledge on Mo <mark>lecular D</mark> ynamics and its application to solve materials problem	.3	MIN 12	1	3	-	-	-	-	-	-	-	-	-		
CO-4:	improve their knowledge on materials modeling with Monte Carlo Simulation	3		200		2	-	-		-	-	-	-	-		
CO-5:	solve problems to understand the electronic, mechanical and optical properties of Materials us	sing 3		3	Ж.	-	Č	-	-	-	-	-	-	-	2 -	

### Unit-1 - Classical Many, Body System

9Hour

Hamiltonians, Coordinate systems in the context of solving the physical problems, Potential energy, Definition and Concept – Calculation of elastic constants from potential function, Potentials for ionic systems, Potentials for ceramics Systems, Concept of Many-body potential, Many-body potentials for metals, Many, body potentials for covalently bonded systems, Comparative Study, Energy optimization, Significance of Lowest energy structure, Molecular statistics, Problems on Molecular Statistics, Thermo statistics, Problems on Thermo statistics problems

### Unit-2 - Density Functional Theory

9 Hour

Born-Oppenheimer approximation, Limitations of BO approximation, Introduction to DFT, Hohenberg-Kohn Theorems, Kohn-Sham Equation, Interpretation of KS equations, Exchange, correlation functions and LDA/GGA, Accuracy of LDA/GGA, PW91 method, PBE method, Pseudopotentials, Types of Pseudopotentials, Billouin zone, K,points, Monkhorst-Pack mesh, Gama point, Concept of Basis Set, The need for self, consistency, Setting up structures, key parameters, Volume optimization Metals vs.insulators, Basis sets, energy cutoff, exchange, correlation function, K-points, Convergence and scaling with lattice parameters, DOS and BAND Structure

# Unit-3 - Molecular Dynamics

9 Hour

Integrating F=ma, Detail time steps, The basic MD algorithm, The MD steps, Taylor expansion, Verlet algorithms, choosing the time step, Predictor-corrector algorithm, Discussion with Examples, MD in different ensembles, MD in constant temperature, Molecular dynamics in constant pressure, Examples of MD in constant temperature and pressure, Energies: molecular statics, Problems on Molecular Statistics, MD Simulation analysis. Limitations of MD. Application of MD as Case Study: 3D system. Application of MD as Case Study: 3D system.

### Unit-4 - Monte-Carlo Methods

9 Hour

Introduction, key concepts, Starting structure, energy cutoff, State space sampling, Classical momentum, Metropolis algorithm, Examples with a problem, Monte Carlo simulation analysis, Limitations of Monte Carlo simulations, Introducing ensemble sin MC, Kinetic Monte Carlo, Key concepts: starting structure in MD, Key concepts: starting structure in KMC, Convergence criteria, Scaling with lattice parameters, Understanding the electronic structure, Electrical conductivity, Excited electron states, Application of MC method as Case Study: Temperature effect, Determination of Tc

Unit-5 - DFT Codes 9 Hour

Introduction to various DFT codes, Basic DFT outputs, Basic output of QM code, Energies, electronic structure, Using the energies: molecular statics, MD, MC, Using the energies: MC, Using the electronic structure optical properties, Transitions between electronic states, Electrical conductivity, Mobility of electrons, scattering of electrons between states, Excited electron states due to thermal (or optical) excitations. Type of bonding, tunneling rates, Excited electron states due optical excitations, Example with a Material problem, Understanding the electronic structure from different Methods, Comparative study, Wave functions, charge density, band structure, density of states, Confinement effect on Electronic Structure, 3D, 2D, 1D Carbon based materials as example

Learning
Learning Resources
Resources

- Jörg-Rüdiger Hill, Lalitha Subramanian and Amitesh Maiti, Molecular modeling techniques in material sciences, Taylor & Francis/CRC Press: Boca Raton, 2005
- 2. Andrew R.Leach, Molecular modelling: principles and application, Pearson Education, In-dia, 2001
- 3. R. Martin, Electronic Structure: Basic Theory and Practical Methods, Cambridge University Press, 2004
- 4. J.M. Thijssen, Computational Physics, Cambridge, UK: Cambridge University Press, 2000

Learning Assessm	ent	- A(0) =								
	Bloom's Level of Th <mark>inking</mark>		Continuous Leamin native ge of unit test %)	g Assessment (CLA) Life-Long L CLA: (10%	-2	Summative Final Examination (40% weightage)				
		Theory	Practice	Theory	Practice	Theory	Practice			
Level 1	Remember	15%	all a little to the	15%		15%	-			
Level 2	Understand	25%	A Section of the Sect	20%	. 1 . 7	25%	-			
Level 3	Apply	30%	William Comment to	25%	- 4	30%	-			
Level 4	Analyze	30%	100 m 100 m 100 m	25%		30%	-			
Level 5	Evaluate	2.7 (7.5)		10%		0 -	-			
Level 6	Create		20 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	5%	3 -	-	-			
	Total	100	)%	100	%	100	0 %			

Course Designers				
Experts from Industry	E .	cperts from Higher Technical Institutions		Internal Experts
Dr. Hemant Dixit, GlobalFoundaries,	1	. Dr. Ranjit Kumar Nanda, IITM Chennai, nandab@iitm.ac.in		1. Dr. C. Prefer <mark>encial Ka</mark> la, SRMIST
aplahemant@gmail.com		1310		- N
2. Dr. Murali Kota, Global Foundaries, USA,	7 2	. Prof. G.P. Das, IIT KGP, msgpd@iacs.res.in	7/	2. Dr. Saurab <mark>h Ghosh,</mark> SRMIST
kvrmmurali@gmail.com				/

Course	21NTE529T	Course	DEFECTS IN MATERIALS	Course	Е	PROFESSIONAL ELECTIVE	L	Т	Р	С	
Code	21111123291	Name	DEFECTS IN WATERIALS	Category		PROFESSIONAL ELECTIVE	3	0	0	3	

Pre-requisite Courses	Ni	Co- requisite Courses	Nil	Progressive Courses	Nil
Course Offeri	ng Department	Physics and Nanotechnology	Data Book / Codes / Standards		Nil

Course L	Course Learning Rationale (CLR): The purpose of learning this course is to:			Program Outcomes (PO)									Program			
CLR-1:	utilize XRF material chara	acterization techni <mark>ques to anal</mark> yse defects in materials	1	2	3	4	5	6	7	8	9	10	11	12	_	pecific itcomes
CLR-2:	introduce strain and defor	rmation in mat <mark>erials</mark>	ge		Jo	SI	-	. "			Work		9			
CLR-3:	introduce dislocations and	d boundarie <mark>s defects</mark>	Knowledge	S	nent	ations	age	ъ	1		M M		Finan	Bu		
CLR-4:	explain the crystallograph	ic featur <mark>es of mate</mark> rials		Analysis	ldoli	estig		r and	∞ >	k.	Team	fion	∞	arni		
CLR-5:	introduce magnetic defec	ts	ering		gn/development	t inv	100 100	engineer	Environment Sustainability	. 1	<u>छ</u>	Sommunication	Mgt.	g Le		
			inee.	roblem	esign/		dern	enç	iron	S	Individual	l m	roject	Long	7-	7.2
Course C	Outcomes (CO):	At the end of this course, learners will be able to:	Engine	Pro	Des	ြုပ် မြောင်	N N	The	Env Sus	Ethics	ndi	Sol	Proj	Life	PSO-1	PSO-2 PSO-3
CO-1:	acquire knowledge on diff	fere <mark>nt types</mark> of defects in materials through XRF techniques	2	11.5	1	-1,	-	-7	-		-	-	-	-	-	
CO-2:	gain knowledge on strain	an <mark>d deform</mark> ation in materials	2	44-	40.00	3	2	4	-	-	-	-	-	-	3	
CO-3:	gain knowledge on disloc	ati <mark>ons and</mark> boundaries defects	2	وترابان	, P.	3	-	-	-	-	-	-	-	-	-	
CO-4:	acquire knowledge on cry	rst <mark>allograp</mark> hic features of materials	2	4,40		3	2	-	-		-	-	-	-	-	
CO-5:	gain knowledge on magn	eti <mark>c defect</mark> s	2	-	-	3	2		-		-	-	-	-	-	2 -

### Unit-1 - Defects in Crystalline Solids

9 Hour

Point and Electronic defects in crystalline solids, effect on electronic properties (doped Si and Ge), optical properties (F center and Ruby), Thermoelectric properties (Seebeek Coefficient); Point defect notations, Charges on defect. Balanced population on point defect: Schottky and Frenkel Defects, Determination of mineral concentration using XRF spectrometer for metal oxide / sulfide nanoparticles synthesized by chemical precipitation method

Unit-2 - Strain

Strain: Introduction, Infinitesimal strain, Homog<mark>eneous Strain; Stress; Elasticity of Crystals Translation Glide, Glide elements, independent slip systems, Large strain, texture Twinning, description of deformation twinning, Examples of twin structures, twinning elements, morphology of twinning elements.</mark>

## Unit-3 - Dislocation

9 Hour

Dislocation; Edge, Screw & Mixed dislocations, Unit & partial dislocations, Multiplication of Dislocations, Interaction of Dislocations & Point Defects, Dislocations in Nonmetallic Crystals, Internal Boundaries, Low-Angle Grain Boundaries, Twin Boundaries, Antiphase Boundaries

### Unit-4 - Martensitic Transformation

9 Hour

Martensitic transformation, General crystallographic features, Examples Co, Zr, In-Th, Steels; Transformations in non-metals, Crystallographic aspect of Nucleation and growth. Structure of Surface and Surface free energy, Structure and energy of Grain boundaries.

### Unit-5 - Magnetic Defects

9 Hour

Magnetic defects, magnetic defects in semiconductor, magnetic defects in Ferrites, Charge and spin state of Cobaltites and Manganites, Extended Magnetic Defects Optical Defects, Absorption and scattering, Pigments, minerals and Gemstones. Colours and Impurity. Photoluminescence, Energy Degradation and Down-conversion, Up-conversion

Learning	1. R. J. D. Tilley, Defects in solids, (Wiley, 2011)	3. D. Hull and D. J. Bacon, Introduction to Dislocations, 5th Edition, Pergamon Press, 2011
Resources	2. Kelly, Groves and Kidd, Crystallography and Crystal Defects (John Wiley, 2000)	

			Continuous Learning Assessment (CLA)						
	Bloom's Level of Thinking	CLA-1 Avera	rative ge of unit test %)	CL	Learning A-2 0%)	Summative Final Examination (40% weightage)			
		Theory	Practice	Theory	Practice Practice	Theory	Practice		
Level 1	Remember	15%	-	15%		15%	-		
Level 2	Understand	25%		20%		25%	-		
Level 3	Apply	30%		25%	2 - 1	30%	-		
Level 4	Analyze	30%	A	25%	- A-	30%	-		
Level 5	Evaluate	A 7-	27.70	10%	( P)	-	-		
Level 6	Create	/-/-/	A 200 Sept. 1999	5%		-	-		
	Total	100	) %	10	0 %	10	0 %		

Course Designers		
Experts from Industry	Experts from Higher Technical Institutions	Internal Experts
1. Dr. Venkataramana Bonu, NAL, Bangalore	1. Dr. Herojit Loushambam, NIT Manipur	1. Dr. S. Anbumoz <mark>hi Angay</mark> arkanni, SRMIST
2. Dr. Manan, IGCAR, manan@igcar.gov.in	2. Dr. Sudhashu Sekar Pati, NIT Jamshedpur, sspati.chem@nitjsr.ac.in	2. Dr. Rudra Baneriee SRMIST



# SRM INSTITUTE OF SCIENCE AND TECHNOLOGY

(Deemed to be University u/s 3 of UGC Act, 1956)

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